



Quality & Reliability

August 2022 Rev. A

1623 Buckeye Dr.

Milpitas, CA 95035

p. 408-969-6600

f. 408-969-7800

sales@Lumissil.com

www.Lumissil.com

Contents

| | |
|--|-----|
| Quality and Reliability | 4 |
| 1.1. Quality and Reliability Organization..... | 4 |
| 1.2. ISO 9001 Certificate..... | 5 |
| 1.3. Quality Systems..... | 8 |
| 1.4. Quality Assurance Processes..... | 19 |
| 1.5. Customer Complaints | 30 |
| 1.6. Change Control..... | 34 |
| 1.7. Management of Subcontractors | 36 |
| 1.8. Functional Safety..... | 41 |
| Failure Analysis | 43 |
| 2.1. Establishment of Failure Analysis Laboratory..... | 43 |
| 2.2. Physical Failure Analysis (PFA) Laboratory | 43 |
| 2.3. Failure Analysis Function | 43 |
| 2.4. Failure Analysis Flow | 44 |
| 2.5. Failure Analysis Instruments..... | 46 |
| Reliability Assurance | 46 |
| 3.1. Semiconductor Reliability | 47 |
| 3.2. Failure Rate Calculation..... | 49 |
| 3.3. New Product/Process Qualification | 55 |
| 3.4. Qualification Test Method and Acceptance Criteria | 61 |
| 3.5. Production Reliability Monitoring..... | 66 |
| 3.6. LUMISSIL Reliability Test conditions..... | 68 |
| 3.7. LUMISSIL Reliability Test Equipment List..... | 71 |
| 3.8. Zero Defect Statistics | 71 |
| Environmental Management Systems | 77 |
| 4.1. Environmental Policy..... | 77 |
| 4.2. Environmental Management Systems | 78 |
| 4.3. Environmental Substances Management..... | 81 |
| 4.4. Product Composition..... | 100 |
| 4.5. Lead-free Solution | 101 |
| 4.6. Halogen-free Solution..... | 103 |

| | | |
|-------|---|------------|
| 4.7. | Pb-free/Halogen-free Evaluation/Qualification Information | 103 |
| 4.8. | Current Status | 107 |
| 4.9. | Solder Heat Resistance for PCBA (PC Board Assembly)..... | 107 |
| 4.10. | Lead Time from Ordering to Delivery | 108 |
| 4.11. | Distinguishing Mark of Lead-free and RoHS compliance Package | 108 |
| 4.12. | Re-flow Temperature Profile for Lead-free Package..... | 109 |
| 4.13. | Storage Recommendations..... | 110 |
| 4.14. | LUMISSIL Declaration of Compliance | 110 |
| 4.15. | RoHS Declaration..... | 112 |
| 4.16. | California Proposition 65..... | 113 |
| 4.17. | China Volatile Organic Compounds (VOC)..... | 114 |
| 4.18. | Conflict Free Materials Template (CMRT) for Analog, Analog_MCU and Connectivity | 115 |
| | Business Continuity | 116 |

Quality and Reliability

At LUMISSIL Quality and Reliability are key to our success, and of the highest priority.

LUMISSIL Quality Systems have evolved over the years to support the company business strategy of long term support.

The LUMISSIL Quality and Reliability Organization has team members positioned around the world to better support our customers.

LUMISSIL Quality and Environmental Management Systems are ISO certified. While LUMISSIL does not directly manufacture products, and therefore not eligible for automotive standard certification, the subcontractors who build products for LUMISSIL are automotive standard certified.

LUMISSIL's Quality Assurance Processes apply to all stages of activity. This means that Project Approval, Design and Development, Production, and Testing through Shipping are carried out in compliance to high quality standards.

Additionally, LUMISSIL employs Quality Tools and implements the 8D process of Problem Solving for Customer Complaints in order to continually improve customer satisfaction. For product and process changes, notifications are sent out to customer via our PCN process.

Outsourcing to our manufacturing partners is essential to our success. Consequently, the subcontractors are regarded as extensions of LUMISSIL's production process, particularly due to the fact that LUMISSIL is a fabless company. LUMISSIL's Supplier Management contributes to our strategic objectives.

1.1. Quality and Reliability Organization

Lumissil Microsystems is a division of Integrated Silicon Solution Inc. (ISSI).

LUMISSIL headquarters is located at 1623 Buckeye Drive, Milpitas, California, USA where the corporate policies and programs are determined and applied to world-wide operations. The Taiwan facility is located in the Science-Based Industrial Park, Hsin-Chu, Taiwan, R.O.C. The China office is located in Software Park III, Xiamen. The Israel office is located in 38 Habarzel st., Tel Aviv. Operations in Taiwan and China consist primarily of research and development activities and Foundry and Subcontractor management. Subcontracted operations include Wafer Fabrication, Assembly and Final Test. Many of these subcontractors are located in Taiwan and China and are managed by the Taiwan and China

quality organization.

LUMISSIL Management and all other team members are committed to:

- Understand and satisfy interested parties expectations
- Provide defect-free products and outstanding service cost effectively
- Continuously improve ours and our partners methods and processes
- Training that enables us to do things right
- Be the best in class in everything we do

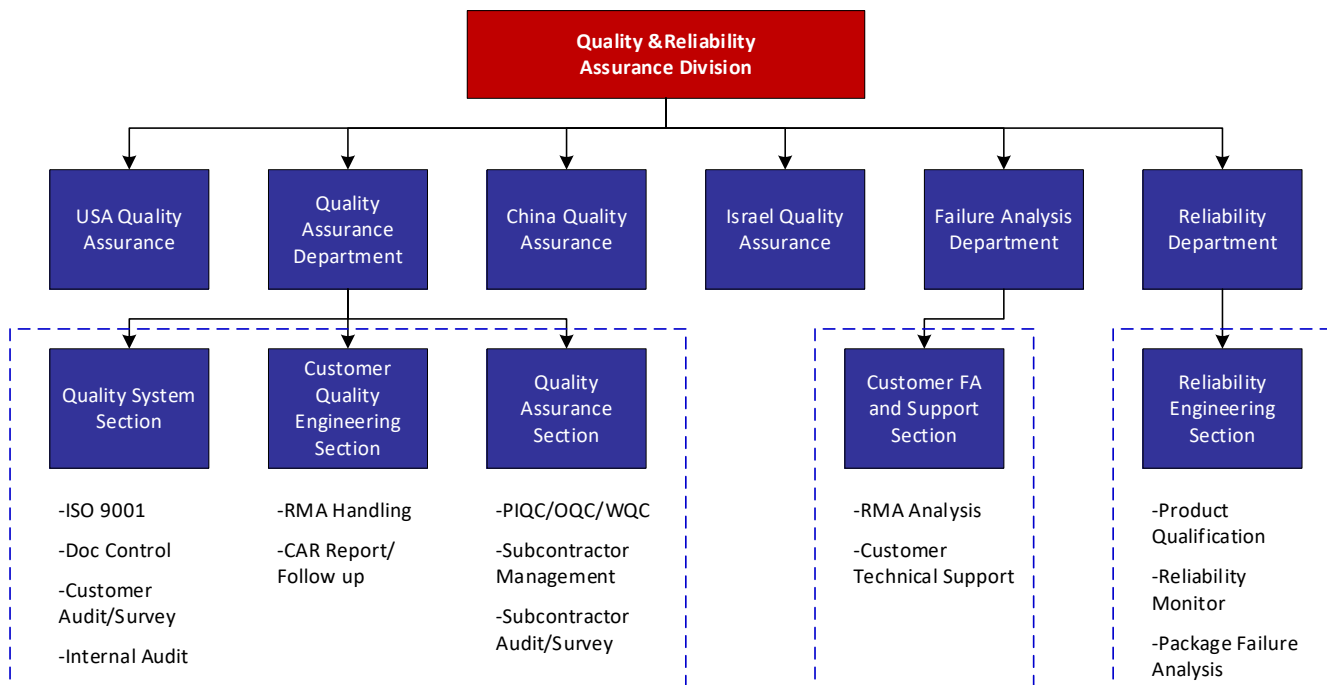


Figure 1-1. Quality and Reliability Organization

1.2. ISO 9001 Certificate



CERTIFICATE



This is to certify that

**Integrated Silicon Solution (Cayman), Inc. Taiwan Branch
Integrated Silicon Solution, Inc. (ISSI)
Chingis Technology Corp.**

No. 2, Technology Road, V Hsinchu Science Park
Hsinchu
Taiwan

with the organizational units/sites as listed in the annex

has implemented and maintains a **Quality Management System**.

Scope:

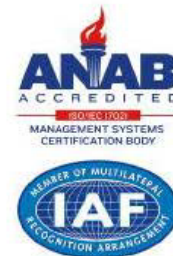
The design of integrated circuits.

The management of outsourced integrated circuit production activities.

Through an audit, documented in a report, it was verified that the management system fulfills the requirements of the following standard:

ISO 9001 : 2015

| | |
|--------------------------------|---------------|
| Certificate registration no. | 20001373 QM15 |
| Date of original certification | 2004-03-29 |
| Date of revision | 2020-10-06 |
| Date of certification | 2020-10-23 |
| Valid until | 2023-10-22 |



DQS Inc.

Brad McGuire
Managing Director

Accredited Body: DQS Inc., 1500 McConnor Parkway, Suite 400, Schaumburg, IL 60173 USA
Administrative Office: DQS Taiwan Inc., 8F, 23, Yuan Huan West Road, Feng Yuan Dist.,
Taichung City, Taiwan 420

1 / 2





**Annex to certificate
Registration No. 20001373 QM15**

**Integrated Silicon Solution (Cayman), Inc. Taiwan Branch
Integrated Silicon Solution, Inc. (ISSI)
Chingis Technology Corp.**

No. 2, Technology Road, V Hsinchu Science Park
Hsinchu
Taiwan

| Location | Scope |
|---|--|
| 20001370 Integrated Silicon Solution, Inc. (ISSI) 1623 Buckeye Drive, Milpitas California, 95035-7423 USA | Product Design, Sales & Marketing activities. |
| 20001371 Integrated Silicon Solution (Cayman), Inc. Taiwan Branch 7F, No. 106, Sec. 1, Hsin-Tai 5th Road Hsi-Chih, New Taipei City Taiwan | Sales and Marketing activities. |
| 50600141 Integrated Circuit Solution, Inc. (ICSI) 5F, No.669, Sec. 4, Zhongxing Rd Zhudong Township, Hsinchu County Taiwan | Logistics, Testing, Warehousing, Sales & Marketing activities. |
| 505513 Si En Technology (Xiamen) Limited A-12, Innovation Tower, Zhenzhuwan Software Park, Siming Zone, Xiamen City Fujian Province China 361005 | The design of integrated circuits. The management of outsourced integrated circuit production activities, Sales & Marketing activities. |
| 50600297 Integrated Silicon Solution Israel Ltd (ISSI Israel) 38 Habarzel St Tel-Aviv 69710 Israel | Sales and Marketing, Design and Development of Connectivity Devices. |

This annex (edition: 2020-10-06) is only valid in connection with the above-mentioned certificate.

2 / 2

1.3. Quality Systems

LUMISSIL Quality systems have evolved to comply with automotive standard compliance. While not all LUMISSIL products are shipped to automotive, the system requirements have been embraced to attain more robust quality processes.

ISO 9001 Year 2015 Revision

The Management team has defined the quality policy and objectives for LUMISSIL and has established a quality management system to ensure that the quality policy and quality objectives are understood, implemented and maintained. The Quality System defined in LUMISSIL Quality Manual is in compliance with the requirements of ISO 9001: 2015. It is stratified and compiled into documents with the Quality Manuals at the top supported by procedures, specifications, regulations, rules and detailed work instructions, etc. (see Figure 1-2).

Employees are trained and keep records of duties carried out according to the prescribed methods based on the latest documents to ensure that the constructed quality system is implemented in the prescribed manner.

The quality system is periodically checked and evaluated through the internal quality audits and external audits by ISO certified agencies to provide opportunities for continuous improvement.

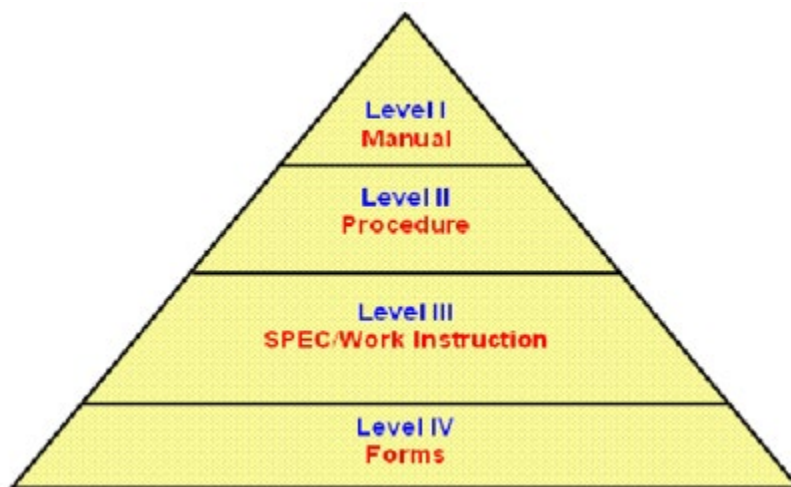


Figure 1-2. Quality Document System

LUMISSIL in USA was certified to ISO 9001:1994 in Sept 1995. With the continuous effort in quality improvement, LUMISSIL achieved the ISO 9001: 2000 standard in July 2002.

And, LUMISSIL is certified to ISO 9001:2008 in 2009. All LUMISSIL locations passed ISO9001 assessments in 2005 conducted by UL (Underwriters Laboratories) current DQS one of the leading international certification bodies, as shown by the certificate issued in Figure 1-3. Since the ISO9001:2015 has been published in Sep 2015, LUMISSIL is compliance with new revision as well as planned schedule.

LUMISSIL is not only certified to ISO9001 but also achieved the required quality system level as required by IATF16949 through team effort in the past few years. LUMISSIL has implemented IATF16949 quality system requirements and has successfully passed several automotive customer audits that are leaders in the international automotive industry. All employees are moving forward through continuous improvement. The IATF16949 has been published in Oct. 2016, LUMISSIL is on the way to comply with the new quality standard.

Process Map

The inter-relationship of LUMISSIL systems is shown in the Figure 1-3.

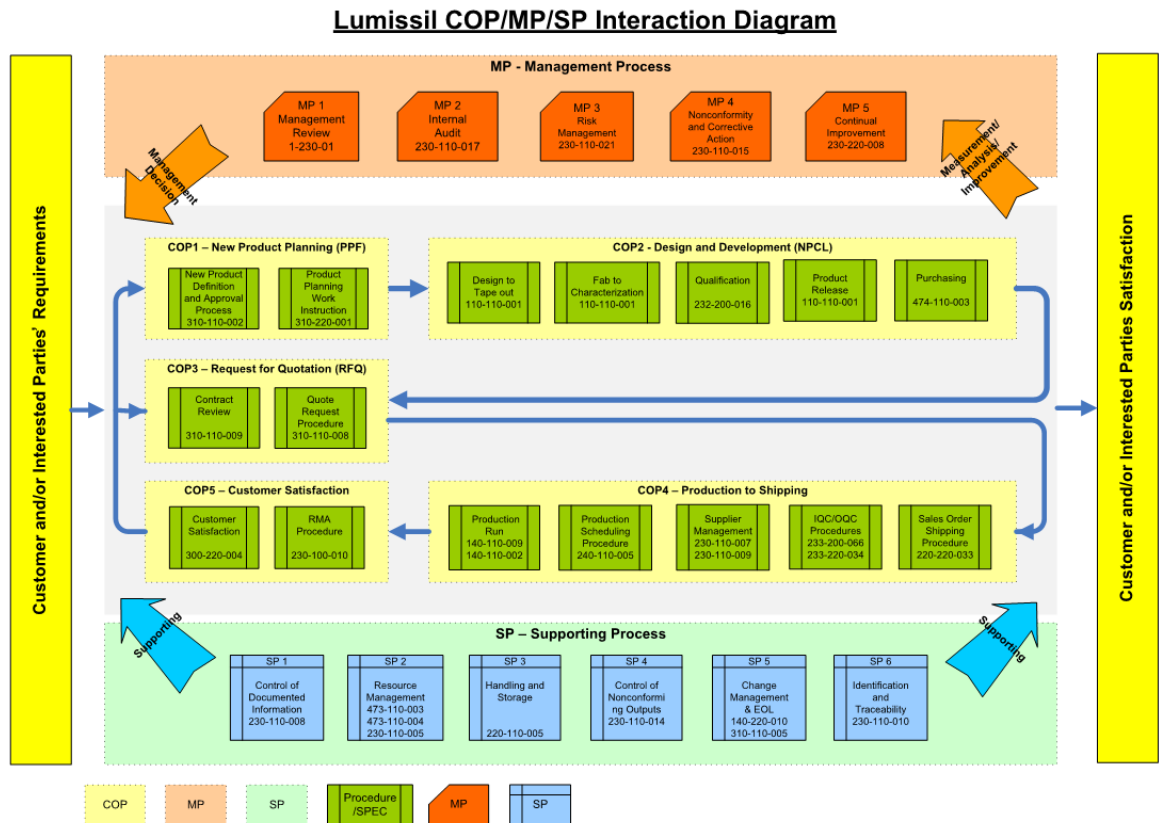


Figure 1-3. Process Map – Interaction Diagram

Advanced Product Quality Planning

LUMISSIL linked together the requirements of the automotive Advanced Product Quality Planning by setting up Product Planning Form (PPF) and New Project Checklist (NPCL) System. The system is web based and can be accessed by all the team members. In the NPCL system, all the steps and requirements for the life of a product can be documented and tracked. The following processes contribute to the success of the NPCL.

1) Product planning – Marketing gets the new project approved.

2) New Product Plan – Marketing endorses the project to Design who will work with Marketing, Development and Engineering to put the product plan together.

The consideration of Automotive Functional Safety is required at this stage. Either customer DIA or SEooC will be discussed and decided.

3) Design and Development – at this stage, Design works with Technology Development for the actual Design of the product taking into consideration customer requirements for the product. One tool used at this stage is the Design FMEA. FMEAs are discussed in the succeeding section.

4) Process Development – it is at this stage that Design and Technology Development work with Product Engineering and Assembly Engineering and QRA to develop the Production Design and Product Flow. It is also at this point that the requirements for qualifying the product are planned to verify if the actual performance of the product meets the intended characteristics. At this stage, additional tools are identified such as Production flows, Control Plans and Statistical Methods for controlling the characteristics of the product. It is also at this stage that the tool Product Part Approval Process is utilized.

5) Product Verification – the plans for verifying the conformance of the product to required characteristics is executed

6) Prototypes – LUMISSIL also builds product prototypes which are a limited quantity of risk builds are produced as needed. During these builds the conditions and controls are the same as actual production. At this point, preliminary Cpk's are already computed and studied.

7) After the successful production of risk builds, then the product is ready for full production and ramp up. Samples for customer qualification have already passed and customers have already given feedback to LUMISSIL on the product performance in their application.

8) Any problems encountered during the steps of the NPCL requires corrective action and lessons learned are recorded. For problem solving, LUMISSIL uses the 8Discipline (8D) method.

Any problems encountered during the life of the product will undergo this process of problem resolution.

The interrelation shown in Figure 1-4 represents the activities and different department's involvement during each phase of Advanced Product Quality Planning.

| Process | Sales/ Marketing | Design Engineering | Technology Development | Product Engineering | Assembly Engineering | Reliability Engineering | Testing Engineering | QA | Purchase | Production Control |
|-------------------------------|--|--|--|---|--|--|---|--------------------------------|------------------------------|---|
| Product Planning Form | 1. Issue Product planning form 2. Prepare Data sheet 3. Customer DIA or SEoC | 1. Resource arrangement 2. Plan/ Schedule | 1. Foundry/ Technical selection | 1. Resource arrangement 2. Production flow identification | 1. Assembly selection 2. Resource survey | 1. Reliability survey | 1. Wafer sort/ Final test survey | | 1. Cost survey | 1. Resource survey 2. Cost analysis |
| New Project Check List | Kick-off Meeting and project approved | | | | | | | | | |
| | | 1. Review DFMEA 2. Design rule check 3. Tape out document 4. Design report 5. CAD check 6. Tape-out approval/ meeting 7. Review FMEDA | 1. Review mask layer spec 2. review Device cross section 3. WAT spec complete 4. Process flow 5. PPAP review (PFMEA, MSA, Control plan, SPC and production flow) | 1. Review Handler/ change kit and prepare Probe card/Load board 2. Risk production Stage (a) CP yield trigger (b) FT yield trigger (c) CP test program release (d) FT test program Release (e) PPK review 3. PPAP review (PFMEA, MSA, Control plan, and flow) | 1. Marking specification 2. PPAP review (PFMEA, MSA, Control plan, SPC, Production flow) 3. Process stage (a) lead frame preparation (b) Bonding diagram (c) IC marking | 1. Burn-in diagram 2. HAST diagram 3. PQR report (Device) 4. PQR report (Package) | 1. Test flow preparation 2. Test program preparation 3. Characterization program/report 4. Sample preparing stage (a) ESD/ Latch up sample (b) Qualification sample | Review / Monitor every process | Follow up wafer out schedule | Handle small volume/ middle volume and mass production |
| Release Meeting | Release / Start Check meeting | | | | | | | | | |

Figure 1-4 New Project Checklist Activity Flow

The major milestones determine the status of each new product including project approval, design development, and release to production. Each of the indicated departments must approve the new product release to production based on defined objectives that include product performance and quality.

Failure Mode and Effects Analysis (FMEA)

FMEA is a structured procedure for identifying and minimizing effects of as many potential failure modes as possible. FMEA was formalized as a failure analysis technique in the 50s and 60s in the aerospace industry -NASA, etc. And FMEA training program was developed by FORD in 1972 and used by all big 3 U.S. automakers.

The factors contributing to spread of FMEA are rapid advancements in technology, which are forcing manufactures to develop new products more quickly to remain competitive. With less time for testing and re-design, they must achieve their reliability target the first time around. Both of foreign and domestic competition has raised customers' expectations for quality and reliability. Also, the trend toward litigation has forced manufacturers to exercise greater care in the design and manufacture of their products.

FMEA is one of quality improvement tools. It helps reduce the effects of potential failure modes associated with key product characteristics. In general, there are three applications for purpose of design, process and service FMEA. In LUMISSIL current situation, we started FMEA in Oct 2004 by reviewing three kinds of data and experiences, QA, FA & RMA, by concentrating on abnormality case in production line, reliability issue, case of failure analysis, customer feedback study, and case of products returned. All of FMEAs focus on design and process which helps to minimize effects of failure that results from shifting in process variables, i.e., out of spec conditions, such as misplacing ball bonds, die misalignment, holes in package, burrs on lead frame, etc. It is useful for existing products or processes that are undergoing a major design change which could affect their reliability.

The FMEA addresses the following issues:

- What function(s) is the product supposed to perform?
- How could the product fail to perform that function(s)?

- What effect would the failure have on the end product and the end user?
- How severe is the effect?
- What could cause the failure?
- How likely is the cause to actually result in the failure mode?
- What is being done to prevent or detect the cause?
- How effective is this prevention or detection method?
- What is the overall risk associated with the failure mode?
- What corrective actions can be taken to eliminate the cause of failure, or to improve the prevention or detection measure, and thus reduce the risk?

Basic Steps to Develop FMEA

1) A cross function team, made up of people from all affected functions should be formed to develop an FMEA. These could be, but are not limited to, design, process, manufacturing, marketing, operators, technicians, QA, etc., having involvement early on from these areas will help ensure that all significant areas of potential failure are addressed.

2) The cross function team can draft the FMEA by determining the information indicated on the form as following:

- a) Potential failure mode
- b) Potential effects of failure
- c) Ranking of severity
- d) Potential cause/mechanisms of failure
- e) Ranking of occurrence
- f) Current process controls
- g) Ranking of detection
- h) Calculate the risk priority number
- i) Recommended actions
- j) Countermeasures and plans

k) Responsibility & target completion date

l) Action taken

In fact, the above items are included in the FMEA format (Figure 3). Although the purpose of FMEA is not to simply complete the form, the FMEA is a tool that helps provide new insights about the product or process. The management commitment, a cross functional team that understands and supports the FMEA process and team members with as much information about the product or process as possible are basic requirements for success of FMEA implementation.

Recommended Priority for the Corrective Action Taken

1. Priority number #1 always falls on the item with the highest score of severity.
(Example Sev. \cong 9)
2. To prioritize item by top 20% of Pareto of RPN which is a product of the Severity, Occurrence and Detection numbers (SxOxD).
3. Customer's instruction
4. Government regulations
5. Degree of easiness in implementing corrective action

Regarding the new version AIAG-VDA FMEA, LUMISSIL have received training courses by outsourcing consultant in Oct 2020. The relevant staffs have attended the training and willing to implement it when starting new project from Jan 2021.

As reference to US/European and some Japanese car makers have reached the agreement to adopt new FMEA for their 2022 or 2023 new models. However, since the development of a new car will take about 3 years, the required dates for its IC components are actually "Today".

LUMISSIL intends to apply new FMEA format by following step 1-Planning and preparation, step 2- Structure analysis, step 3-Function analysis, step 4-Failure analysis, step 5-Risk analysis and step 6-Optimization. The new FMEA requests all the "Analysis" to be linked closely with each other. It is required to list all the process steps at top level. For each step, the factors of 4M1E (Man, Machine, Material, Method and

Environment) need to be addressed explicitly. Then all the items have to be linked from step 2- Structure analysis all the way to step 5-Risk analysis. Please refer to new FMEA format as Figure 1-6.

The new FMEA seems closely related to ISO-26262 concept and need to involve related departments to work together based on given applications. It is crucial that Marketing/Sales needs to work closely with customers to provide application scenarios so that engineering team can construct FMEA accordingly.

Design Failure Mode and Effects Analysis
(Design FMEA)

PLANNING AND PREPARATION (STEP 1)

Company Name: _____
 Engineering Location: _____
 Customer Name: _____
 Model Year / Platform: _____

Subject: _____
 DFMEA Start Date: mm.dd.yyyy
 DFMEA Revision and Date: Rev. / mm.dd.yyyy
 Cross-Functional Team: _____

DFMEA ID Number: _____
 Design Responsibility: _____
 Confidentiality Level: _____

| STRUCTURE ANALYSIS (STEP 2) | | | FUNCTION ANALYSIS (STEP 3) | | | FAILURE ANALYSIS (STEP 4) | | | | RISK ANALYSIS (STEP 5) | | | For ISO 26262 | OPTIMIZATION (STEP 6) | | | | | | | | | |
|-----------------------------|-------------------------------|---------------------------------------|--|---|---|--------------------------------|--------------------|----------------------|-----------------------|--------------------------|---------------------------------------|--|---------------------------|---|-------------------|------------------|---------------------------|----------------------------|----------------------------------|---------------------------------------|----------------------------|--|---------|
| 1. System (Item) | 2. System Element / Interface | 3. Component Element (Item) Interface | 1. Function of System and Requirement or Intended Output | 2. Function of System Element and Intended Performance Output | 3. Function of Component Element and Requirement or Intended Output or Characteristic | 1. Failure Effects (FE) | Severity (S) of FE | 2. Failure Mode (FM) | 3. Failure Cause (FC) | Failure Functional Block | Current Prevention Control (PC) of FC | Current Detection Control (DC) of FC or FM | Detection (D) of FC/FM AP | ISK Related <i>(Referenced file: please insert filename)</i> | Preventive Action | Detection Action | Responsible Person's Name | Target completion Date | Status: Open Completed discarded | Action Taken with Pointer to Evidence | Completion Date | Severity (S) Occurrence (O) Detection (D) AP | Remarks |
| | | | | | | Your Plant; | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | Ship to Plant; | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | End User; | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |
| | | | | | | | | | | | | | | | | | | mm.dd.yyyy | | | mm.dd.yyyy | | |

Figure 1-6 AIAG-VDA FMEA

1.4. Quality Assurance Processes

1.4.1. Quality Assurance in the Project Approval Stage

Before starting product planning, it is essential to carry out market research activities to ascertain the intended applications and the product quality/reliability demanded by each customer, and also to understand technical trends in the general marketplace, basic specifications, delivery requirements, prices, quality, reliability and other demands on products.

Information on demanded quality and reliability acquired through the above activities, various data obtained in-house from accumulated results and fundamental research on reliability technology are used to set target levels which are appropriate for product applications and operating environments and to formulate development plans.

This information is then compiled into product plans, and design specifications are drawn up based on these product plans and summarized as input for design.

1.4.2. Quality Assurance in the Design and Development Stage

Product Development and Design

Product design is an extremely important process for ensuring high quality and reliability in semiconductor devices, and it is necessary to implement both built-in quality and built-in reliability.

Product design proceeds according to the design specification. These specifications include design inputs (applicable regulations, customer demands and in-house standards) to ensure that appropriate requirements are considered. Product design goes through the stages of logic/circuit design, layout, mask design, prototype manufacture and evaluation before reaching completion.

Design Review

Design review consists of checking whether the design standards are the rules to be followed. Observance of design standards is checked using various simulation tools automatically or manually.

LUMISSIL provides simulation models for each Analog, Analog_MCU and Connectivity part manufactured. These models are revised as new device and technologies are developed. Models can be obtained by contacting LUMISSIL FAE department.

In addition, characterization data on each device are performed and retained in LUMISSIL K2 database. These characterization data are available upon request on a case-by-case basis. Also, the Automotive Functional Safety requirement will be reviewed and the FMEDA will be checked.

Product Release

The final stage before a new product is released to manufacturing is Product Release. During the final product release meeting all requirements of the NPCL are reviewed for completeness and the checklist of items for the product released are discussed. When all are supplied of the satisfaction of the team, the documentation is signed off and the product is officially released together with the qualification and characterization data to demonstrate that the product can be manufactured in accordance to requirements.

Production Part Approval Process (PPAP)

As part of the NPCL process, the requirements of the PPAP for automotive products are supplied whenever a product is being qualified for automotive applications.

LUMISSIL will supply the Certificate of Design, Construction and Qualification (CoDC) as well as the Part submission Warrant (PSW) together with the various specific requirements by the automotive customer.

LUMISSIL subcontractors (Fab and Assembly) also submit their own PPAP to LUMISSIL for new technologies and processes.

1.4.3. Quality Assurance in the Production Stage

Wafer Processing

1) Wafer Process Technology

Since LUMISSIL is one of the IC design leaders in the world, we serve hundreds of customers with different needs and applications. In order to satisfy all customers' needs, we offer the LED driver, touch sensors, audio, microcontrollers, power

management and connectivity products with leading-edge Mixed-Signal and BCD process technologies in 40nm, 55nm, 90nm, 0.11-micron, 0.15-micron, 0.18-micron, 0.25-micron generations as well as 0.35-micron, 0.5-micron for Lumissil products.

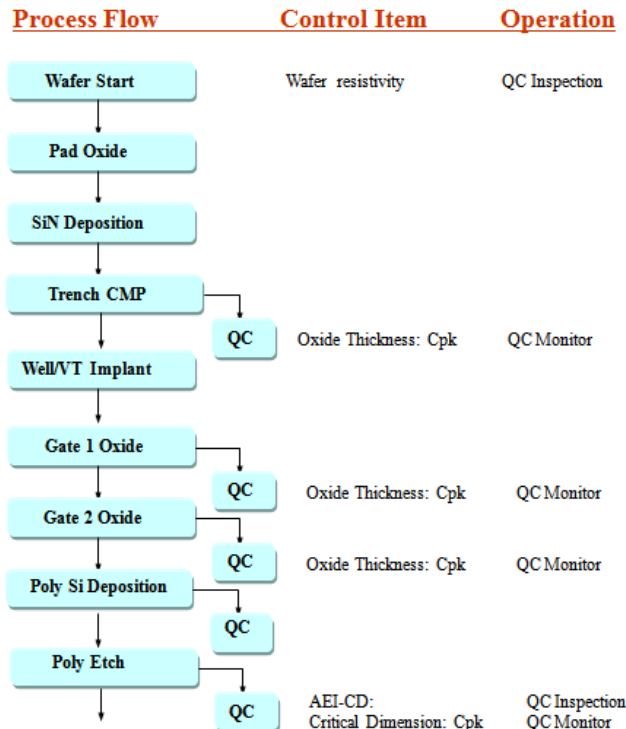
The process technology is developed in accordance with standardized methodologies. Each new technology must pass a rigorous qualification procedure based on typical industry standards before it is released to mass production.

Once in production, every released process is constantly monitored against a predetermined set of standards. The monitor results are then published in the foundry's website and LUMISSIL QA will periodically access the database for evaluation.

Products released to production are monitored at the wafer and package level. Wafer acceptance test (WAT) data by lot indicate key process measurements tested to specified limits. Packaged units are periodically monitored for reliability based on package family and assembly line.

2) Wafer Process Flow and In-line Control

The generic wafer process flow and major control items are shown in Figure 1-7 with Analog as an example.



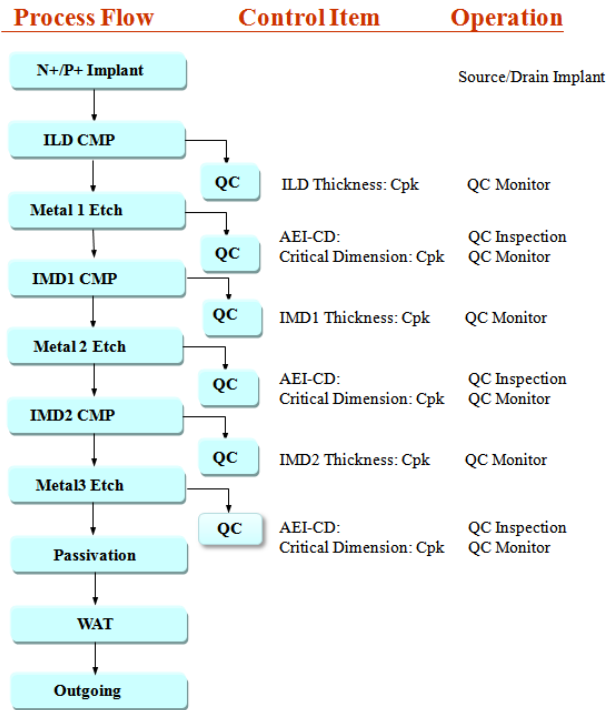


Figure 1-7 Generic Analog Wafer Process & Control Example

Assembly Process Technology

Our qualified assembly houses offer IC packaging design and fabricate a full array of packages for LUMISSIL products, with pin counts from 5 to more than 128. Major packaging offers include quad flat packages (TQFP, LQFP), small outline packages (SOP, TSOP) and Dual/Quad flat no-lead (DFN, QFN) for Analog products. To ensure that they create world-class packages, the major assembly houses are ISO 9000, IATF 16949 and ISO 14001 certified companies.

For the Automotive Functional Safety project, part of our Subcontractors including Assembly and Final testing houses are certified ISO26262 process audit by certification bodies.

The generic assembly process flow and major control item are shown in Figure 1-8.



Figure 1-8 Generic Assembly Process & Control

Testing

1) Overview

The purpose of testing is to verify the conformance to LUMISSIL specifications and/or customer requirements before the products are delivered to customers. Testing is an inspection process that is needed because the failures have not been eliminated. The failures are usually caused by design errors, materials and process defects, operational environment extremes, and aging effects.

Although testing does not add value to the product, LUMISSIL recognizes it is crucial to recruit skilled engineering expertise to guarantee testing quality. This requires a sizable investment, however, we believe it is a necessity for any company intending to become, or remain as, a leading logic and memory supplier.

Electrical testing consists of three steps: 1) continuity test, 2) DC parametric test, and 3) functional and dynamic test (AC). It is used for verifying IC performance and conformance to LUMISSIL published data sheet so that “bad” parts¹ are not shipped to the customers. The electrical specification limits and conditions are related to the wafer fabrication process parameters and thus to the potential physical defects that might occur.

2) Analog/Analog_MCU/Connectivity Product Testing Flow

The templates of Commercial Analog/Analog_MCU/Connectivity product Test Flow & Control are shown in Figures 1-9 and 1-10 respectively.

3) Known Good Die Testing Flow

In addition to the package products LUMISSIL offers die only material to customers. Known good Die (KGD) business and service is provided to our customers upon request. The generic KGD Test Flow and Control is shown in Figure 1-11.

These die could be in wafer form. Also, the customer can choose an option of tested die without speed testing (Known Tested Die) or die that had gone through burn-in and full testing (Known Good Die)

¹ The unit of measurement for this is typically a parts-per-million (ppm) value for the defective parts shipped to customer.

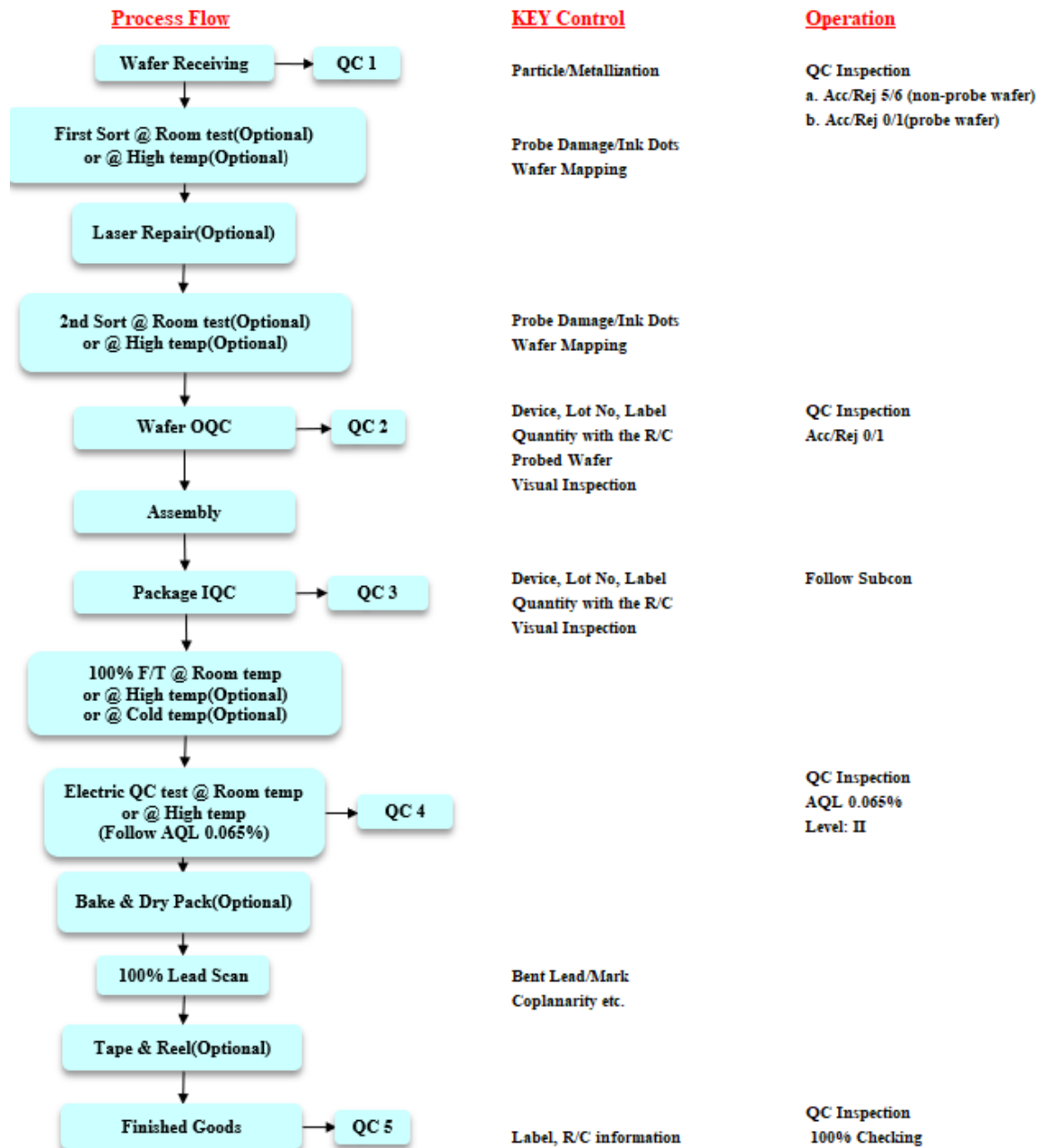


Figure 1-9 General Analog Test Flow & Control

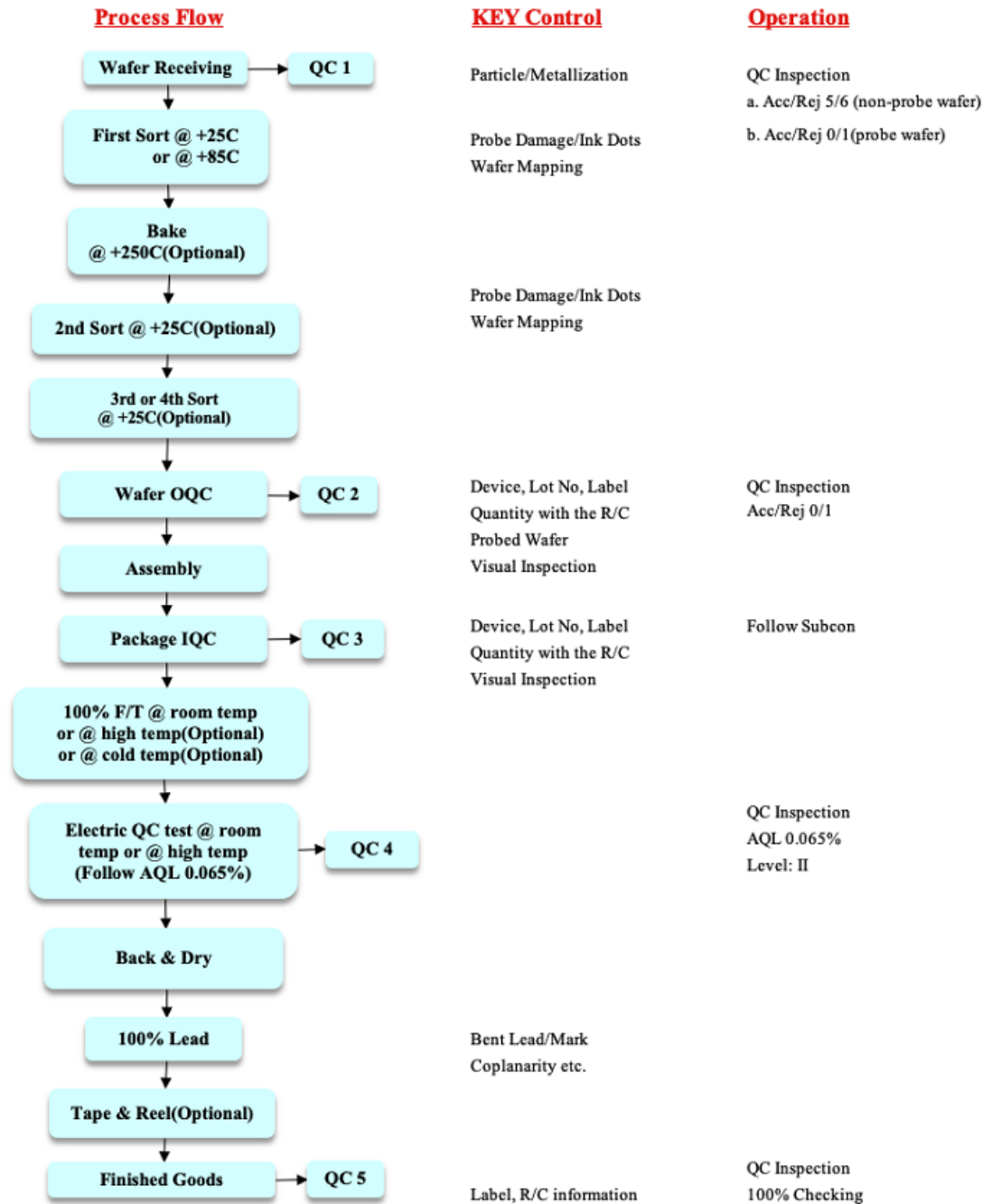


Figure 1-10 General Analog_MCU Test Flow & Control

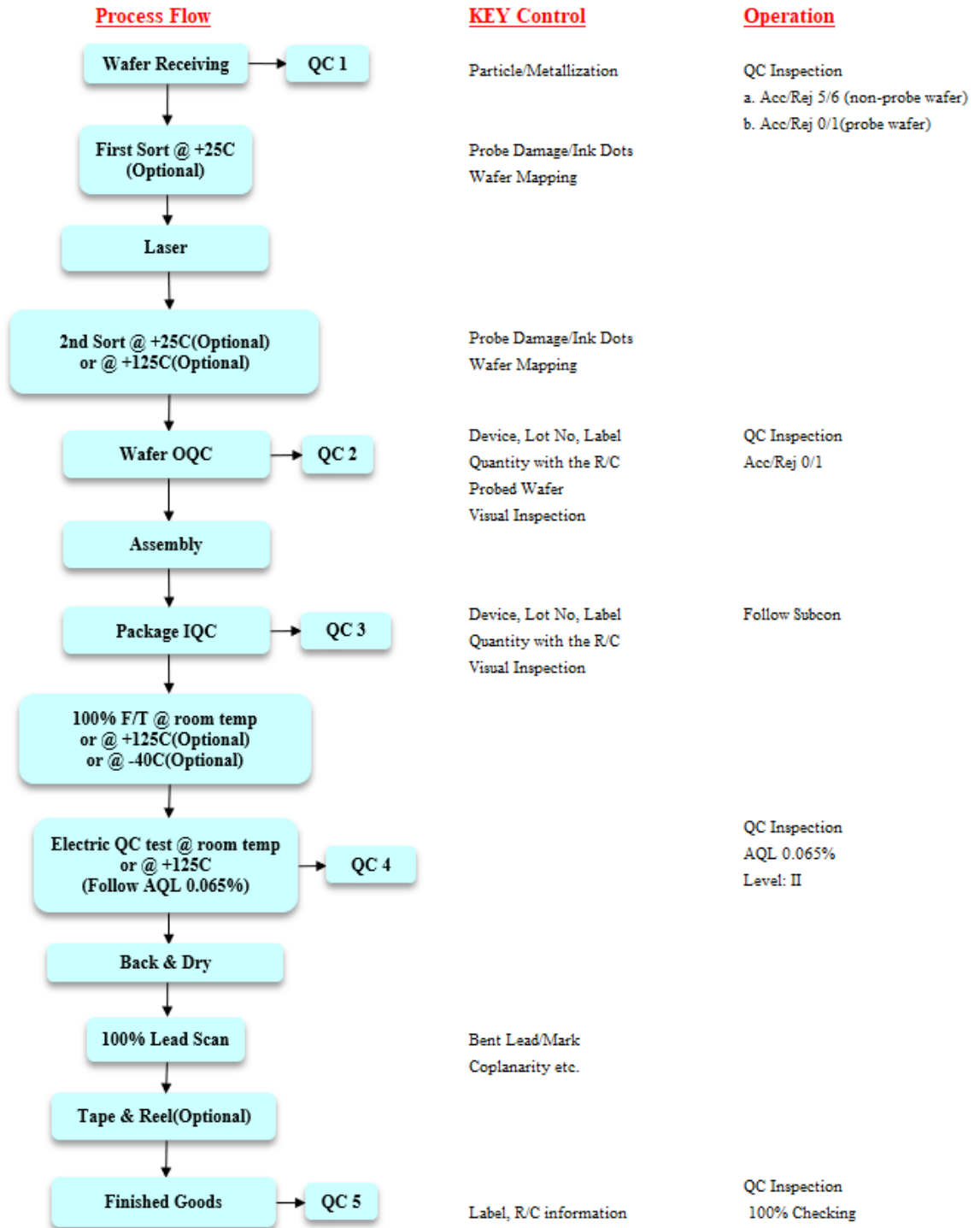


Figure 1-11 General Connectivity Test Flow & Control

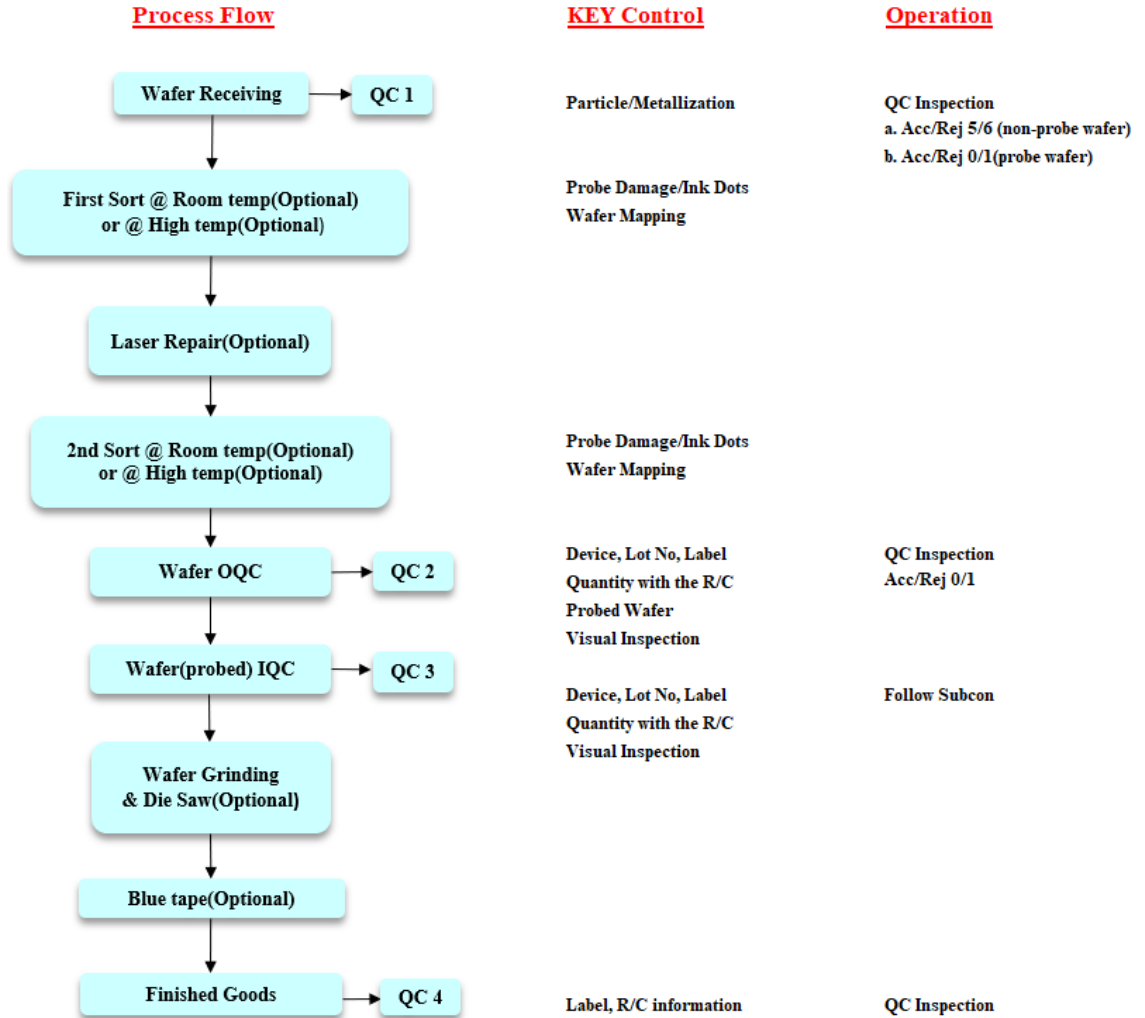


Figure 1-12 General Known Good Die Test Flow & Control

1.4.4. Quality Assurance of Product Shipping

Checks are carried out to ensure that the quality control established in the development and manufacturing stages is being reliably executed. Shipping inspections are performed to confirm the quality assurance of each lot in order to ensure the quality and reliability of shipped products.

The shipping inspection includes visual check and sampling of electrical characteristics. Visual check consists of checks on lead bending, marking defects, chipping, voids and defects. Electrical characteristics involve DC and AC characteristics as described in (section 1.4.4.) "Monitoring Data for AOQL".

After the final inspection, judgment is made to confirm that the electrical specifications, appearance and packing condition of shipped products satisfy the specifications demanded by customers.

Monitoring Data for AOQL

LUMISSIL establishes outgoing quality level target, measurement and procedure for continuous improvement.

- a) The target of outgoing quality level for LUMISSIL products is less than 20 ppm for Analog/Analog_MCU/Connectivity products. This target is periodically reviewed by management representative to approach the goal of zero defects.
- b) All the device types will be measured to establish the outgoing quality level. QRA shall issue Quality Deviation Notice (QDN) or Vendor Corrective Action Report (VenCAR) for the devices that fall below the targeted quality level and require analysis improvement until the desired quality level is achieved.
- c) The average outgoing quality level (AOQL) is sampled from the LUMISSIL inventory parts, and the sample lots should be included to be tested by each testing subcontractor.

Outgoing quality levels will be published by QRA and distributed to appropriate persons.

For Connectivity products, there are very few devices in stock and the AOQL is not monitored at present.

1.5. Customer Complaints

1.5.1. LUMISSIL RMA Process

Field quality information is an essential factor for improvement of product quality. Equally important are the investigation of field failures and feedback of results to the customers.

When a customer desires to return product, a return material authorization (RMA) form identifying the customer, the product, and the nature of the customer's concern should be completed. There are six types of returned material that LUMISSIL accepts from customers. These are:

1) Administrative:

Customer received wrong parts, wrong quantity, order entry error, duplicate shipment barcode label errors, etc. Shipping discrepancies must be reported within 60 days of shipment.

2) Customer Convenience:

Customer doesn't want the parts even though they are what they ordered and work according to specification.

3) Electrical:

Parts failed to function as specified or did not work in the application. Electrical RMAs usually require an FA.

4) Failure Analysis:

Customer has requested in depth failure analysis on returned part(s)

5) Stock Rotation:

Product returned from distributors

6) Visual/Mechanical:

Visual inspection failures such as bent leads, coplanarity, tape & reel

If the RMA involves a quality issue, a FA RMA is requested and the appropriate failure analysis engineer is immediately notified. A customer who needs to receive information

on the cause of the failure can request failure analysis to be performed. For automotive product, within 24 hours of LUMISSIL QRA's receipt of the returned product, a preliminary report will be issued, to verify the customer complaint. For non-automotive product, a preliminary report will be issued within 48 hours of LUMISSIL QRA's receipt of the returned product to verify the customer complaint.

If the product function meets LUMISSIL specifications, the customer will be contacted and the application will be investigated.

If, on the other hand, the product proves to be defective, a failure analysis will be done to determine the cause and corrective action will be taken. Within two weeks of LUMISSIL QRA's receipt of the returned product, the customer will receive a final report documenting the completion of the failure analysis and the cause of the failure.

1.5.2. RMA Flow Chart

LUMISSIL has developed procedures and e-RMA system for providing and controlling returns from customers for failure and non-failure issues. See flow as shown in Figure 1-12 for failure issues.

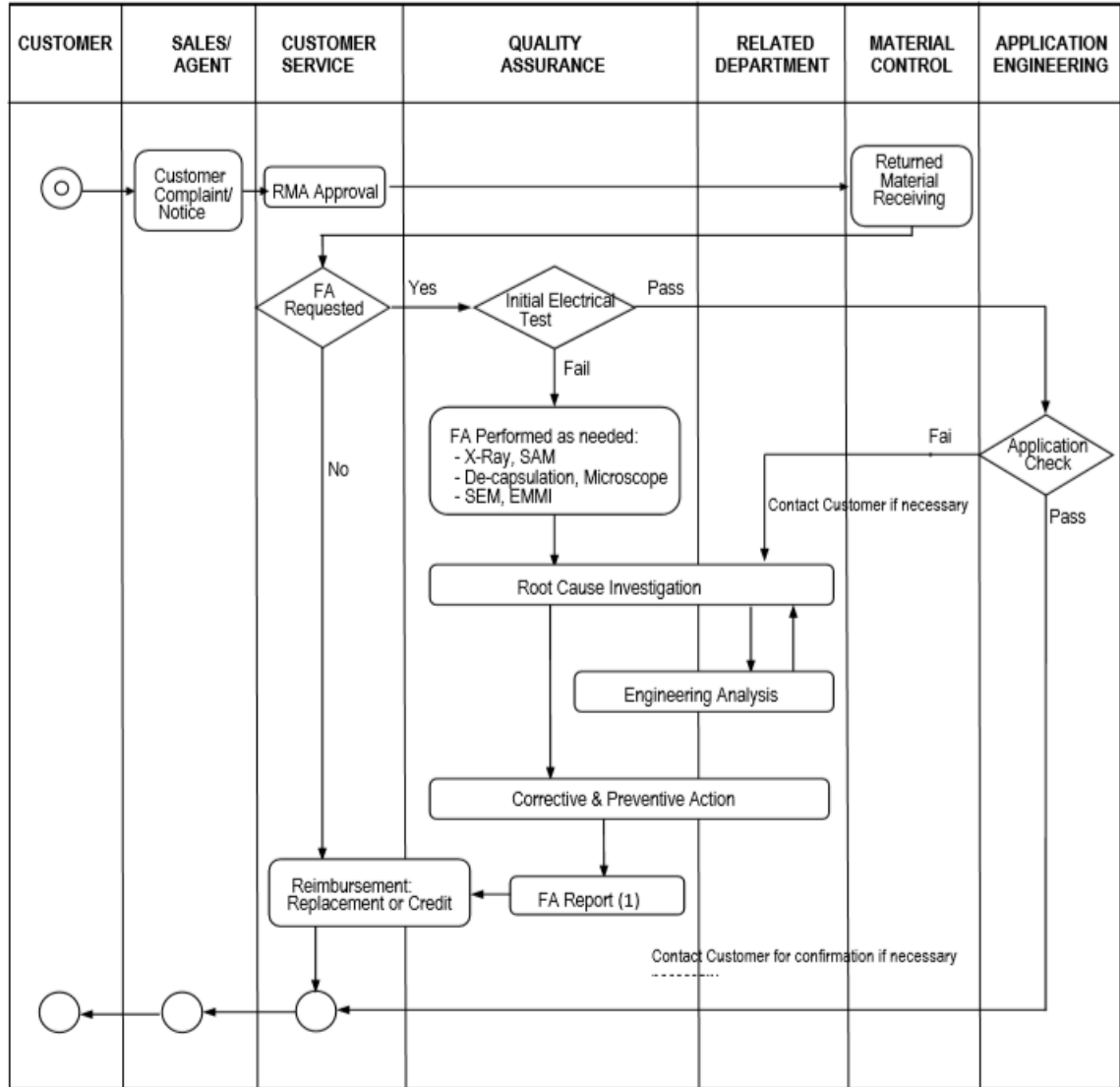


Figure 1-12. RMA Process Flow

1.5.3. Corrective Action

For LUMISSIL's commitment to continuous quality improvement, a corrective action request (CAR) procedure is established according to the ISO 9001:2015 and JEDEC 671 standard. The Corrective Action methodology follows the 8 Discipline process.

LUMISSIL shall take action to eliminate the cause of non-conformities in order to prevent recurrence. Corrective actions shall be appropriate to the effects of the non-conformities encountered. A documented procedure shall be established to define requirements for

- 1) reviewing non-conformities (including customer complaints),
- 2) determining the causes of non-conformities,
- 3) evaluating the need for action to ensure that non-conformities do not recur,
- 4) determining and implementing action needed,
- 5) recording the results of action taken, and
- 6) reviewing corrective action taken
- 7) verifying that the action taken is effective.

1.5.4. Preventive Action

LUMISSIL shall determine action to eliminate the causes of potential non-conformities in order to prevent their occurrence. Preventive actions shall be appropriate to the effects of the potential problems. A documented procedure shall be established to define requirements for

- 1) determining potential non-conformities and their causes,
- 2) evaluating the need for action to prevent occurrence of non-conformities,
- 3) determining and implementing action needed,
- 4) records of results of action taken, and
- 5) reviewing the preventive actions taken.

e-CAR

The electronic Corrective Action Request (e-CAR) system was established by LUMISSIL IT and QRA on K2 Platform. The e-CAR is used to record and track the most important quality issues including in-house design and operations, customer complaint, and subcontractor's processes. The data is reported to periodic corporate meeting and quarterly management review meeting.

The e-CAR system as shown in Figure 1-13 is a listing of the CAR's accumulated year to date. Each individual CAR is accessible electronically on the database. E-CAR can also be searched by date, processor or status. Online CAR is based on 8D method as shown in Figure 1-14.

K2 CustomerCAR

CAR No. _____
 RMA No. _____
 ProductGrade: ... Please Select ...
 Received Date: _____ ~ _____
 End Customer: _____
 Part No. _____
 Device: _____
 Root Cause: _____
 Dest. User (Active ID): _____
 Create Date: 2019/02/01 ~ 2021/02/02
 Status: Process Complete

Query CAR Engineering Export Admin Create CAR

| CAR No. | Dest User | ProductGrade | RMA No | Part No | Device | EndCustomer | Lot No | Date Code | RootCause | Ver A Date | Status | Create Date | Receive Date |
|----------|-----------|--------------|---------------|------------------------|--------|-------------|------------|-----------|-----------|------------|------------------|-------------|--------------|
| 2021-018 | | Auto | C01RMA-005036 | IS46LR16160G- #BLA2 | N207 | | BRJ46000X1 | 2001 | Good | 01/25/2021 | Process Complete | 01/21/2021 | 01/21/2021 |
| 2021-016 | | Auto | C01RMA-005031 | IS46LR16320B- #BLA2 | K056 | | BPL50300Y2 | 1910 | Good | 01/21/2021 | Process Complete | 01/20/2021 | 01/20/2021 |
| 2021-009 | | Auto | C01RMA-005027 | IS32CS8973C-ZNLA2 | MC03 | | CK9M0T1BZ | V1926 | | 01/17/2021 | Process Complete | 01/13/2021 | 01/14/2021 |

Figure 1-13 e-CAR system

Hit Rate

CAR

ISSI CORRECTIVE ACTION REQUEST

CAR No. 2021-009
 Ver.A 2021/01/19

| | | | |
|--------------|---------------|---------------------|-------------------|
| RMA # | C01RMA-005027 | Customer | |
| FA # | iT2021-015 | End Customer | |
| Reject Qty | 3 | Customer Tracking # | NA |
| QA Personnel | | Customer Contact(s) | NA |
| Device | MC03 | ISSI Part Number | IS32CS8973C-ZNLA2 |
| Date Code | V1926 | Lot Number | CK9M0T1BZ |
| Fab Location | | Assembly Location | |

Non-conformance:

Location of Non-conformance:
 End customer

| File Name | Download |
|--|--------------------------|
| CAR2021-009_C01RMA-005027_IS32CS8973C-ZNLA2-20210118.pdf | Download |

Figure 1-14 e-CAR Example

1.6. Change Control

Quite often, changes are made to products or manufacturing process in order to improve quality, reliability and/or productivity.

The feasibility of these changes is judged using sufficient data indicating that the change will not produce any negative effects.

When a change is planned, all related departments review the change and its potential impact. In the case of changes that have a significant effect on product, these results are conveyed in advance to customers to confirm that there is no deteriorated effect at the customer side.

After these judgments are received, if the change is acceptable, instructions are issued and initial control of floating data is performed as necessary for the final check.

The LUMISSIL change list is shown below (Table 1) and its system flow is depicted in Figure 1-15.

Table 1 LUMISSIL Change List

| <u>Item</u> | <u>Non-Auto Lead Time</u> | <u>Auto Lead Time</u> |
|---------------------------|---------------------------|-----------------------|
| Die Technology | 3 months | 6 months |
| Foundry Site | 3 months | 6 months |
| Wafer Fabrication Process | 3 months | 6 months |
| Assembly House | 3 months | 6 months |
| Assembly Process | 3 months | 6 months |
| Marking | 3 months | 6 months |
| Data Sheet | 3 months | 6 months |
| Packing | 3 months | 6 months |
| Discontinue | 6 months | 6 months |

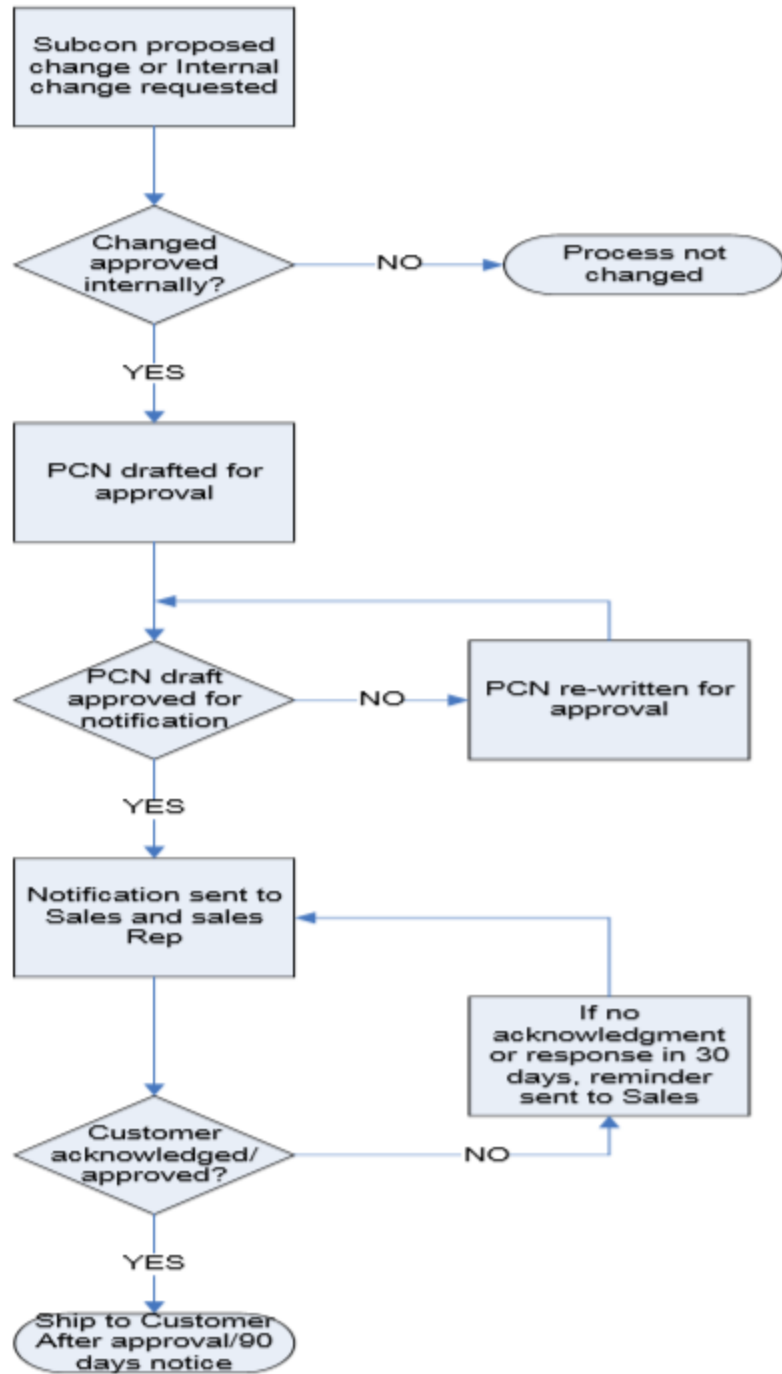


Figure 1-15 LUMISSIL Change System

1.7. Management of Subcontractors

1.7.1. Task Force

On average, 40% of production cost is due to material procurement; therefore, subcontractor management is extremely important. It follows that a substantial portion of quality problems is related to the subcontractor. Establishment of a partnership is essential in order for both parties to succeed in their business.

The subcontractor should make a positive contribution to design, production, and cost reduction. Emphasis should be placed on the total material cost, which includes that of price and quality. In order to ensure high quality, LUMISSIL QA and relevant engineering departments are performing on-site process monitoring via a task force unit as shown in Figure 1-16

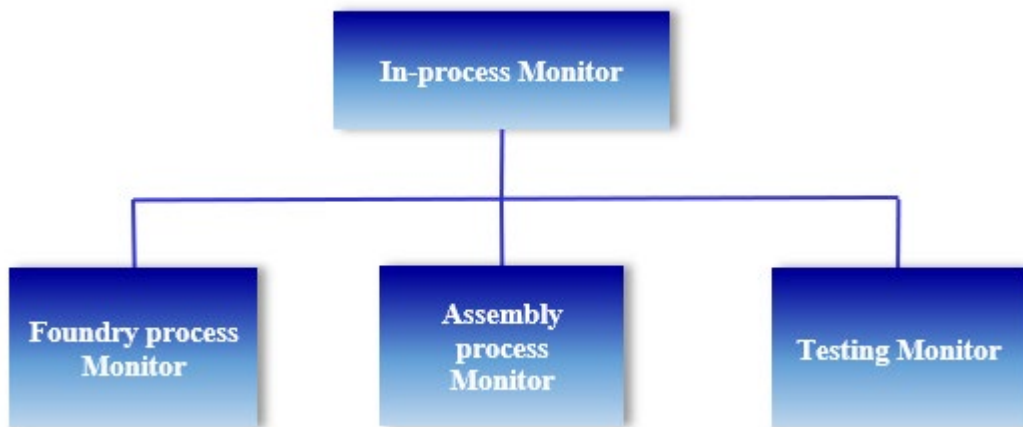


Figure 1-16

1.7.2. Methodology

Subcontractor management activities include:

- 1) Subcontractor qualification & Approved Vendor List control
- 2) Control of bill of material (BOM) and process
- 3) Package IQC
- 4) Monthly key process Cpk² (Automotive Product > 1.67 and Non-Automotive Product > 1.33) report

² Cpk is an index of process capability. It measures the process stability with respect to the standards over a certain period. To calculate Cpk, it is necessary to calculate another index, Cp, which measures the data bias toward the standard center.

- 5) Reliability monitoring (de-lamination, die crack, and solderability etc.)
- 6) Foundry/ Assembly/ Testing house rating
- 7) Monthly/ Quarterly meeting with key subcontractors
- 8) In-process monitor
- 9) Process control (Man, Machine, Material, Method)
- 10) Product output (inspect good and reject parts in each stage)
- 11) LUMISSIL finding and reporting
- 12) Subcontractor's action and continuous improvement
- 13) Review FMEA (corrections effectiveness validation)
- 14) Regular and non-regular on side audit

1.7.3. Quality Rating / Audit

Subcontractor quality ratings provide an objective measurement of a subcontractor's performance. This measurement will lead to a subcontractor review, allocation of business, and identification of the areas for quality improvement. LUMISSIL subcontractor management team conducts quarterly review meeting on subcontractors' performance, product quality and relevant business. It is not only quarterly review but also quarterly rating and ranking review meeting at LUMISSIL. In order to continuously improve product quality, LUMISSIL team informs rating and ranking to individual subcontractors in order to ask for improvement actions particularly if the rating is lower than 70%.

LUMISSIL audit team is mainly composed of senior QA engineer, QS engineer and relevant PE, RE, TD, PC engineering people. QA is the leader of annual audit team when performing audit at subcontractor site. Audits are planned at beginning of every year. The annual audit schedule is the basis of the audit plan. Also, a random audit could be performed in case of anomaly or occurrence of a serious product quality problem.

$$C_p = \frac{(\text{upper limit} - \text{lower limit})}{6\sigma} \text{ and}$$

$$C_{pk} = \frac{|\text{standard limit closest to the average value} - \text{average}|}{3\sigma}$$

where σ is the standard deviation

The vendor quality ratings are based on certain measures and are weighted as follows:

(1) For Back End:

| ELEMENT | POINT VALUE |
|----------------------|-------------|
| QUALITY | 40 |
| TECHNOLOGY | 15 |
| FLEXIBILITY/ SERVICE | 15 |
| COST | 15 |
| DELIVERY | 15 |

(2) For Foundry

| ELEMENT | POINT VALUE |
|----------------------|-------------|
| QUALITY | 30 |
| TECHNOLOGY | 30 |
| FLEXIBILITY/ SERVICE | 12 |
| COST | 18 |
| DELIVERY | 10 |

1.7.4. Supplier Relationship

Subcontractor relationship is vital to product quality. In LUMISSIL, bi-directional communication/ meetings with suppliers are periodically held to review if the supplier performance follows LUMISSIL's requirements closely. The key communication items are defined in the following diagram (Figure 1-17):

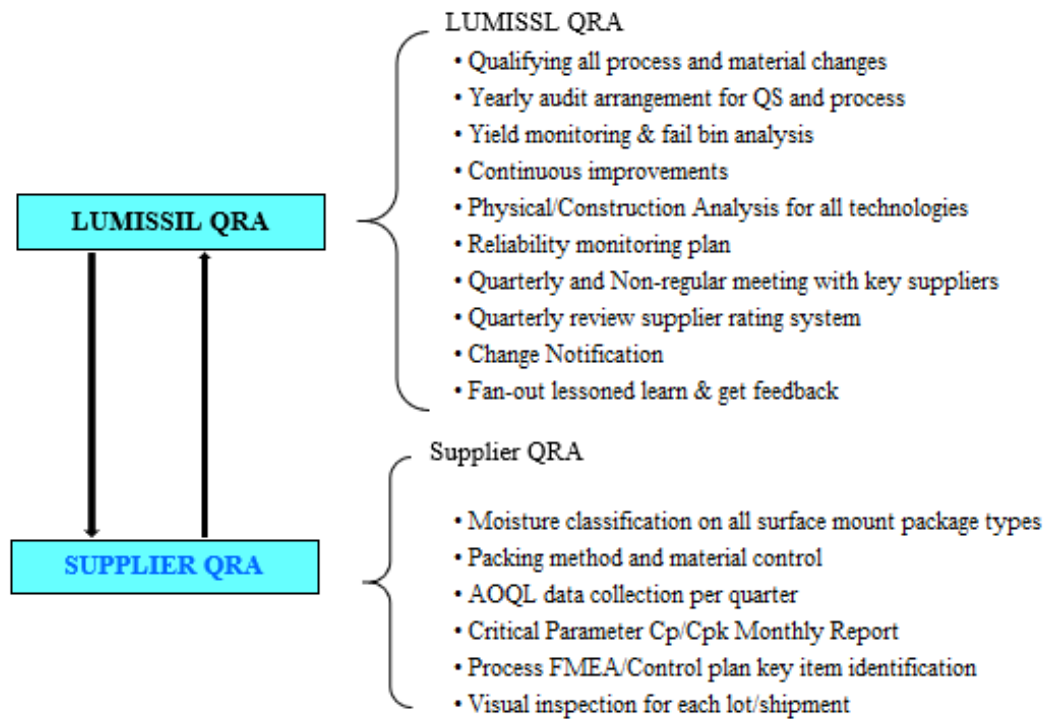


Figure 1-17. Supplier Relationship

1.7.5. Subcontractor process control

Following the process flow, the quality control flow along with the process control plan are established for producing either mature packages or advance packages at subcontractor manufacturing process. In order to avoid potential failure, the key characteristics are linked with the living document FMEA which will be reviewed regularly.

LUMISSIL products are manufactured following a developed process control flow and quality control flow. Also, the subcontractor QC staff monitors in-line process and product performance based on defined quality control plan and inspection/test criteria. In case of nonconforming product, subcontractor quality team follows defined procedure to dispose nonconforming product and inform LUMISSIL QA staff if severe quality discrepancy is found.

LUMISSIL QRA team is responsible for subcontractor management. The team coordinates with subcontractor in reviewing both process stability and product quality periodically.

If any product quality discrepancy is found, corrective action or improvement action is required. The effectiveness of correction will be tracked and verified in a timely manner by LUMISSIL QRA team depending on the severity of the nonconforming event.

1.7.6. Production line ESD control/management

Electrostatic Discharge (ESD) is well known in the semiconductor industry that the IC component could be severely damaged if the ESD program is not well maintained. The ESD protection/ wiring was built during the facility construction. In compliance to standard ANSI S20.20/JESD 625/JEDEC JS-001 and JS-002, ESD protection is widely applied in the production line such as personnel conductive garments, footwear, gloves, wrist strap, ESD flooring system, worktable mat, ionizer to neutralize the charge, conductive container. Also, there is an “ESD protected area” sign and a lock gate system installed at front door of ESD sensitive area.

Subcontractors including Foundry Fab, Assembly, Final testing and Packing houses have defined regular monitor schedule to check the personnel grounding and the connection of grounding of machine/working table/stock shelf and mobile push cart in the ESD sensitive area. Also, the ESD resistance is required to be measured and reviewed periodically.

LUMISSIL QRA staff is well trained on ESD related knowledge and have practical experiences in the production line. ESD protection is one of check items to be verified when LUMISSIL QA conducts on-site audit. The ESD verification will be commenced once there is ESD damaged product suspected until the concern can be eliminated.

1.8. Functional Safety ISO 26262 implementation

LUMISSIL kicked off ISO 26262 project in January 2021. A series of training courses, on site workshop exercises, SC-AFSP (Automotive Functional Safety Professional for Semiconductor) training/ certification and process audit will be completed in July 2022. LUMISSIL plans to start next step for First product certification by compliance with ISO 26262 standard. The estimated completion date is in December 2023.

LUMISSIL requested its subcontractor to implement ISO 26262 and get its own process certificate in order to follow LUMISSIL’s strategy to meet automotive safety requirement. It

not only starts from product design phase but also involves product production processes of whole lifecycle.

Failure Analysis

LUMISSIL Failure Analysis function is divided into two major categories. One is "Lab Service" and the other is "Internal Engineering Application". Customer Complaints utilize the Lab service and follow the prescribed FA flow and cycle time is measured. LUMISSIL has continually improved the capability of the Failure Analysis Lab to meet the increasing demands of the industry.

See FA Instrument List.

2.1. Establishment of Failure Analysis Laboratory

2.1.1. Electrical Failure Analysis (EFA) Laboratory

For the purpose of engineering debug and verification of the IC's electrical characteristic in the package levels, ASL1000 Tester, STS8200 Tester with High/Low Temperature Handler, thermal controller instrument and oscilloscope were acquired.

2.2. Physical Failure Analysis (PFA) Laboratory

LUMISSIL external FA laboratory have fully capable of performing FA works, from electrical analysis to physical failure analysis. Defects, such as gate oxide damage, via abnormality, metal damages, etc., induced during production line or field application can be detected. This FA capability helps reducing the cycle time from the product's development stage to its mature stage, improving the production yield and expediting the customer service.

2.3. Failure Analysis Function

The failure analysis function can be divided into two major categories. One is "Lab Service Items" and the other is "Internal Engineering Application". The detailed contents are listed in Figure 2-1.

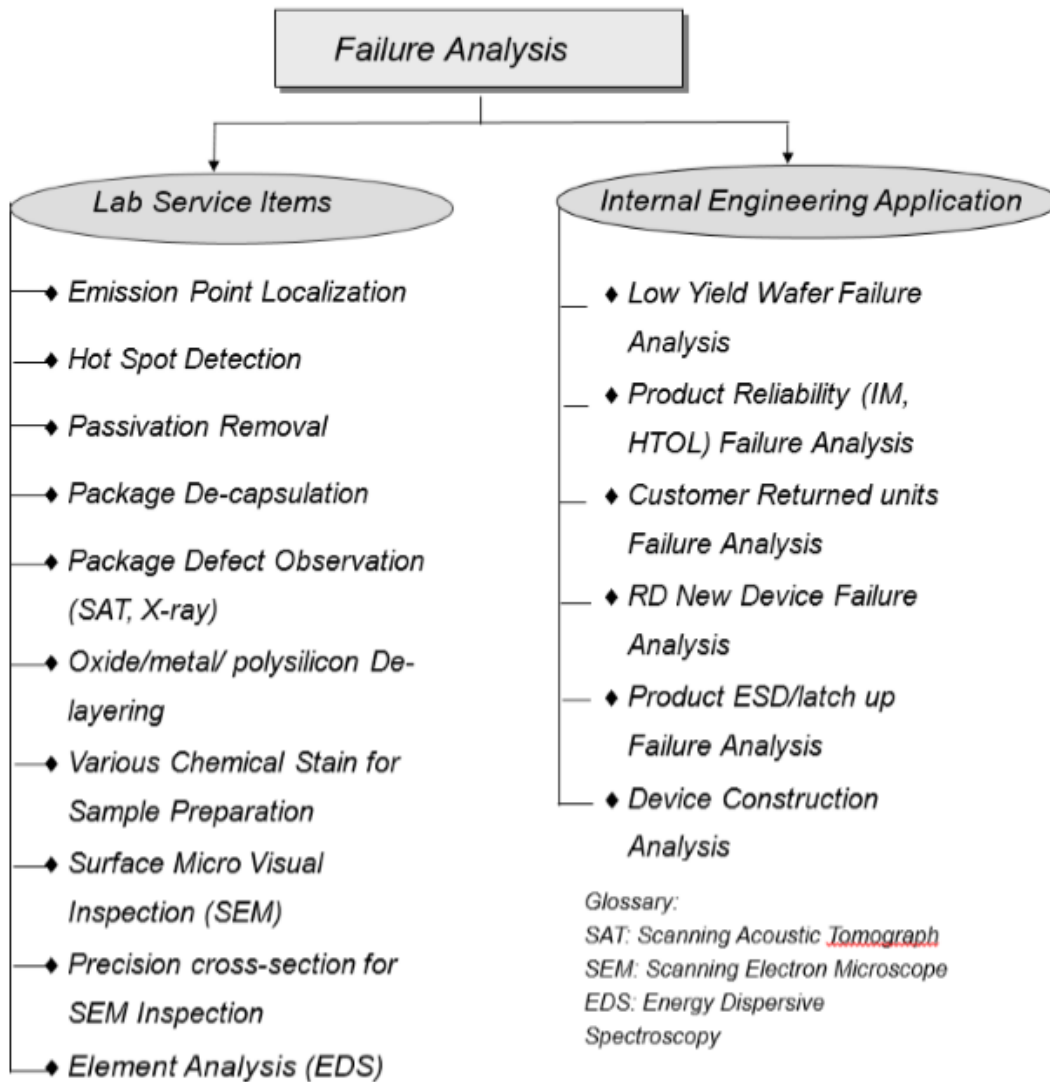
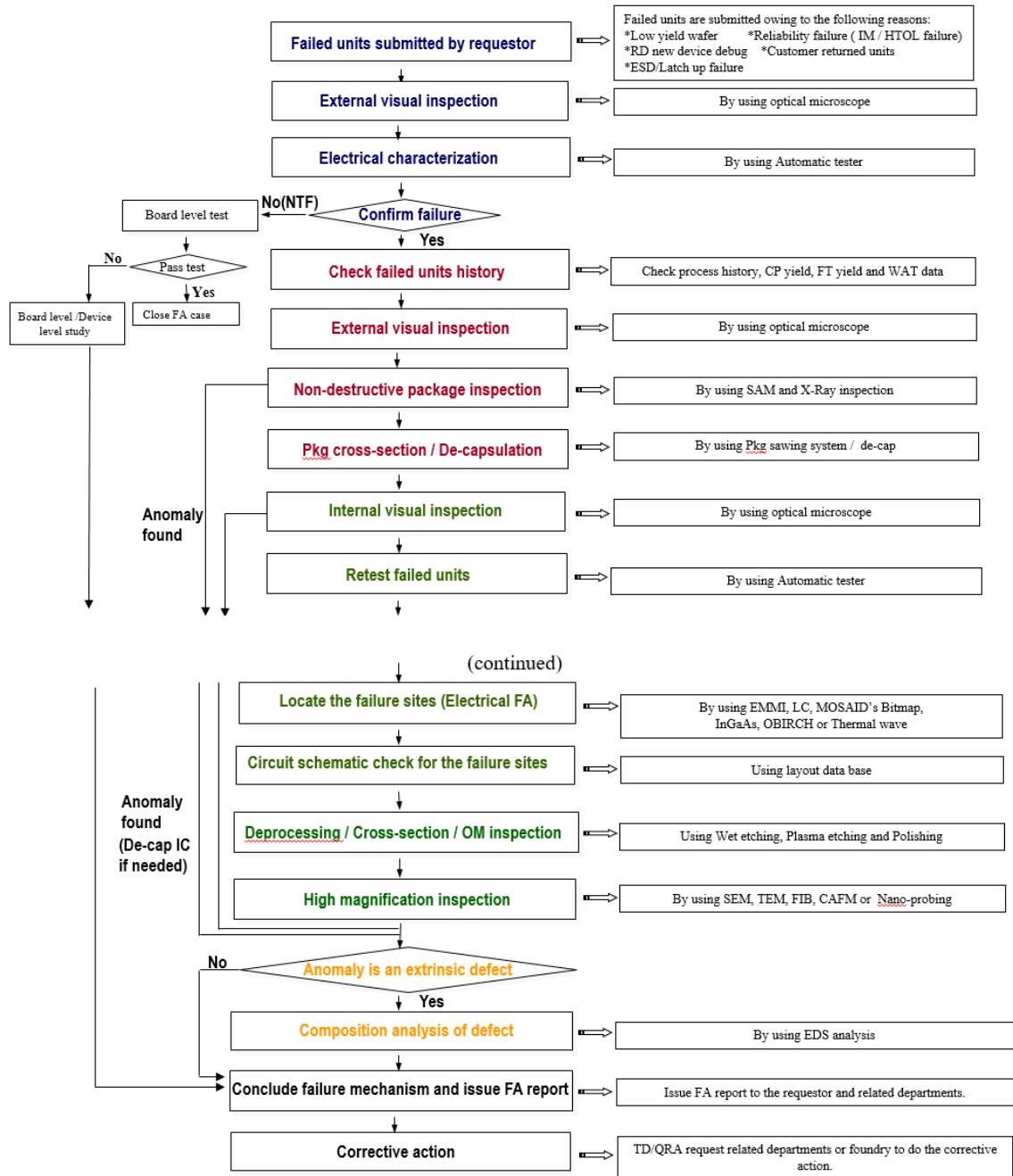


Figure 2-1. Failure Analysis Function

2.4. Failure Analysis Flow

A general failure analysis procedure is shown in Figure 2-2. The method demonstrated in the flow chart is utilized for all failure analyses.



GLOSSARY:

| | |
|--|---------------------------------------|
| SAM: Scanning Acoustic Microscope | OM: Optical Microscope |
| EMMI: Emission Microscope with Si detector | SEM: Scanning Electron Microscope |
| LC: Liquid Crystal | TEM: Transmission Electron Microscope |
| InGaAs: Emission Microscope with InGaAs detector | FIB: Focus Ion Beam |
| OBIRCH: Optical Beam Induced Resistance Change | EDS: Energy Dispersive Spectroscopy |
| CAFM: Conductive Atomic Force Microscope | FA: Failure Analysis |
| | NTF: No Trouble Found |

Figure 2-2. Failure Analysis Flow

2.5. Failure Analysis Instruments

As ULSI (Ultra-Large-Scale Integration) integration is becoming more complicated, analytical techniques and instruments become more advanced and dedicated in dealing with process related problems. LUMISSIL external laboratory currently has all the necessary analytical instruments to assist in finding solutions to process related problems.

Table 2-1 FA Instrument List

| Category | Department | TEST ITEMS | EQUIPMENT TYPE | Equipment Capability/Parameter |
|-------------------|------------|----------------------|--------------------|---|
| Material analysis | MA | Dual Beam FIB | FEI Helios | Rotating: 0° ~ 360° Tilt: -10° ~ 60° Acceleration voltage: 0.5~30KV; Magnification: X200~1200.000 Sample limit:15(W)*15(D)*0.7(H)cm |
| | | TEM | FEI TAOLS | •TEM resolution: 0.1nm •STEM resolution: 0.16nm EDS •Detector: SDD 30mm2 x 4 |
| Failure analysis | NDE | SAT | SONOSCAN | Frequency: 15MHz ~ 230MHz Scan-Spot Gap : 0.13 um Resolution: 0.1um |
| | | X-RAY | Dage | Inspection Area: 736mm X 580mm Tilting: 0° ~ 70° |
| | | 3D X-RAY | ZEISS Xredia | Resolution:1.0um Objectives : 0.4X,4X,20X Sample size limit : 300mm |
| | | 3D OM | Keyence | 20x-1000x |
| | | CP | Gatan | polishing speed:300 μm/h polishing region:20um ~ 70um sample size:1.0mm(W)×10mm(L) ×2mm (T) |
| | | Re-ball | Fineplacer | ball pitch: 0.25\0.4\0.5\1um |
| | EFA | InGaAs | PHEMOS | detected Imin:uA ; front side/backside InGaAs ; Highly sensitive in the near- infrared range of 900nm to1550nm. |
| | | OBIRCH | PHEMOS | detected Imin:uA ; front side/backside OBIRCH |
| | | Probe | PW | 6 neilsbeds;chuck size 800mm;with Probe card;detected Imin:mA |
| | | Curve Tracer | Smart | 256 channels ;Vmax=200V ; Imax=500mA; Precision:uA |
| | | Parameter Analyzer | Keisight | 4 channels ;Vmax=100V ; Imax=100mA; Precision:p A |
| | | Thermal Emmision | DCG | detected Imin:uW ; front side/backside Thermal |
| | PFA | Grinding Machine | BUHLER | 8" Grinder |
| | | Microscope | LEICA | 50x / 100x / 200x / 500x / 1000x / 1500x |
| | | 3D Microscope | Keyence | 20x-1000x |
| | | SEM | FEI-NOVANO/Hitachi | Acceleration voltage: 0.5~30KV; Magnification: X25~650000 |
| | DECAP | Plasma (ICP) etcher | SAMCO | Dry etching oxide organics |
| | | Microscope | OLYMPUS | 50x / 100x / 200x / 500x / 1000x / 1500x |
| | | 3D Microscope | Keyence | 20x-1000x |
| | | Laser-Decap | hanslaser | Al / Au /Cu Bonding Wire Decap |
| | ASS | Gold wire bond | KNS-ultra | 0.5mil/0.6mil /0.8mil/1.0mil AU wire, bonding area X axis 56mm,y axis 66 mm |
| | | Die sown | disco | 12-inch wafer, MPW |

Reliability Assurance

In the highly competitive market of semiconductors, the requirement for IC component suppliers to deliver very reliable products has resulted in an overall philosophy of quality and reliability assurance. LUMISSIL is committed to ship highly reliable products with reliability results well within specified and strict levels. To ensure the reliability standards, the rules of design, layout and processing are reviewed to cope with the new concepts during the early product development stage. Furthermore, new product/process qualifications and production reliability monitoring are performed in order to assure device performance and to accumulate statistical data.

3.1. Semiconductor Reliability

Below figure shows the time-dependent change in the semiconductor device failure rate. Discussions on failure rate change in time often classify the failure rate into three types of early, random and wear-out failure regions (the so-called “bathtub” curve). However, there is no clear definition for determining the boundary between these regions.

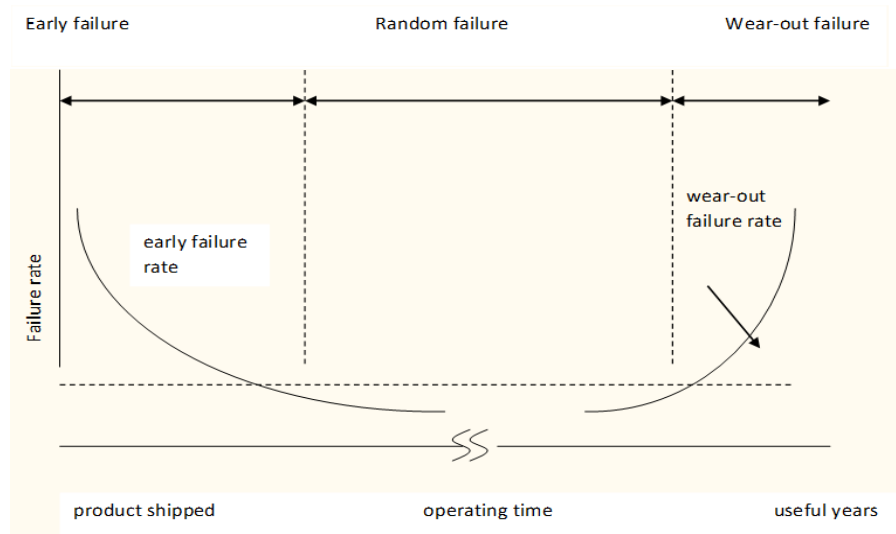


Figure 3-1: Time-Dependent Changes in Semiconductor Device Failure Rate

Early Failures

The failure rate in the early failure period is called the early failure rate (EFR), and exhibits a shape where the failure rate decreases over time. The vast majority of semiconductor device’s initial defects belong to those built into devices during wafer processing.

While most of these defects will be eliminated in the final sorting process, a certain percentage of devices with relatively insignificant defects may not have failed and may be shipped as passing products. These types of devices are inherently defective from the start and apt to fail when stress (voltage, temperature, etc) is applied for a relatively short period, and exhibit a high failure rate in a short time within the customer's mounting process. However, these inherently defective devices fail and are eliminated over time, so the rate at which early failures occur decreases.

This property of semiconductor devices where the failure rate decreases over time can be used to perform screening known as "burn-in" where stress is applied for a short time in the stage before shipping to eliminate devices containing early defects. Products screened by burn-in not only improve the early failure rate in the market, but also make it possible to maintain high quality over a long period as long as these products do not enter the wear-out failure region.

Random Failures

When devices containing early defects have been eliminated to a certain degree, the early failure rate becomes extremely small, and the failure rate exhibits a constant level over time. In this state, the failure distribution is close to an exponential distribution, and this is called the random failure period.

The device failure rate is normally at a level that can be ignored for the most part. Most of the failures are due to devices containing relatively insignificant early defects (dust or crystal defects) that fail after a long time or random failures.

Wear-out Failures

Wear-out failures are failures rooted in the durability of the materials comprising semiconductor devices and the transistors, metal lines, oxide films and other elements. In this region, the failure rate increases with time until ultimately all the devices fail or suffer characteristic defects.

The main wear-out failure mechanisms for semiconductor devices are as follows:

- Time-dependent dielectric breakdown (TDDB)
- Hot carrier-induced characteristics fluctuation

- Electromigration

Semiconductor device life is defined as the time at which the cumulative failure rate for the wear-out failure mode reaches the prescribed value, and is often determined by the reliability of each element comprising the device during the process development stage. These evaluation results are incorporated into design rules in the form of allowable stress limits to suppress wear-out failures in the product stage and ensure long-term reliability.

3.2. Failure Rate Calculation

Two functions are often used in the evaluation of reliability: probability density function (pdf) of failure $f(t)$ and failure rate $\lambda(t)$.

$f(t)$ denotes the probability of a device failing in the time interval dt at time t . It is related to the Cumulative Distribution Function (CDF), $F(t)$, as $f(t) = dF(t)/dt$.

On the other hand, failure rate $\lambda(t)$ is defined as the instantaneous failure rate of devices having survived to time t . Using the concept of conditional probability, $P(B|A) = P(B \text{ and } A \text{ both occur})/P(A)$, it can be derived that $\lambda(t)$ equals $f(t)/R(t)$ as shown below.

$$\text{instantaneous failure probability} = \frac{\text{fail in next } \Delta t}{\text{survive to } t} = \frac{F(t + \Delta t) - F(t)}{R(t)}$$

$$\text{instantaneous failure rate} = \lambda(t) = \frac{\lim_{\Delta t \rightarrow 0} \left[\frac{F(t + \Delta t) - F(t)}{\Delta t} \right]}{R(t)} = \frac{f(t)}{R(t)}$$

In the following discussion, the failure rate calculation is described according to the stages of product lifespan.

3.2.1. Methods for Estimating the Early Failure Rate

Weibull distribution is applied to approximate the CDF of early failure period; it can exhibit a shape where the failure rate decreases over time.

Weibull distribution is characterized by two important parameters, scale factor (α) and shape factor (β). They are defined as:

$$F(t) = 1 - \exp\left[-\left(\frac{t}{\alpha}\right)^\beta\right] = 1 - R(t)$$

where t : life cycle or life time (EFR duration to failure)

α : scale factor or characteristic function

β : shape factor or shape parameter

Rearranging the equation, one obtains:

$$1 - F(t) = \exp\left[-\left(\frac{t}{\alpha}\right)^\beta\right]$$

$$\ln[1 - F(t)] = -\left(\frac{t}{\alpha}\right)^\beta$$

$$\ln[-\ln(1 - F(t))] = \beta \ln t - \beta \ln \alpha$$

When plotted in $\ln[-\ln(1 - F(t))]$ against t on log scale (Below figure) , the data should approximately fall on a straight regression line. Scale factor α can be obtained from the intercept of the straight line; it is constant for a fixed test condition. Shape factor β is the slope of the straight line and its value is less than one for early failure period.

Using the relationships that $f(t) = dF(t)/dt$ and $\lambda(t) = f(t)/R(t)$, one can derive the failure rate as:

$$\lambda(t) = \frac{\beta t^{\beta-1}}{\alpha^\beta}$$

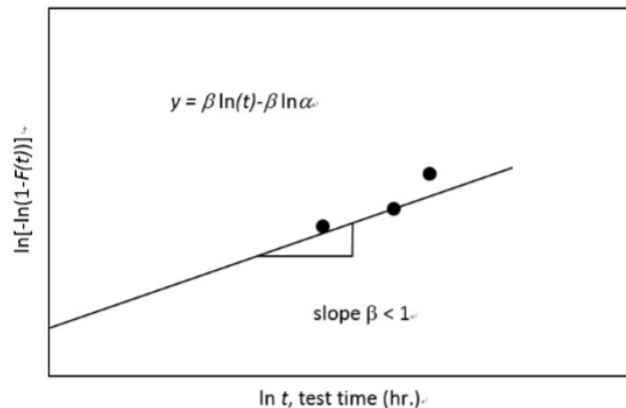


Figure 3-2 - $\ln t$, test time (hr.) VS $\ln[-\ln(1-F(t))]$

3.2.2. Methods for Estimating the Useful Life Failure Rate

When devices containing early defects have been eliminated to a certain degree, the initial failure rate becomes extremely small, and the failure rate exhibits a gradually declining curve over time. The failure rate at this period is obtained by dividing the number of failures observed by the device hours, usually expressed as failures per billion device hours (FITs). This is called point estimate because it is obtained from observation on a portion (sample) of the population of devices. In order to determine the unknown population parameter from known sample statistics, it is necessary to make use of specific probability distribution. The chi-square distribution (χ^2) that relates observed and expected frequencies of an event is frequently used. The relationship between failure rate at stress conditions and the chi-square distribution is shown in the following formula:

$$\lambda_{stress} = \frac{\chi^2(\alpha, n)}{2t}$$

Where:

λ_{stress} = failure rate at stress conditions

χ^2 = chi-square function

α = (100 - confidence level) / 100

n = degree of freedom = $2r + 2$

r = number of failures

t = device hours

The chi-square values for α equal to 60% and 90% at γ between 0 and 12 are shown in below table.

| Chi-Square Distribution Function | | | |
|----------------------------------|-------------------|----------------------|-------------------|
| 60% Confidence Level | | 90% Confidence Level | |
| No. Fails | χ^2 Quantity | No. Fails | χ^2 Quantity |
| 0 | 1.833 | 0 | 4.605 |
| 1 | 4.045 | 1 | 7.779 |
| 2 | 6.211 | 2 | 10.645 |
| 3 | 8.351 | 3 | 13.362 |
| 4 | 10.473 | 4 | 15.987 |
| 5 | 12.584 | 5 | 18.549 |
| 6 | 14.685 | 6 | 21.064 |
| 7 | 16.780 | 7 | 23.542 |
| 8 | 18.868 | 8 | 25.989 |

Since all the reliability tests are performed under accelerated stress condition, it is important to evaluate the acceleration factor of different stresses.

1) Thermal Acceleration Factor

Acceleration factor for thermal stress is calculated using the Arrhenius equation:

$$AF_t = e^{\left[\frac{E_a}{k} \left(\frac{1}{273 + T_{use}} - \frac{1}{273 + T_{stress}} \right) \right]}$$

where: AF_t = thermal acceleration factor 3
 E_a = activation energy in electron Volts (eV)
 k = Boltzmann's constant 8.62×10^{-5} eV / °K
 T_{use} = junction temperature at normal use condition in °C
 T_{stress} = the stress temperature in °C

2) Voltage Acceleration Factor

³ The activation energy is defined as the excess free energy over the ground state that must be acquired by an atomic or molecular system in order that a particular process can occur. Examples are the energy needed by the molecule to take part in a chemical reaction, by an electron to reach the conduction band in a semiconductor, or by a lattice defect to move to a neighboring site. (Ref. Van Nostrand's Scientific Encyclopedia) LUMISSIL's failure rate calculations are based on acceleration from high temperature where thermal activation energy, E_a , is typically identified in JEDEC Standard.

High electrical field can cause physical damage in the oxide layers. The acceleration factor due to voltage stress is a function of both the stress voltage, V_{stress} , and the wafer process. AF_v can be derived from Eyring model as:

$$AF_v = e^{\gamma(V_{stress} - V_{use})}$$

where: AF_v = voltage acceleration factor
 γ = constant in 1/V
 V_{stress} = stress voltage
 V_{use} = use voltage

3.2.3. Humidity Acceleration Factor

For humidity acceleration test, the acceleration factor can be estimated by

$$AF_h = \left(\frac{RH_{stress}}{RH_{use}} \right)^m$$

where : RH_{stress} = relative humidity in stress
 RH_{use} = relative humidity in use (typical value 17.6%)
 m = experimentally determined (typical value $m = 3$)

If temperature is included in the humidity test, both temperature and humidity acceleration factor need to be considered.

In THB test (Temp/Humidity/Bias), the voltage acceleration factor must be added. The junction heating effect can reduce the relative humidity. For example, a 5°C junction heating effect by bias can reduce the RH from 85% to 73%.

3.2.4. Temp Cycling Acceleration Factor

The acceleration factor can be estimated by

$$AF_{tc} = \left(\frac{T_{\max, stress} - T_{\min, stress}}{T_{\max, use} - T_{\min, use}} \right)^n$$

where : $T_{\max, stress}$ = high temp in cycling stress

$T_{\min, stress}$ = low temp in cycling stress

$T_{\max, use}$ = high temp in field application, usually 70°C

$T_{\min, use}$ = low temp in field application, usually 0°C

n = experimentally determined, usually $n = 5$

3.2.5. MTTF at Use Conditions

The mean-time-to-failure (MTTF) is defined as the average time-to-failure (or expected time-to-failure) for a population of devices, when operating its required function under the specified conditions for a stated period of time. It can be expressed by:

$$MTTF = \int_0^{\infty} tf(t)dt$$

The overall relationship of $F(t)$, $R(t)$, $f(t)$, $\lambda(t)$ and MTTF can be depicted as below figure.

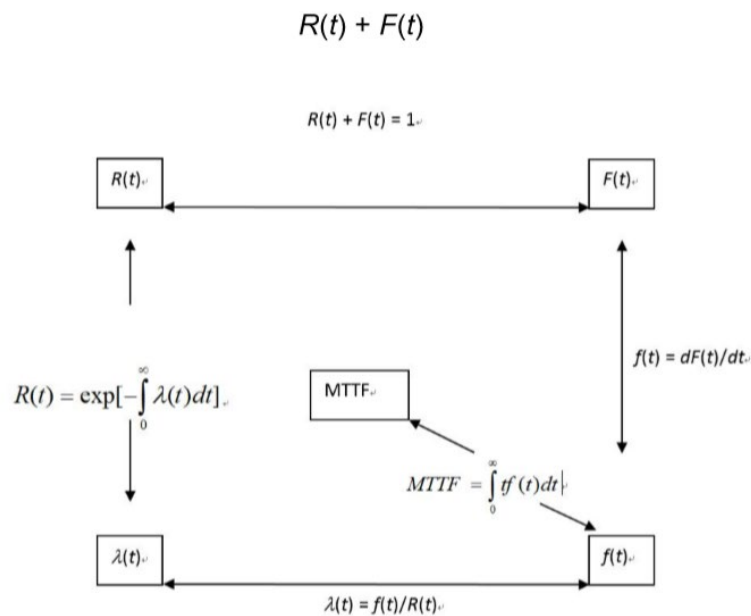


Figure 3-3. The overall relationship of $F(t)$, $R(t)$, $f(t)$, $\lambda(t)$ and MTTF

For the case of constant failure rate ($\lambda(t) = \text{constant}$), $R(t) = \exp(-\lambda t)$, $F(t) = 1 - \exp(-\lambda t)$ and $f(t) = dF(t)/dt = \lambda \exp(-\lambda t)$

$$\text{MTTF} = \int_0^{\infty} t f(t) dt = \int_0^{\infty} t \lambda \exp(-\lambda t) dt = \frac{1}{\lambda_{use}}$$

where the point estimate of the failure rate at use conditions is calculated as:

$$\lambda_{use} = \frac{\lambda_{stress}}{AF_t \times AF_v}$$

3.3. New Product/Process Qualification

The products used for reliability testing are representative of all device families, package families, foundry locations, and assembly locations. The standards referenced by LUMISSIL are JEDEC Standard 22 and MIL-STD-883, which have been universally used throughout the semiconductor industry.

Reliability is defined as the probability that a semiconductor device will perform its required function under the specified conditions for a stated period of time. The probability of survival prior to time t , $R(t)$, plus the probability of failure, $F(t)$, is always unity. Expressed as a formula:

$$R(t) + F(t) = 1, \text{ or } R(t) = 1 - F(t)$$

The probability of survival and failure is derived from the observed results of actual stress tests performed on the devices. High Temperature Operating Life (HTOL) will determine the expected failure rate, $\lambda(t)$, under operating conditions. The other reliability tests, which are described in below, accelerate other expected conditions and contribute further survival /failure rates for both die/process and package.

3.3.1. Die/Process Reliability Tests

1) High Temperature Operating Life Test (HTOL)

(Refer to JEDEC 22-A108)

High temperature operating life test is performed to accelerate failure mechanisms that are activated by temperature while under bias. This test is used to predict long-term

failure rates since acceleration by temperature is understood and the calculation for acceleration factor is well established. Prior to HTOL, all test samples are screened to standard electrical tests at low temperature and high temperature with prior burn-in. Dynamic operating conditions are applied to most cases and the test circuit is depending on the specific device. The typical stress voltage is 1.1 times of normal operating voltage. Unless otherwise specified, the stress temperature is maintained at 125 °C. Devices are tested at prescribed time-points. Failure rates are calculated in terms of FITs (failures in time). Each FIT represents one failure in 10⁹ device-hours.

2) Electrostatic Discharge (ESD)

(Refer to ANSI/ESDA/JEDEC JS-001 and JS-002)

Electrostatic discharge sensitivity (ESD) tests are designed to measure the sensitivity of each device with respect to electrostatic discharges that may occur during device handling. Various test methods have been devised to analyze ESD. Currently, LUMISSIL evaluate ESD using the following test methods. The human body model (HBM) is in accordance with the standard specified by ANSI/ESDA/JEDEC JS-001 while the charge device model (CDM) is by ANSI/ESDA/JEDEC JS-002.

The human body model is based on a high-voltage pulse (positive and negative) of longer duration, simulating discharge through human contact. The charge device model is based on the phenomenon where the semiconductor device itself carries a charge or where the charge induced to the device from charged object near the device is discharged. It reproduces the discharge mechanism in the form closest to the discharge phenomenon occurring in the field.

3) Latch-up

(Refer to JEDEC standard No. 78)

The latch-up test is designed specifically for CMOS processed devices to detect parasitic bipolar circuits that, when activated, may short power and ground nodes. Test conditions are significantly worse than normal operation variations to provide a margin for safe operation. Presently, LUMISSIL evaluates latch-up based on JEDEC standard No. 78. For JEDEC standard, current (positive and negative) is injected into individual

input/output pins in steps while the power supply current is monitored. The current into the test pin must rise to a minimum of 100 mA without a latch-up condition.

4) Endurance Cycling

(Refer to MIL-STD-883 1033, JEDEC 22- A117, JEDEC 47)

The test is used to evaluate the quality of the tunnel oxide of Flash products. Continued program-erase operation can cause charge trapping or even breakdown in the tunnel oxide, resulting in threshold shift and eventually failure of a cell to retain data. The test requires typical 100k cycles at room temperature and high temperature. Large electrical field changes between the gate and drain of the memory cell can also cause damage of the oxide layer.

5) Data retention

(Refer to JEDEC 22- A117, JESD 47)

The test is to measure the stability of electron in the floating gate of Flash products. Devices are exposed to high temperature, typically, 125 or 150 °C, which causes acceleration of charge loss or gain, resulting in shifting of threshold voltage. No bias is needed for this test. Charge trapping or defect in tunnel oxide and other dielectric, mobile ion contamination may contribute to the degrading of data retention performance.

3.3.2. Package Reliability Tests

1) Highly Accelerated Stress Test (HAST)

(Refer to JEDEC 22 - A110)

The highly accelerated stress test provides constant multiple stress conditions including temperature, humidity, pressure, and voltage bias. It is performed for the purpose of evaluating the reliability of non- hermetic packaged devices operating in the humid environments. The multiple stress conditions accelerate the penetration of moisture through the package mold compound or along the interface between the external protective materials and the metallic conductors passing through package. When moisture reaches the die surface, the applied potential establishes an electrolytic condition that corrodes aluminum conductors and affects DC parameters of the device.

Presence of contaminants on the die surface such as chlorine greatly accelerates the corrosion process. Additionally, excessive phosphorus in the passivation will react under these conditions.

2) Unbiased Autoclave (Pressure Cooker Test)

(Refer to JEDEC 22- A102)

The autoclave test is performed to evaluate the moisture resistance of non-hermetic packaged units. Devices are subject to pressure, humidity, and elevated temperature to accelerate the penetration of moisture through the molding compound or along the interface of the device pins and molding compound. Expected failure mechanisms include mobile ionic contamination, leakage along the die surface, or metal corrosion caused by reactive agents present on the die surface. The autoclave test is performed in a pressure chamber capable of maintaining temperature and pressure. Steam is introduced into the chamber until saturation, then the chamber is sealed and the temperature is elevated to 121 °C, corresponding to a pressure of 30 psia (2 atm). This condition is maintained for the duration of the test. Upon completion of the specified time, the devices are cooled, dried and electrically tested. (Note: PCT is not applied for organic substrate package.)

3) Temperature Cycling Test (TCT)

(Refer to JEDEC 22- A104)

Temperature cycling test accelerates the effects that changes in the temperature will cause damage between different components within the specific die and packaging system due to different thermal expansion coefficients. Typical examples of damage caused by this test include package cracking, cracking or cratering of the die, passivation or metal de-lamination, and more subtle damage resulting impaired electrical performance. During testing devices are inserted into a chamber where the interior is cycled between specified temperatures and held at each temperature for a minimum of one minute. Temperature extremes depend on the condition selected in the test method. The total stress corresponds to the number of cycles completed at the specified temperature.

4) High Temperature Storage Life Test (HTSL)

(Refer to JEDEC 22-A103)

The high temperature storage test is typically used to determine the effects of time and temperature, under storage conditions, for thermally activated failure mechanisms and time-to-failure distributions of solid state electronic devices, including nonvolatile memory devices (data retention failure mechanisms). Unless otherwise specified, the stress temperature is maintained at 150 °C.

5) Preconditioning Test (Moisture Sensitivity)

(Refer to JEDEC 22- A113, J-STD-020)

Surface mount packages may be damaged during the solder reflow process when moisture in the package expands rapidly. Two test methods are utilized to determine which packages may be sensitive and what level of sensitivity exists. JEDEC test method A113 establishes the reliability of devices exposed to a specified preconditioning process at various moisture levels by subjecting preconditioned devices to HAST, PCT and TCT. The test result determines whether dry packing is necessary to ensure the reliability of the product after the assembly process.

6) Solderability

(Refer to J-STD-002)

The solderability test is used to determine the ability of package leads wetted by solder. This test verifies that the method of lead treatment to facilitate solderability is satisfactory and will allow successful solder connection to designated surface.

(a) For Lead Frame package, the test is accomplished by immersing leads in flux then dipping the leads into molten solder of 215°C ± 5°C for non Pb free or 245°C ± 5 °C for Pb free. No less than 95% coverage of the dipped area should be shown on each lead.

(b) For Substrate package, the reflow temperature IR Reflow Soldering is Pb-free: 230~245°C and SnPb: 215~230°C.

7) Mark Permanency

(Refer to JEDEC 22-B107)

The mark permanency test subject's package marking to solvents and cleaning solution commonly used for removing solder flux on circuit boards to ensure the marking will not become illegible. Devices and a brush are immersed into one of three specified solvents for one minute, and then removed. The devices are then brushed ten strokes. This process is repeated three times for each group of solvents and devices. After they are rinsed and dried, the devices are examined for legibility according to specified criteria.

8) Lead Integrity

(Refer to JEDEC 22-B105)

The lead integrity test provides tests for determining the integrity of devices leads, welds and seals. Devices are subject to various stresses including tension, bending fatigue and torque appropriate to the type of lead. Devices are then examined under optical microscope to determine any evidence of breakage, loosening or motion between the terminal and device body.

9) Solder Ball Shear

(Refer to JEDEC 22-B117)

This test method is used to assess the ability of solder balls to withstand mechanical shear forces that may be applied during device manufacturing, handling, test, shipment, and end-use conditions.

10) Bond Pull and Shear

(Refer to MIL-STD-883, Method 2011)

The purpose of these tests is to measure bond strength, evaluate bond strength/bond strength distributions or determine compliance with specified bond strength requirements of the applicable acquisition document.

11) Bump Shear Test

(Refer to JEDEC 22-B117)

This test method is used to assess the ability of bumps to withstand mechanical shear forces that may be applied during device manufacturing, handling, test, shipment, and end-use conditions.

3.4. Qualification Test Method and Acceptance Criteria

The summary shown in following tables give brief descriptions of the various reliability tests.

Not all of the tests listed are performed on each product and other tests can be performed when appropriate.

Table 3-1: Qualification Test Method and Acceptance Criteria

| No. | Qualification Test | Applied to | Test Method | Test Conditions | Samp. Size (Min) | Lots Req. (Min) | Rej. No. | Comments |
|-----|--|------------|--|---|------------------|-----------------|----------|--|
| 1 | High Temp. Operating Life (HTOL) | Auto | JESD22A108 | 1) T=125°C, 1000 hrs 2) V=1.1 Vcc*1 typical 3) Dynamic stress | 77 | 3 | 0 fail | 1. Grade 1: T=125°C, 1000 hrs. Vcc max* operating for both DC /AC parameter 2. F/T check before and after at low, room, and high temp. (Non-Auto: just at room temp) 3. Target failure rate < 100 FITs after 1000 hrs at 60% CL. |
| | | Non-Auto | JESD22A108 (JESD85) | 1) T=125°C, 1000 hrs 2) V=1.1 Vcc*1 typical 3) Dynamic stress | 77 | 1 | 0 fail | |
| 2 | Electrostatic Discharge-Human Body Model (ESD-HBM) | Auto | MIL-STD-883 3015.8 ANSI/ESDA/JEDEC JS-001 | 1) R=1.5kohm, C=100pF. 2) HBM \geq +/-2000V. 3) Step: 500V, 1000V, 2000V. | 3 | 1 | 0 fail | 1. Auto: 3 samples per V level, F/T check before and after at room and high temp. 2. Non-Auto: same sample for all V level, no FT check. |
| | | Non-Auto | ANSI/ESDA/JEDEC JS-001 | 1) R=1.5kohm, C=100pF. 2) HBM \geq +/-2000V. 3) Step: 500V, 1KV, 2KV, 4KV, 8KV to fail. | 3 | 1 | 0 fail | |
| 3 | Electrostatic Discharge-Charged-Device Model (ESD-CDM) | Auto | ANSI/ESDA/JEDEC JS-002 | all pins \geq ±750 volts | 3 | 1 | 0 fail | 1. FT check before and after at room and high temp (IV curve check) (Non-Auto: just at room) 2. However, the acceptance criteria may be set at other levels as specified in AEC-Q100 per customer requests. |
| | | Non-Auto | ANSI/ESDA/JEDEC JS-002 | all pins \geq ±750 volts | 3 | 1 | 0 fail | |
| 4 | Latch-up (LU) | Auto | JESD78 | 1) JEDEC-I \geq ±100mA, 2) JEDEC-V \geq +1.5Vcc max or MSV, which is less. | 6 | 1 | 0 fail | 1. F/T check before and after at room and high temp (Icc variation check for initial and F/T check for final confirm) (Non-Auto: just at room temp) 2. E-test, just for Auto product and per requests. The Test Conditions refer to AEC-Q100-004. |
| | | Non-Auto | JESD78 | 1) JEDEC-I \geq ±100mA, 2) JEDEC-V \geq +1.5Vcc max or MSV, which is less. | 3 | 1 | 0 fail | |

| | | | | | | | | |
|---|--|--------------------|----------------------------|---|-----------|--------|--------|---|
| 5 | Early Life Failure Rate (ELFR) | Auto | AEC-Q100-008 JESD22A108 | Grade 1: T=125°C, 48 hrs. Vcc max operating for both DC /AC parameter. | 800 | 3 | 0 fail | 1. Only for NVM (Non-volatile Memory), per requests. 2. Grade 1: T=125°C, 48 hrs. Vcc max* operating for both DC /AC parameter 3. F/T check before and after at room, and high temp. |
| 6 | NVM Endurance Data Retention, and Operational Life (EDR) | Auto | AEC-Q100-005 | T=150°C,1000hrs | 77 | 3 | 0 fail | 1. Only for NVM (Non-volatile Memory). 2. F/T check before and after at room, and high temp. 3. Some specific devices with different cycling count. SPEC should follow the statement in the datasheet. 4. If EDR is performed, the HTSL is not required to perform. |
| 7 | High Temperature Storage Test (HTSL) | Auto-Au | JEDEC 22-A103 | T=150°C Duration = 1000 hours minimum. | 45 | 1 | 0 fail | 1. Only for Auto part# Au & Cu wire products. 2. Non-Auto: no need or per requested. 3. F/T check before and after at room and high temp. |
| | | Auto-Cu | JESD22A103 | Grade 2 : 150 °C, 2000 hrs. After 1000hrs readpoint, need choose 1pcs/lot do cross-section. After 2000hrs readpoint, need choose 1pcs/lot do cross-section. | 45 | 3 | 0 fail | |
| | | Non-Auto (Au & Cu) | NA | NA | NA | NA | NA | |
| 8 | Pre-conditioning (PC) | Auto-Au | JESD22-A113 J-STD-020 | bake 24hrs @+125°C*, moisture soak (level 1, 168 hrs @ 85°C/85%RH, level 3, 192 hrs @ 30°C/60%RH), reflow solder IR @ 260°C, | 231 | 3 | 0 fail | 1. For all analog products. 2. Prior to TCT, PCT, HAST, PTC. 3. F/T check before and after at room temp. 4. Level 1 or 3 are performed upon package types. * For WLCSF package, applied MSL Level 1. * Clear package using bake 24hrs @+100°C. |
| | | Auto-Cu | JESD22A113 | bake 24hrs @+125°C*, moisture soak (level 1, 168 hrs @ 85°C/85%RH, level 3, 192 hrs @ 30°C/60%RH), reflow solder IR @ 260°C, | 231 45 | 3 1 | 0 fail | |

| | | | | | | | | |
|----|---------------------------------------|--------------------|--------------------------|--|-----|----|--------|---|
| | | Non-Auto (Au & Cu) | JESD22-A113 J-STD-020 | bake 24hrs @ +125°C*, moisture soak (level 1, 168 hrs @ 85°C/85%RH, level 3, 192 hrs @ 30°C/60%RH), reflow solder IR @ 260°C, | 231 | 1 | 0 fail | |
| 9 | Highly Accelerated Stress Test (HAST) | Auto-Au | JESD22-A101 JEDEC22-A110 | T=130°C, 85%RH, 33.3psia, V>=1.1V. Duration = 96 hrs minimum | 77 | 3 | 0 fail | <ol style="list-style-type: none"> 1. Only for Auto part# Au & Cu wire products. 2. Non-Auto: no need, or per requested. 3. Use LTPD=3%. 4. F/T check before and after at room and high temp. |
| | | Auto-Cu | JESD22A104 | T=130°C, 85%RH, 33.3psia, V>=1.1V. Duration =192 hrs minimum for Auto Cu After 96hrs read point, need choose each 3pcs/lot do WP&BS, 1pcs cross-section, 22pcs do SAT. After 192hrs read point need choose each 2pcs/lot do WP&BS, 1pcs cross-section, 22pcs do SAT. | 77 | 3 | 0 fail | |
| | | Non-Auto (Au & Cu) | NA | NA | NA | NA | NA | |
| 10 | Unbiased-HAST (UHAST) | Auto-Au | NA | NA | NA | NA | NA | <ol style="list-style-type: none"> 1. For Non-Auto products, perform HAST auto products. 2. FT check before and after at room temp. |
| | | Auto-Cu | NA | NA | NA | NA | NA | |
| | | Non-Auto (Au & Cu) | JEDEC22-A118 | T=130°C, 85%RH, 33.3psia. Duration = 96hrs minimum | 77 | 1 | 0 fail | |
| 11 | Temperature Cycling (TCT) | Auto-Au | JESD22A104 | T=-65°C to 150°C. Cycles =500 | 77 | 3 | 0 fail | <ol style="list-style-type: none"> 1. Grade 1: -65~150°C, 500 cycles. (Or equivalent -55°C ~125°C, 1000 cycles) 2. F/T check before and after at room and high temp (Non-Auto: just at room temp). |
| | | Auto-Cu | JESD22A104 | Grade 1: -65°C~150°C, 1000 cycles. After 500cycles read point, need choose each 3pcs/lot do WP&BS, 1pcs cross-section, 22pcs do SAT. After 1000cycles read | 77 | 3 | 0 fail | |

| | | | | | | | | |
|----|-----------------------------------|--------------------|-----------------------------|--|----|----|--------|--|
| | | | | point, need choose each 2pcs/lot do WP&BS, 1pcs cross-section, 22pcs do SAT. | | | | *Clear package T=-40°C to 85°C. |
| | | Non-Auto (Au & Cu) | JESD22A104 | T=-65°C to 150°C. Cycles =500 | 77 | 1 | 0 fail | |
| 12 | Autoclave (Pressure Cooker) (PCT) | Auto-Au | JESD22A102 | T=121°C, 100%RH. Duration =168 hrs | 77 | 3 | 0 fail | 1. 121°C/100%RH. a. 168 hrs for LF type. b. PCT is not applied for organic substrate packages. 2. F/T check before and after at room temp. |
| | | Auto-Cu | JESD22A102 | T=121°C, 100%RH Duration = 168 hrs | 77 | 3 | 0 fail | |
| | | Non-Auto (Au & Cu) | JESD22A102 | T=121°C, 100%RH, Duration = 168 hrs | 77 | 1 | 0 fail | |
| 13 | Power Temperature Cycling (PTC) | Auto-Au | JESD22A105 | Grade 0: T=-40°C to 150°C, 1000 cycles; Grade1: T=-40°C to 125°C,1000 cycles; Grade2&3:T=-40°C to 105°C,1000cycles. | 45 | 1 | 0 fail | 1. Only for Au & Cu wire Auto product. 3. F/T check before and after at room and high temp. 4. PC before PTC for surface mount devices. Test required only on devices with maximum rated power>=1watt or $\Delta T_j \geq 40^\circ\text{C}$ or device designed to drive inductive loads. |
| | | Auto-Cu | JESD22A105 | A: T=-40°C to 85°C,2000 cycles, Dwell time:10min,Transition time:20min B: T=-40°C to 125°C,2000cycles, Dwell time:10min,Transition time:30min | 45 | 1 | 0 fail | |
| | | Non-Auto (Au & Cu) | NA | NA | NA | NA | NA | |
| 14 | Physical Dimensions (PD) | Auto-Au | JEDEC 22 B100&B108 AEC Q003 | Cpk >=1.67 | 10 | 3 | 0 fail | 1. For all analog products. |
| | | Auto-Cu | JEDEC 22 B100&B108 AEC Q003 | Cpk >=1.67 | 10 | 3 | 0 fail | |
| | | Non-Auto (Au & Cu) | JEDEC 22 B100&B108 | Cpk >=1.33 | 30 | 1 | 0 fail | |

| | | | | | | | | |
|----|-------------------------|--------------------|--------------------------------------|--|-----------------------------------|---|--------|--|
| 15 | Solderability (SD) | Auto-Au | JEDEC 22-B102 method 1 J-STD-002D | 1) Steam aging - Temp: 93±3°C, Time: 8±0.25 hrs. (Optional) 2) T=245°C+/-5°C (Pb free); 215°C+/-5°C (SnPb) t=5+/-0.5sec, Lead coverage area > 95% | 15 | 1 | 0fail | 1. Only for L/F package 2. Lead coverage area > 95% |
| | | Auto-Cu | JEDEC 22-B102 method 1 J-STD-002D | 1) Steam aging - Temp: 93±3°C, Time: 8±0.25 hrs. (Optional) 2) T=245°C+/-5°C (Pb free); 215°C/-5°C (SnPb) t=5+/-0.5sec, Lead coverage area > 95% | 15 | 1 | 0fail | |
| | | Non-Auto (Au & Cu) | J-STD-002D | Characterization | 15 | 1 | 0fail | |
| 16 | Wire Bond Shear (WBS) | Auto-Au | AEC-Q100-001 AEC Q003 | Cpk >=1.67 | 30 bonds of 5 devices | 1 | 0fail | all PKG (except WLCSP) |
| | | Auto-Cu | AEC-Q100-001 AEC Q003 | Cpk >=1.67 | 30 bonds of 5 devices | 1 | 0fail | |
| | | Non-Auto (Au & Cu) | JEDEC 22-B116 | Characterization, Pre Encapsulation Cpk >=1.33 | 30 bonds of 5 devices | 1 | 0fail | |
| 17 | Wire Bond Pull (WBP) | Auto-Au | MIL-STD-883 2011 AEC Q003 | Cpk >=1.67 or 0Fail after TC(Test #A4) | 30 bonds of 5 Devices | 1 | 0 fail | all PKG (except WLCSP) |
| | | Auto-Cu | MIL-STD-883 2011 AEC Q003 | Cpk >=1.67 or 0Fail after TC(Test #A4) | 30 bonds of 5 Devices | 1 | 0 fail | |
| | | Non-Auto (Au & Cu) | MIL-STD-883 2011 | Characterization, Pre Encapsulation; Cpk >=1.33. | 30 bonds of 5 Devices | 1 | 0 fail | |
| 18 | Solder Ball Shear (SBS) | Auto-Au | AEC-Q100-010 AEC Q003 | Cpk >=1.67 | 5 balls from a min. of 10 devices | 3 | 0 fail | Only for WLCSP |
| | | Auto-Cu | AEC-Q100-010 AEC Q003 | Cpk >=1.67 | 5 balls from a min. of 10 devices | 3 | 0 fail | |

| | | | | | | | | |
|----|-------------|--------------------|---------------|---|-----------------------|---|--------|----------------------|
| | | Non-Auto (Au & Cu) | JESD22-B117 | Characterization, Pre Encapsulation ; Cpk >=1.33. | 30 bonds of 5 Devices | 1 | 0 fail | |
| 19 | Coplanarity | Auto-Au | JEDEC 22 B108 | Measured accuracies within +/-10% of specified deviation. Failure specification. Deviation=4 mil. | 5 | 1 | 0 fail | Only for SMD package |
| | | Auto-Cu | JEDEC 22 B108 | Measured accuracies within +/-10% of specified deviation. Failure specification. Deviation=4 mil. | 5 | 1 | 0 fail | |
| | | Non-Auto (Au & Cu) | JEDEC 22 B108 | Measured accuracies within +/-10% of specified deviation. Failure specification. Deviation=4 mil. | 5 | 1 | 0 fail | |

3.5. Production Reliability Monitoring

3.5.1. Philosophy of Reliability Monitoring

In order to guarantee the high standard of reliability for each wafer technology family, a reliability monitoring methodology is executed. By monitoring the data of sampling HTOL yield, RE department will determine if extended burn-in is needed for any specified lots. To screen out any potential failure parts, it is necessary to do 100% extended burn-in for the whole mother lot if the sampling HTOL result is substandard. The reliability monitoring process flow is shown in below Figure. 1.

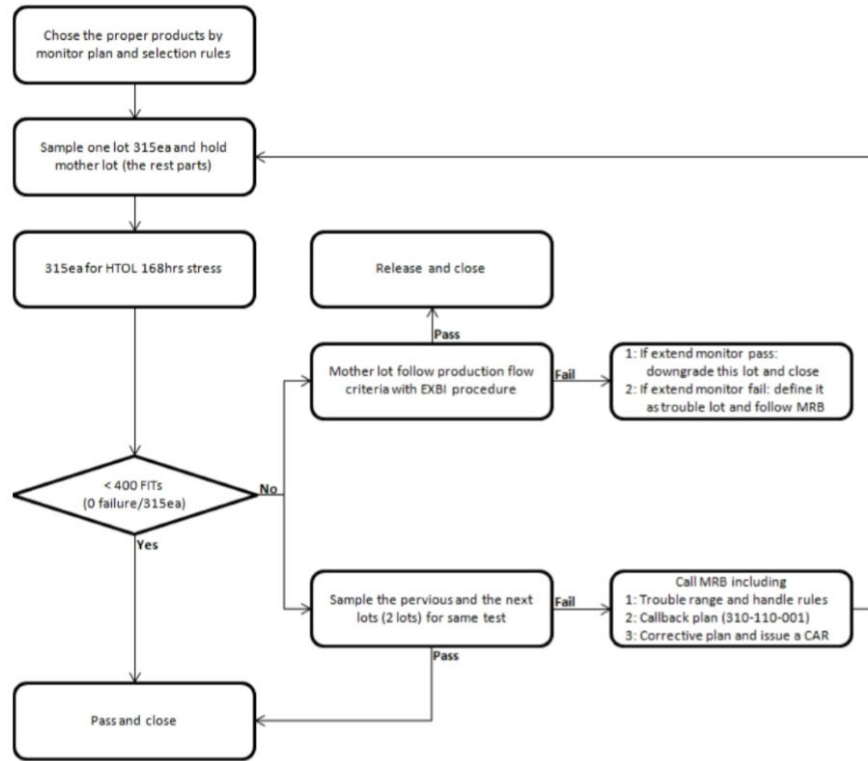


Figure 3-4. Reliability Monitor Flow

3.5.2. Reliability Monitor Procedure

The Product Reliability Monitoring should be executed following below requirement (See below Table 3-2). All these topics cover the requirement from the spec of JESD 659 Failure-Mechanism-Driven Reliability Monitoring/ section 6.

Table 3-2: Product Reliability Monitoring Requirement Table

| | Topic | Requirement |
|---|----------------------|--|
| 1 | Test Item | (1) HTOL, 168h, 125C, dynamic operating with $\geq V_{cc-max}$, sample size: Total 77ea minimum. (Some special devices with BI temperature different with 125C followed mass production temperature) (2) Endurance cycling Min. 100K at room temperature for flash only, sample size: Total 77ea minimum. (Cycling count depends on product SPEC.) |
| 2 | Monitoring Frequency | (1) Cover major foundry technology family in at least 1 year. (2) Follow customer's spec if customer have special request. |
| 3 | Selection Rule | (1) Per each mass production foundry/process technology family with any device shipping quantity larger than 1KK pcs per year. |

| | | |
|---|-------------------------------|--|
| | | ISSI need to select one product for monitoring at least. (Mass production foundry/process technology family didn't include "EOL" stage). (2) Special contracts or requirements from customer or MKT will be executed as selective one. (3) If there were only ODC lots in the WIP, it's no need to redo monitor qual since it was done monitor in the former year already. |
| 4 | Reliability Monitoring Plan | RE should give a product monitoring plan annually for the following whole year, and report in "Quarterly Management Review Meeting" for getting GM's approval. |
| 5 | Reliability Monitoring Report | RE should publish the product monitoring report quarterly and report it in "Quarterly Management Review Meeting". |

3.6. LUMISSIL Reliability Test conditions

3.6.1. Device Related Tests

High Temperature Operating Life Test

Condition: Dynamic operation, T = 125 °C.

Duration: Up to 1000 hrs, failed device were counted at 168, 500 and 1000hrs

Failures: When a device fails to pass production test program

Calculation: Both temperature and voltage acceleration factors are considered for the failure rate calculation; Poisson probability distribution with confidence level = 60% is assumed.

Electrostatic Discharge (ESD) and Latch-up Tests

- LUMISSIL currently performs two types of ESD tests:

- 1) The Human Body model (HBM), according to ANSI/ESDA/JEDEC JS-001
- 2) The Charge Device model (CDM), according to ANSI/ESDA/JEDEC JS-002

During the tests, the applied voltage is increased in steps until reaching the maximum passing voltage. The test sequence for ESD is listed as following:

- 1) Zap all IO pins (+/-) respectively to VDD and Vss pins.

- 2) Zap all IO pins (+/-) respectively to all other IO pins.
- 3) Zap all VDD pins (+/-) respectively to all Vss pins.
- 4) Zap all VDD pins (+/-) respectively to all other Vdd pins.

- **Latch-up test:**

In accordance with JEDEC standard No.78, the currents are injected into the input, output and I/O pins, and Icc is monitored to see whether latch-up has occurred.

The test sequence of latch-up is listed as following:

- 1) Current trigger to all IO pins (+/-) respectively with all input pins biased during VDD power is applied.
- 2) Voltage trigger to all VDD pins respectively with all input pins biased during VDD power is applied.

Endurance Cycling and Data Retention tests

(Refer to MIL-STD-883 1033 and JEDEC 22 A117)

Data retention test measures the stability of electron in the floating gate of Flash products.

Condition: High temperature (typically, 125 or 150 °C) with no bias

Duration: 1000 hours

Failures: Measure threshold shift or cell current that eventually cause failure of a cell to retain data

Calculation: Percentage of cells that cannot retain data after baking

3.6.2. Package Related Tests

Pre-condition Test

Procedure:

- 1) Baking 24 hrs at 125°C;
- 2) Moisture soaking at certain temperature and humidity level.

For level 1: T=85°C; and RH=85%, for 168 hrs;

For level 3: T=30 °C; and RH=60%, for 192 hrs;

3) Re-flowing solder IR at 240 °C/260 °C; for regular and Pb-free packages respectively

Highly Accelerated Stress Test

Condition: Steady-state temperature humidity bias, voltage is normally set at 1.1× VCCmax, T = 130°C; 85% RH, 33.3 psi.

Duration: Electrical tests conducted at 96 hrs (or 110°C/85%RH/264 hrs)

Failure: When device fails to pass production test program

Calculation: Both temperature and humidity acceleration factors are considered for the failure rate calculation. Poisson probability distribution with confidence level = 60% is assumed.

Temperature Cycling Test

Condition: T = -65 to +150 °C; temperature cycle, transition period: 5 min.

Duration: Electrical tests conducted after 500 temperature cycles.

Failure: When device fails to pass production test program

Calculation: Poisson probability distribution with confidence level = 60% is assumed.

Pressure Cooker Test

Condition: No bias, T=121 °C; relative humidity (RH) = 100%, pressure 15 psi.

Duration: Electrical tests conducted at 168 hrs for Non BGA pkg and 96hrs for BGA pkg.
(Reference only for BGA)

Failure: When device fails to pass production test program

Calculation: Poisson probability distribution with confidence level = 60% is assumed.

High Temperature Storage Life Test

Condition: T = 150 °C.

Duration: For AU wire, up to 1000hrs, for CU wire, up to 2000hrs.

Failures: When a device fails to pass production test program

Calculation: Both temperature and voltage acceleration factors are considered for the failure rate calculation; Poisson probability distribution with confidence level = 60% is assumed.

3.7. LUMISSIL Reliability Test Equipment List

The reliability test equipment utilized throughout LUMISSIL’s device measurement laboratory and approved subcontractors are shown in below Table.

| Category | Item | Application | Application Site |
|-----------------|--|--|----------------------------|
| Visual | Stereo Microscope | For visual inspection of wafer and package parts | In-house lab |
| | Scanning Electron Microscope (SEM) | Inspect surface or cross section of a device at high magnification | Currently in subcontractor |
| | Acoustic Microscope (CSAM) | For visual inspection delamination in package | In-house lab |
| | Optical Microscope | For visual inspection both wafer and package parts | In-house lab |
| | X-ray | To inspect the bonding wire of encapsulated devices | Currently in subcontractor |
| Electrical Test | Keytek ESD & Latch-up Test system | To test ESD and Latch-up, both JEDEC and EIAJ modes available | Currently in subcontractor |
| | Curve Tracer | To measure parameters | Currently in subcontractor |
| | Parameter Tester | To measure parameters | In-house lab |
| | Oscilloscope | To test timing and functionalities | In-house lab |
| | Bench testers (GII, Adventest -Tester, EPRO-142, etc.) | To test parametric and functional characteristics. | In-house lab |
| | MOSAID Tester | To test functionalities and parameters | In-house lab |
| Stress Test | Temperature Probe System | To probe the device at high temperature. | Currently in subcontractor |
| | HTOL Oven | To do high-temperature operating life test | Currently in subcontractor |
| | HAST Test System | To do highly accelerative stress test | In-house lab |
| | Temperature Cycling System | To do temperature cycling test (-65 °C to 150 °C) | In-house lab |
| | Bake Oven | To do baking and data retention test. | In-house lab |
| | Temp. & Humid. Storage Chamber | To do high temp and humidity soak test. | In-house lab |
| | PCT Test System | To do pressure cooker test. | In-house lab |
| | IR-reflow chamber | To do preconditioning test. | In-house lab |
| | Other Package Related Tests | To quality the leads, marking, etc. | In-house lab |

3.8. Zero Defect Statistics

Process Average Testing (PAT), Statistical Yield Analysis (SYA)

To enhance the quality control and achieve the zero defect target for automotive grade parts, we need to implement the PAT, SYA, concept in the production flow.

3.8.1. Part Average Testing (PAT)

1) Definition:

Part Average Testing (PAT) is intended to identify Components that perform outside the normal statistical distribution.

2) Purpose:

Every part is built with a particular design and process which, if processed correctly, will yield a certain consistent set of characteristic test results. PAT uses statistical techniques to establish the limits on these test results. These test limits are set up to remove outliers (parts whose parameters are statistically different from the typical part) and should have minimal yield impact on correctly processed parts from a well-controlled process.

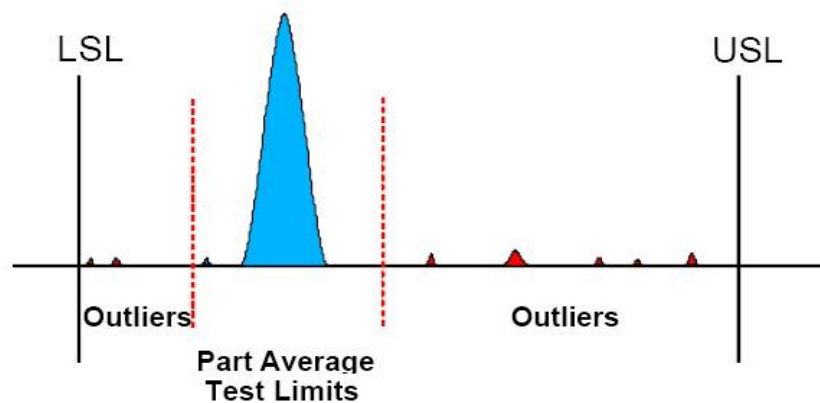


Figure 3-8. Graphical Representation of Part Average Test Limits and Outliers

History has shown that parts with abnormal characteristics significantly contribute to quality and reliability problems.

3) Method:

a. Setting the Test Limits

PAT Limits = Robust Mean \pm Robust 6 sigma

PAT test limits shall not exceed the device specification limits.

Test limits may be set in either a static or dynamic manner. New PAT limits (both static and dynamic) must be established when wafer level design changes, die shrinks or process changes have been made.

b. Static PAT limits

The static limits are established based on an available amount of test data and used without modification for some period of time.

Sample Size:

Package parts: 30 pass parts × at least 6 lots.

Wafer level: 30 pass dies from at least 5 die located × at least 6 lots.

When data from six lots is not available, data from characterization lots may be used.

This data shall be updated as soon as production data is available.

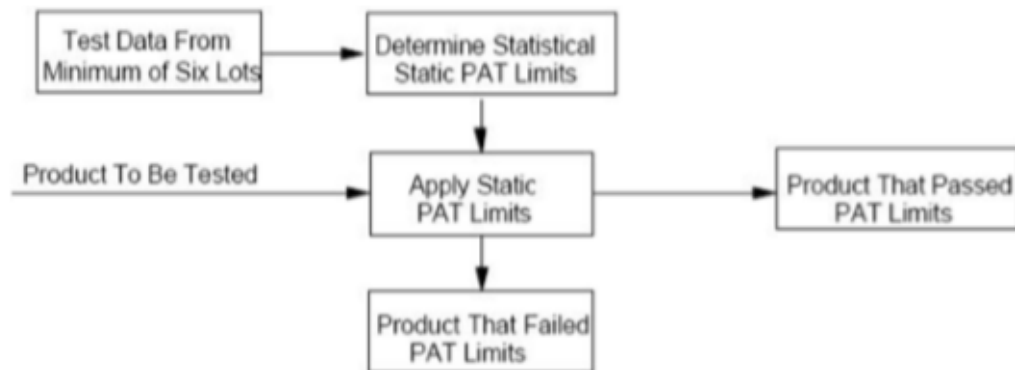


Figure 3-9. Determining Static PAT Limits

The first 6 months: PAT test limits shall be reviewed and updated as required using current data of production or the last 8 lots. Older data shall not be used.

After 6 months: The static PAT limits shall be reviewed and updated as needed on a quarterly (every 3 month) basis.

c. Dynamic PAT limits

The dynamic test limits are based on the static limits, but are established for each lot and continually change as each lot is tested.

Sample Size:

Package parts: 1000 pass parts per lot

Wafer level: 200 pass parts per lot

The dynamic limits shall not exceed the static limits.

Dynamic PAT can provide tighter limits without causing rejection of good parts because it does not have to consider the lot -to-lot variation that is part of Static PAT Limits.

This analysis establishes new tighter test limits for that particular lot (or wafer) and removes additional outliers.

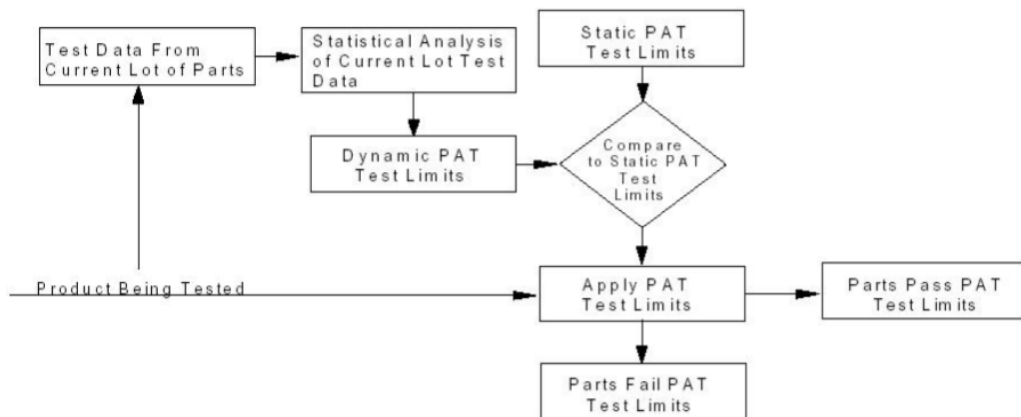


Figure 3-10. Determining Dynamic PAT Limits

The lot of parts being tested must be held in a manner that allows the outliers to be removed after the test limits for the lot have been calculated and applied.

4.) Application on electrical tests

Any electrical parameter with a Cpk greater than 2.0 ($CPK = 2.0 = 6\sigma$) is considered a candidate for implementation.

PAT limits should be used for all electrical tests if possible, but shall be established for at least one of the important characteristics as below:

a. Standby power supply current (IDD or ICC)

b. Output leakage

c. Output current (IOUT)

3.8.2. Statistical Yield Analysis (SYA)

1) Definition:

Statistical Yield Analysis (SYA) identifies lots of components that yield abnormal distributions, or contain abnormal failure characteristics.

2) Purpose:

Utilizes statistical techniques to identify a wafer, wafer lot, or component assembly lot that exhibits an unusually low yield or an unusually high bin failure rate. Experience has shown that wafer and component assembly lots exhibiting these abnormal characteristics tend to have generally poor quality and can result insignificant system reliability and quality problems that impact the customer.

3) Method:

a. 2 ways: statistical yield limits (SYL) and statistical bin limits (SBL) results. Both use test limits based on Part Average Testing (PAT) Limits.

b. Sample Size: Collect data from at least six lots and determine the mean and sigma value for the percentage of devices passing per lot and the percentage of devices failing each bin-out per lot

Early in production of a part, when data from six lots is not available, data from characterization/matrix lots may be used. This data shall be updated as soon as production data is available

c. The first 6 months: This early data shall be reviewed and updated using current data at least quarterly (every 3 months). The current data used shall include the data available since the last update or at least the last 8 lots. Older data shall not be used

After 6 months: the limits shall be updated on half an year(every 6months) basis

d. Setting the value for SYL and SBL

e. Disposition:

SYL1 = Mean - 3 Sigma

SBL1 = Mean + 3 Sigma

SYL2 = Mean - 4 Sigma

SBL2 = Mean + 4 Sigma

Any lot that fall below SYL1 or exceed SBL1 shall be held for engineering review. In addition, lots that fall below SYL2 or exceed SBL2 may be impounded and require customer notification before release. Analysis shall be performed on failures to determine the failure mechanism causing these abnormal failure rates.

f. Records: The supplier shall maintain records on all lots that fall below SYL1 or exceed SBL1. This data shall include the root cause for the yield problem and corrective action taken to prevent reoccurrence of the problem. It should also include any special testing or screens that were performed on lot and the customer that approved the shipment of the parts in question.

4) Customer Notification

a. Supplier shall have determined the failure mechanism and, based on his experience, determine the corrective action required to prevent a reoccurrence of the condition in future product. The supplier shall also present a plan for additional tests and screens which could provide the user with reasonable certainty that the product he receives will be at least equal to normal product.

b. The customer reserves the right to reject material that falls below SYL2 or exceeds SBL2 if the supplier data does not satisfy his concerns about the quality. The parts from the lots falling below SYL2 shall not be supplied to distributors as meeting AEC - Q100 if the supplier does not know who the customer is and customer approval cannot be obtained.

Environmental Management Systems

As a technology leader, LUMISSIL designs, develops and markets high performance semiconductors throughout the world. LUMISSIL acknowledges our responsibility to manage these functions in a responsible manner, endeavoring to preserve, protect, and whenever possible to enhance the environment. To achieve these goals, we consider and control all key factors which impact the environment including the sourcing of raw materials, manufacturing processes and disposal and recycling of materials.

The Environment Management (EM) System defined in LUMISSIL EM Manual is in compliance with the requirements of ISO 14001: 2015. In addition, we also rely on external subcontractors, such as wafer foundries and assembly houses. All of them are required to be ISO 14001-certified. For your reference, please contact us directly for copies of LUMISSIL Vendors' ISO 14001 certificates.

Notice:

Part of making dismantling and recycling of ELV and electronics more environmental friendly, please be advised that end-of-life materials are disposed following ELV Directive (end-of-life vehicles regulations, Directive 2000/53/EC) and WEEE Directive (Waste Electrical & Electronic Equipment, Directive 2012/19/EU).

4.1. Environmental Policy

LUMISSIL, a technology leader, designs, develops and markets high performance semiconductors throughout the world. LUMISSIL acknowledges our responsibility to manage these functions in a responsible manner, endeavoring to preserve, protect and where possible enhance the environment. To achieve these goals, we consider and control all key factors which impact the environment including the sourcing of raw material and manufacturing processes.

Our vision for the environment is C.L.E.A.N.

Continuous Improvement

Undertake actions to prevent pollution and to maintain, review and continuously improve our environmental management system.

Legal Requirements

Comply with all relevant environmental legislation and regulations.

Environment Develop

Regularly review and achieve environmental objectives, targets and improvement plans.

Awareness

Ensure all are trained and aware of the importance of their environmental responsibilities.

Naturalization

Make the commitment to the environment a natural by-product of our processes and business activities.

All worldwide LUMISSIL locations adhere to LUMISSIL Environmental Policy. As prescribed by the ISO 14001:2015 Standard, LUMISSIL Environmental Policy shall be reviewed to ensure that it:

- 1) Remains appropriate to the nature, scale, and environmental impacts of the organization's activities, products, or services
- 2) Includes a commitment to continual improvement and prevention of pollution
- 3) Includes a commitment to comply with relevant environmental legislation and regulations, and with other requirements to which the organization subscribes
- 4) Provides the framework for setting and reviewing environmental objectives and targets
- 5) Is documented, implemented, maintained, and communicated to all employees
- 6) Is available to the public.

4.2. Environmental Management Systems

The Environment Management (EM) System defined in LUMISSIL EM Manual is in compliance with the requirements of ISO 14001: 2015. In addition, we also rely on external subcontractors, such as wafer foundries and assembly houses. All of them are required to be ISO 14001-certified. For your reference, please contact us directly for copies of LUMISSIL vender's ISO 14001 certificates.

4.2.1. ISO 14001 Certificate

LUMISSIL Microsystems is a division of Integrated Silicon Solution Inc. (ISSI). With the continuous effort in pursuing an environmentally friendly product strategy, ISSI became the first design house in Taiwan that achieved the ISO 14001:1996 standard in January 2004. Since the ISO14001:2015 has been published in Sep 2015, LUMISSIL is compliance with new revision as well as planned schedule.



CERTIFICATE



This is to certify that

Integrated Silicon Solution, Inc. Chingis Technology Corporation

No. 2, Technology Road V, Hsinchu Science Park
Hsinchu
Taiwan

has implemented and maintains an **Environmental Management System**.

Scope:

The environmental activities and supporting processes associated with the design of integrated circuit products.

Through an audit, documented in a report, it was verified that the management system fulfills the requirements of the following standard:

ISO 14001 : 2015

| | |
|------------------------------|---------------|
| Certificate registration no. | 20001373 UM15 |
| Date of revision | 2021-07-28 |
| Date of certification | 2021-08-08 |
| Valid until | 2024-08-07 |



DQS Inc.

Brad McGuire
Managing Director

Accredited Body: DQS Inc., 1500 McConnor Parkway, Suite 400, Schaumburg, IL 60173 USA
Administrative Office: DQS Taiwan Inc., 6F, 23, Yuan Huan West Road, Feng Yuan Dist.,
Taichung City, Taiwan 420



4.2.2. Environmental Management Organization

LUMISSIL Environmental Management organization is outlined as Figure 4-1.

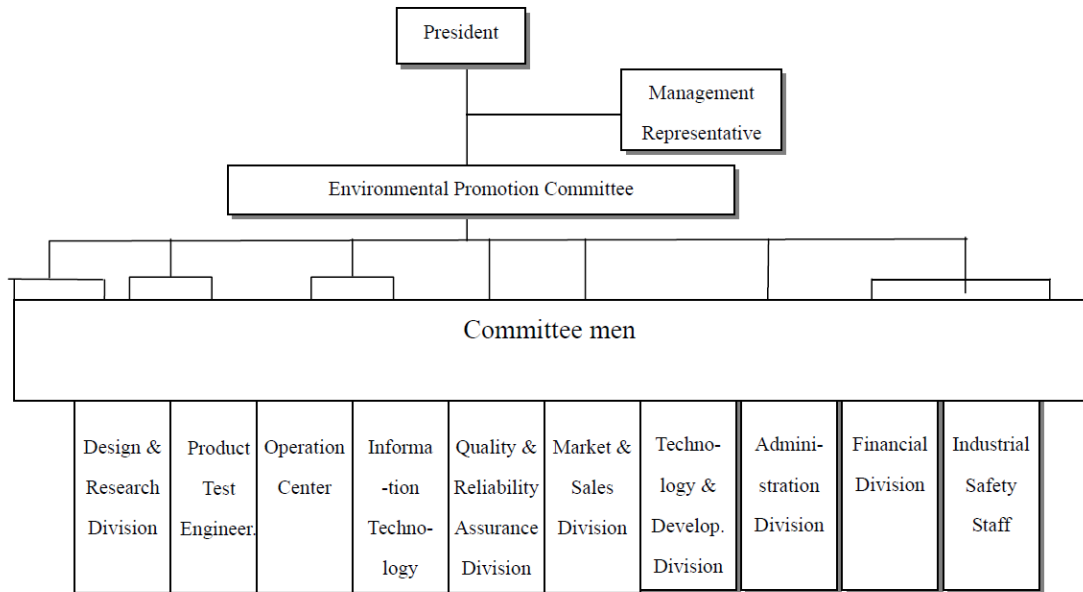


Figure 4-1

4.3. Environmental Substances Management

Through continuous improvement, LUMISSIL has positioned itself to be an environmental-friendly enterprise and a green partner of all environment-concerned companies with which LUMISSIL has a business relationship.

4.3.1. Legislation and SONY Policy

1) Europe – 1 July 2006

Total abolition of Lead, Mercury, Cadmium, Hexavalent Chromium, PFOS, PBB and PBDE has been observed since July 2006, according to the second draft of European Union order (RoHS and WEEE) for the abolishing electrical and electronic equipment.

2) Management Standards for the Restrictively Used Substances (SONY SS-00259)

Table 4-1 Environmental-Restricted Substances

| No | Material/Substance Category | | LUMISSIL Threshold |
|--|--|---|---|
| 1 | Heavy Metals 重金屬 | Cadmium(Cd)/Cadmium compounds 鎘及其化合物 | 5 ppm for resin (rubber, film), coatings, inks pigments, dyes. |
| | | | Less than 20ppm for lead free solder -Bar solder -Wire solder -Resin flux cored solder -Solder paste ,Solder ball -Soldered sections of purchased PC boards -Component solder |
| | | | Less than 75 ppm for homogeneous material |
| | Lead (Pb)/Lead compounds 鉛及其化合物 | 100 ppm or less in plastics/inks | |
| | | Less than 800 ppm of total in homogenous material | |
| | | Less than 500 ppm for lead free solder - Bar solder -Wire solder -Resin flux cored solder -Solder Paste -Solder ball | |
| | Mercury (Hg)/Mercury compounds 汞及其化合物 | Less than 1000 ppm of total in homogenous material | |
| Hexavalent Chromium(Cr6+)/It's compounds 六價鉻及其化合物 | Less than 1000 ppm of total in homogenous material | | |
| 2 | Brominated organic compounds | Polybrominated Biphenyls (PBBs) 多溴聯苯 | <1000ppm or less; Non-detected or intentionally added |
| | | Polybrominated Diphenylethers (PBDEs) | <1000ppm or less; Non-detected or intentionally added |

| | | | |
|---|--|---|--|
| | 有機溴化合物 | Included DecaBDE 多溴聯苯醚 | |
| | | Hexabromocyclododecane (HBCDD) 六溴環十二烷 | Not intentionally added or Max. 0.01wt%(100ppm) of article even contained as impurities. |
| | Brominated flame retardants (BFR) 溴系阻燃劑 | Other Brominated organic compounds | Non-detected or intentionally added |
| 3 | Chlorinated organic compounds 有機氯化物 | Polychlorinated Biphenyls (PCBs) 多氯聯苯 | Not intentionally added |
| | | Polychlorinated naphthalenes (PCNs) 多氯萘 | Not intentionally added |
| | | Chlorinated Paraffins (CP) 氯化石蠟 | Non-detected or intentionally added |
| | | Polychlorinated Terphenyls (PCTs) 多氯三聯苯 | 50ppm in material |
| | | Short Chain Chlorinated Paraffins (C10-C13) 短鏈氯化石蠟 | Non-detected or Intentionally added, mix, or production of substance in the manufacturing process. Less than 1000ppm of article |
| | Chlorinated flame retardants (CFR) 氯系阻燃劑 | Other Chlorinated organic compounds | Non-detected or intentionally added |
| 4 | Halogen 鹵素 | Cl, Br. | Must be lower than 900 ppm, respectively, and total amount of PPM must be lower than 1500 ppm (Br + Cl < 1500 ppm). |
| 5 | Phthalates 鄰苯二甲酸酯類 | Benzyl butyl phthalate(BBP) Dibutyl phthalate(DBP) Bis(2- | Less than 1000 ppm of each in homogenous material. |

| | | | |
|---|--|---|---|
| | | ethylhexyl)phthalate(DEHP) Diisobutyl phthalate(DIBP) | |
| 6 | Organostannic tin compound 有機錫化合物 | Tributyltin(TBT) compounds 三丁基錫化合物 Triphenyltin(TPT) compounds 三苯基錫化合物 Tributyl Tin Oxide (TBTO) 氧化三丁錫 Dibutyltin(DBT) compounds 二丁基氧化錫 Diocetyl tin(DOT) compounds 氧化二辛基錫 | Not intentionally added or 0.1wt % (1000ppm) of the article |
| 7 | Phosphorus-based Flame Retardants 磷系阻燃劑 | Tris(2-chloroethyl) phosphate (TCEP) 磷酸三(2-氯乙基) 酯 Tris (2-chloro-1-methylethyl) phosphate (TCPP) 磷酸三(1-氯丙基) 酯 Tris(1,3-dichloro-2-propyl) phosphate (TDCPP) 磷酸三(1,3-二氯丙基) 酯 Trixylyl phosphate (TXP) 磷酸三(二甲苯)酯 | 0.1wt% (1000ppm) of the article |
| 8 | Asbestos 石棉 | | Non-detected or intentionally added |

| | | | |
|----|--|--|---|
| 9 | Specific aze compound s (Certain Azocouran ts and Azodyes) 特定偶氮 化合物 | | Non-detected or intentionally added |
| 10 | Polyvinyl Chloride (PVC) and PVC blends 聚氯乙 烯及聚 氯乙 烯混 合物 | | Not intentionally added or 0.1wt % (1000ppm) of the product *3 Tube is not applicable, since PVC is the main material. |
| 11 | Beryllium oxide 氧化 鈹 Beryllium copper 鈹 青銅 | | Non-detected or intentionally added. |
| 12 | Specific phthalates 特定鄰 苯二 甲酸 鹽 | - Diisononyl phthalate(DINP, 68515- 48-0, 28553-12-0) - Di-isodecyl phthalate(DIDP, 68515- 49-1, 26761-40-0) - Di-n-octyl phthalate(DnOP, 117-84- 0) - Di-n-hexyl phthalate(DnHP, 84-75-3) - Bis(2-methoxyethyl) phthalate(DMEP, 117-82- 8) | Non-detected or intentionally added |

| | | | |
|----|--|--|-------------------------------------|
| | | <ul style="list-style-type: none"> - Di-iso-pentyl phthalate(DIPP, 605-50-5) - n-Pentyl-isopentyl phthalate(nPIPP, 776297-69-9) - Di-n-pentyl phthalate(DnPP, 131-18-0) - Diethyl phthalate(DEP, 84-66-2) - Dimethyl phthalate(DMP, 131-11-3) - 1,2-Benzenedicarboxylic acid, di-C6-8-branched alkyl esters, C7-rich(DIHP, 71888-89-6) - 1,2-Benzenedicarboxylic acid, di-C7-11-branched and linear alkyl esters(DHNUP,68515-42-4) - 1,2-Benzenedicarboxylic acid, dipentylester, branched and linear(DPP, 84777-06-0) | |
| 13 | <p>Hydrofluorocarbon (HFC), Perfluorocarbon (PFC) 氫氟碳化物(HFC) ,全氟化碳 (PFC)</p> | | Non-detected or intentionally added |

| | | | |
|----|--|---|---|
| 14 | PFOA 全氟辛酸 硫酸 | | Non-detected or intentionally added 0.1wt%(1000ppm) by weight in material. |
| | PFOA 全氟辛酸 | Exemption: <ul style="list-style-type: none"> • Photographic coatings applied to films, paper or printing plates and other coated consumer products • Semiconductors or compound semiconductors manufactured in photolithography processes for semiconductors or in etching processes for compound semiconductors. | < 25 ppb of PFOA and its salts or totally 1000 ppb (1ppm) of one or a combination of PFOA related substances in materials "an article" from 2020/7/4. (PFOA and its salts please refer to Annex 1 control substances) |
| 15 | Ozone Depleting Substances 臭氧危 害物質 | | Banned and must not be used when manufacturing parts and device. |
| 16 | Radioactive Substances 放射性 物質 | | Banned and must not be used when manufacturing parts and device. |
| 17 | Cobalt dichloride 二氯化鈷 | Pneumatic panels to indicate water contamination | Not intentionally added in Moisture indicator used for a desiccant agent (e.g. silica gel) 0.1wt%(1000ppm) of article |
| 18 | Specific benzotriazole 特定苯 并三氮唑 | | Non-detected or intentionally added |

| | | | |
|----|---|---|---|
| 19 | Bisphenol A 雙酚 A | | Not intentionally added or <0.1wt% (SVHC) |
| 20 | Dimethyl fumarate(DMF) 富馬 酸二甲酯 | | Non-detected or intentionally added |
| 21 | PAHs 多環 芳香烴 | | Non-detected (MDL: < 0.2mg/kg) in toy which contact with skin and for the baby. |
| 22 | REACH SVHC substances 高關注物 質 | Refer to ECHA candidate list :https://echa.europa.eu/c andidate-list-table | < 0.1wt % of the article |
| 23 | Biocidal Products 生物殺滅 劑 EU) No 528/2012 | Prohibited in the leather products, wood and packaging materials. | Not contained or intentionally added |

Note:

- 1) Due to restrictions in manufacturing technologies, the lead concentration found in the electroplating of IC's outer leads may be exempt from the threshold level (100 PPM). But the lead concentration must still not exceed 1000 PPM. Assembly house must control lead concentration lower than 800 ppm while Plating process and measurement in process monitor to avoid any deviation.
- 2) For Cabolt dichloride must be prohibited from Dec-01st '2008.
- 3) Sony Class III definition: No deadline for banning the use is currently set for the substances classified into this level. They shall be classified into Level 2 to be banned in phases, Depending on the availability of alternative parts and material that satisfy the intended application.
- 4) Non-detected level please follow the MDL (Method Detect Limit) by third party test report.

4.3.2. Green Partner Certification

- LUMISSIL Pb < 800 ppm

Halogen-free package:

In addition to the requirement of Pb-free package, the Halogen-free package must reduce the content of halogen and antimony trioxide⁴ to the minimum level

- Japan Electronic Insulating Material Association:

Br, Cl, Sb < 900 ppm, respectively

- ST/Philip/Infineon Halogen (Br + Cl) < 900 ppm

based on JPCA-ES-01-1999

- LUMISSIL Br, Cl, Sb < 900 ppm, respectively

Halogen (Br + Cl) < 1500 ppm

The new 'Green' definition will be followed and updated with the green standard of the environmental concerned substances changing around the world.

**Future Material declaration requirement at an Article level for EU/REACH
(Registration, Evaluation, Authorization and Restriction of Chemicals)**

The European Chemicals Agency (ECHA) has published the candidate list of substances of very high concern (SVHC) from 28 October 2008. ISSI will notify customer in case of ISSI use and exceed threshold level (if > 0.1 % w/w) in the future once a new candidate list of REACH which is demanded by ECHA. The SVHC substances please refer to ECHA candidate list:

<https://echa.europa.eu/candidate-list-table>

Table 4-4 SVHC 224

| No. | Substance Name | CAS No. |
|-----|--------------------------|------------|
| 1 | 三乙基砷酸酯 Triethyl arsenate | 15606-95-8 |

⁴ Even though antimony is not a halogen element, it is often used with halogen in the flame retardant of the molding compound. We follow ASE (Advanced Semiconductor Engineering) Group's convention to include antimony trioxide as a "halogen" element in the category of "halogen-free" package.

* All refractory ceramic fibers are covered by index number 650-017-00-8 in Annex VI of the so-called CLP regulation - Regulation No 1272/2008 on the classification, labeling and packaging (CLP) of chemical substances.

| | | |
|----|---|--|
| 2 | 蔥 Anthracene | 120-12-7 |
| 3 | 4,4'- 二氨基二苯甲烷 4,4'- Diaminodiphenylmethane(MDA) | 101-77-9 |
| 4 | 鄰苯二甲酸二丁酯 Dibutyl phthalate(DBP) | 84-74-2 |
| 5 | 氯化鈷 Cobalt dichloride | 7646-79-9 |
| 6 | 五氧化二砷 Diarsenic Pentaoxide | 1303-28-2 |
| 7 | 三氧化二砷 Diarsenic trioxide | 1327-53-3 |
| 8 | 重鉻酸鈉 · 二倍結晶水 Sodium Dichromate | 7789-12-0 10588-01-9 |
| 9 | 5-叔丁基-2,4,6-三硝基間二甲苯 5-tert-butyl-2,4,6-trinitro-m-xylene(musk xylene) | 81-15-2 |
| 10 | 鄰苯二甲酸二(2-乙基己基)酯 Bis(2-ethylhexyl) Phthalate (DEHP) | 117-81-7 |
| 11 | 六溴環十二烷 Hexabromocyclododecane (HBCDD) and all major diastereoisomers identified: Alpha-hexabromocyclododecane Beta-hexabromocyclododecane Gamma-hexabromocyclododecane | 25637-99-4 3194-55-6 134237-50-6 134237-51-7 134237-52-8 |
| 12 | 短鏈氯化路蠟 Alkanes, C10-13, chloro (Short Chain Chlorinated Paraffins) | 85535-84-8 |
| 13 | 氧化三丁錫 Bis(tributyltin)oxide (TBTO) | 56-35-9 |
| 14 | 砷酸氫鉛 Lead hydrogen arsenate | 7784-40-9 |
| 15 | 鄰苯二甲酸丁酯苯甲酯 Benzyl butyl phthalate (BBP) | 85-68-7 |
| 16 | 蔥油 Anthracene oil | 90640-80-5 |
| 17 | 蔥油 · 蔥糊 · 輕油 Anthracene oil, anthracene paste, distn. Lights* | 91995-17-4 |
| 18 | 蔥油 · 蔥糊 · 蔥餾分離液 Anthracene oil, anthracene paste, anthracene fraction | 91995-15-2 |
| 19 | 蔥油 · 含蔥量少 Anthracene oil, anthracene-low | 90640-82-7 |
| 20 | 蔥油 · 蔥糊 Anthracene oil, anthracene paste | 90640-81-6 |
| 21 | 煤瀝青 · 高溫 Coal tar pitch, high temperature | 65996-93-2 |
| 22 | 丙烯醯胺 Acrylamide | 79-06-1 |
| 23 | 矽酸鋁 · 陶瓷耐火纖維 Aluminosilicate Refractory Ceramic Fibres are fibres covered by index number 650-017-00-8 in Annex VI, part 3, table 3.1 of Regulation (EC) No 1272/2008 of the European Parliament and of the Council of 16 December 2008 on classification, labelling and packaging of substances and mixtures, and fulfil the three following conditions: a) oxides of aluminium and silicon are the main components present (in the fibres) within variable concentration ranges b) fibres have a length weighted geometric mean diameter less two standard geometric errors of 6 or less micrometres (µm) c) alkaline oxide and alkali earth oxide (Na ₂ O+K ₂ O+CaO+MgO+BaO) content less or equal to 18% by weight | None |

| | | |
|----|--|--------------------------------------|
| 24 | 矽酸鋁氧化鋯·陶瓷耐火纖維 Zirconia Aluminosilicate, Refractor Ceramic Fibres are fibres covered by index number 650-017-00-8 in Annex VI, part 3, table 3.1 of Regulation (EC) No 1272/2008 of the European Parliament and of the Council of 16 December 2008 on classification, labelling and packaging of substances and mixtures, and fulfil the three following conditions: a) oxides of aluminium, silicon and zirconium are the main components present (in the fibres) within variable concentration ranges b) fibres have a length weighted geometric mean diameter less two standard geometric errors of 6 or less micrometres (µm). c) alkaline oxide and alkali earth oxide (Na ₂ O+K ₂ O+CaO+MgO+BaO) content less or equal to 18% by weight | None |
| 25 | 2,4 二硝基甲苯 2,4-Dinitrotoluene | 121-14-2 |
| 26 | 鄰苯二甲酸二異丁酯 Dilsobutyl phthalate | 84-69-5 |
| 27 | 鉻酸鉛 Lead chromate | 7758-97-6 |
| 28 | 紅色鉻鉬酸硫酸鹽 Lead chromate molybdate sulphate red (C.I. Pigment Red 104) | 12656-85-8 |
| 29 | 黃色硫化鉻酸鉛 Lead sulfochromate yellow (C.I. Pigment Yellow 34) | 1344-37-2 |
| 30 | 三 2-(氯乙基)磷酸酯 Tris (2-chloroethyl) phosphate | 115-96-8 |
| 31 | 三氯乙烯 Trichloroethylene | 79-01-6 |
| 32 | 硼酸 Boric acid | 10043-35-3 11113-50-1 |
| 33 | 無水四硼酸二鈉 Disodium tetraborate, anhydrous | 1303-96-4 1330-43-4 12179-04-3 |
| 34 | 水合七氧四硼酸二鈉 Tetraboron disodium heptaoxide, hydrate | 12267-73-1 |
| 35 | 鉻酸鈉 Sodium chromate | 7775-11-3 |
| 36 | 鉻酸鉀 Potassium chromate | 7789-00-6 |
| 37 | 重鉻酸銨 Ammonium dichromate | 7789-09-5 |
| 38 | 重鉻酸 Potassium dichromate | 7778-50-9 |
| 39 | 硫酸鈷 Cobalt sulfate | 10124-43-3 |
| 40 | 硝酸鈷 Cobalt dinitrate | 10141-05-6 |
| 41 | 碳酸鈷 Cobalt carbonate | 513-79-1 |
| 42 | 醋酸鈷 Cobalt diacetate | 71-48-7 |
| 43 | 2-甲氧基乙醇 2-Methoxyethanol | 109-86-4 |
| 44 | 2-乙氧基乙醇 2-Ethoxyethanol | 110-80-5 |
| 45 | 三氧化鉻 Chromium trioxide | 1333-82-0 |
| 46 | 三氧化二鉻 Chromic acid/重鉻酸 Dichromic acid | 7738-94-5 13530-68-2 |
| 47 | 乙酸-2-乙氧基乙酯 2-ethoxyethyl acetate | 111-15-9 |
| 48 | 鉻酸鋇 Strontium chromate | 7789-06-2 |
| 49 | 鄰苯二甲酸二(C7-11 支鏈與直鏈)烷基酯 1,2-Benzenedicarboxylic acid, di-C7-11-branched and linear alkyl esters (DHNUP) | 68515-42-4 |
| 50 | 胼 Hydrazine | 302-01-2 7803-57-8 |
| 51 | N-甲基吡咯烷酮 1-methyl-2-pyrrolidone | 872-50-4 |
| 52 | 1·2·3-三氯丙烷 1,2,3-trichloropropane | 96-18-4 |

| | | |
|----|---|------------|
| 53 | 鄰苯二甲酸二 C6-8 支链 烷基酯 1,2-Benzenedicarboxylic acid, di-C6-8-branched alkyl esters, C7-rich (DIHP) | 71888-89-6 |
| 54 | 鉻酸鉻 Dichromium tris(chromate) | 24613-89-6 |
| 55 | 氫氧化鉻酸鋅鉀 Potassium hydroxyoctaoxodizincatedi-chromate | 11103-86-9 |
| 56 | C.I.顏料黃 36 Pentazinc chromate octahydroxide | 49663-84-5 |
| 57 | 甲醛和苯胺聚合物 Formaldehyde, oligomeric reaction products with aniline (technical MDA) | 25214-70-4 |
| 58 | 鄰苯二甲酸二甲氧乙酯 Bis(2-methoxyethyl) phthalate | 117-82-8 |
| 59 | 鄰-甲氧苯胺 2-Methoxyaniline; o-Anisidine | 90-04-0 |
| 60 | 4-三級辛基苯酚 4-(1,1,3,3-tetramethylbutyl)phenol, (4-tert-Octylphenol) | 140-66-9 |
| 61 | 1,2-二氯乙烷 1,2-Dichloroethane | 107-06-2 |
| 62 | 二甘醇二甲醚 Bis(2-methoxyethyl) ether | 111-96-6 |
| 63 | 砷酸 Arsenic acid | 7778-39-4 |
| 64 | 砷酸鈣 Calcium arsenate | 7778-44-1 |
| 65 | 砷酸鉛 Trilead diarsenate | 3687-31-8 |
| 66 | N,N-二甲基乙醯胺 N,N-dimethylacetamide (DMAC) | 127-19-5 |
| 67 | 4,4'-二氨基-2,2'-二氯二苯甲烷, 2,2'-dichloro-4,4'-methylenedianiline (MOCA) | 101-14-4 |
| 68 | 酚酞 Phenolphthalein | 77-09-8 |
| 69 | 疊氮化鉛 Lead azide Lead diazide | 13424-46-9 |
| 70 | 收斂酸鉛 Lead styphnate | 15245-44-0 |
| 71 | 苦味酸鉛 Lead dipicrate | 6477-64-1 |
| 72 | 三甘醇二甲醚 1,2-bis(2-methoxyethoxy)ethane (TEGDME; triglyme) | 112-49-2 |
| 73 | 乙二醇二甲醚 1,2-dimethoxyethane; ethylene glycol dimethyl ether (EGDME) | 110-71-4 |
| 74 | α,α -二[(二甲氨基)苯基]-4-氨基苯甲醇 4,4'-bis(dimethylamino)-4''-(methylamino)trityl alcohol | 561-41-1 |
| 75 | 4'-二(N,N-二甲氨基)二苯甲酮 4,4'-bis(dimethylamino)benzophenone (Michler's ketone) | 90-94-8 |
| 76 | 結晶紫 [4-[4,4'-bis(dimethylamino) benzhydrylidene]cyclohexa-2,5-dien-1-ylidene]dimethylammonium chloride (C.I. Basic Violet 3) | 548-62-9 |
| 77 | 碱性藍 26; 維多利亞藍 B [4-[[4-anilino-1-naphthyl][4-(dimethylamino)phenyl]methylene]cyclohexa-2,5-dien-1-ylidene] dimethylammonium chloride (C.I. Basic Blue 26) | 2580-56-5 |
| 78 | 三氧化二硼 (無水硼酸) Diboron trioxide | 1303-86-2 |
| 79 | 氨基甲醛 Formamide | 75-12-7 |
| 80 | 甲基磺酸鉛 Lead(II) bis(methanesulfonate) | 17570-76-2 |
| 81 | N,N,N',N'-四甲基-4,4'-二氨基二苯甲烷 N,N,N',N'-tetramethyl-4,4'-methylenedianiline (Michler's base) | 101-61-1 |
| 82 | 1,3,5-三縮水甘油-S-三嗪三酮 TGIC (1,3,5-tris(oxiranylmethyl)-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione) | 2451-62-9 |
| 83 | A,A-二[4-(二甲氨基)苯基]-4-苯基氨基-1-萘甲醇 α,α -Bis[4-(dimethylamino)phenyl]-4 (phenylamino)naphthalene-1-methanol (C.I. Solvent Blue 4) | 6786-83-0 |
| 84 | β -TGIC (1,3,5-tris[(2S and 2R)-2,3-epoxypropyl]-1,3,5-triazine-2,4,6-(1H,3H,5H)-trione) 異氰脲酸 B-三縮水甘油酯 | 59653-74-6 |
| 85 | 十溴聯苯醚 Bis(pentabromophenyl) ether (DecaBDE) | 1163-19-5 |

| | | |
|-----|--|---|
| 86 | 全氟十三酸 Pentacosfluorotridecanoic acid | 72629-94-8 |
| 87 | 全氟十二烷酸 Tricosfluorododecanoic acid | 307-55-1 |
| 88 | 全氟十一烷酸 Henicosfluoroundecanoic acid | 2058-94-8 |
| 89 | 全氟代十四酸 Heptacosfluorotetradecanoic acid | 376-06-7 |
| 90 | 辛基酚聚醚-9，包括界定明確的物質以及 UVCB 物質、聚合物和同系物 4-(1,1,3,3-tetramethylbutyl)phenol, ethoxylated - covering well-defined substances and UVCB substances, polymers and homologues | - |
| 91 | 分支或線性的壬基酚，含有線性或分支、共價綁定苯酚的 9 個碳烷基鏈的物質，包括 UVCB 物質以及任何含有獨立或組合的界定明確的同分異構體的物質 4-Nonylphenol, branched and linear - substances with a linear and/or branched alkyl chain with a carbon number of 9 covalently bound in position 4 to phenol, covering also UVCB- and well-defined substances which include any of the individual isomers or a combination thereof | - |
| 92 | 偶氮二甲醯胺 Diazene-1,2-dicarboxamide (C,C'-azodi(formamide)) | 123-77-3 |
| 93 | 順環己烷-1,2-二羧酸酐 Cyclohexane-1,2-dicarboxylic anhydride (Hexahydrophthalic anhydride - HHPA) | 85-42-7 |
| 94 | 甲基六氫苯酐、4-甲基六氫苯酐、甲基六氫化鄰苯二甲酸酐、3-甲基六氫苯二甲酯酐 Hexahydromethylphthalic anhydride, Hexahydro-4-methylphthalic anhydride, Hexahydro-1-methylphthalic anhydride, Hexahydro-3-methylphthalic anhydride | 25550-51-0, 19438-60-9, 48122-14-1, 57110-29-9 |
| 95 | 甲氧基乙酸 Methoxy acetic acid | 625-45-6 |
| 96 | 1,2-苯二羧二戊酯 (支鏈和直鏈) 1,2-Benzenedicarboxylic acid, dipentylester, branched and linear | 84777-06-0 |
| 97 | 鄰苯二甲酸二異戊酯 Diisopentylphthalate (DIPP) | 605-50-5 |
| 98 | 鄰苯二甲酸正戊基異戊基酯 N-pentyl-isopentylphthalate | - |
| 99 | 乙二醇二乙醚 1,2-Diethoxyethane | 629-14-1 |
| 100 | N,N-二甲基甲醯胺 N,N-dimethylformamide; dimethyl formamide | 68-12-2 |
| 101 | 二丁基錫 Dibutyltin dichloride (DBT) | 683-18-1 |
| 102 | 城式乙酸鉛 Acetic acid, lead salt, basic | 51404-69-4 |
| 103 | 城式碳酸鉛 Basic lead carbonate (trilead bis(carbonate)dihydroxide) | 1319-46-6 |
| 104 | 城式硫酸鉛 Lead oxide sulfate (basic lead sulfate) | 12036-76-9 |
| 105 | 二鹽基鄰苯二甲酸鉛[Phthalato(2-)]dioxotrilead (dibasic lead phthalate) | 69011-06-9 |
| 106 | 雙(十八酸基)二氧代三鉛 Dioxobis(stearato)trilead | 12578-12-0 |
| 107 | C16-18-脂肪酸鉛鹽 Fatty acids, C16-18, lead salts | 91031-62-8 |
| 108 | 氟硼酸鉛 Lead bis(tetrafluoroborate) | 13814-96-5 |
| 109 | 氨基氰鉛鹽 Lead cyanamidate | 20837-86-9 |
| 110 | 硝酸鉛 Lead dinitrate | 10099-74-8 |
| 111 | 氧化鉛 Lead oxide (lead monoxide) | 1317-36-8 |
| 112 | 四氧化三鉛 Lead tetroxide (orange lead) | 1314-41-6 |
| 113 | 鈦酸鉛 Lead titanium trioxide | 12060-00-3 |
| 114 | 鈦酸鉛鉛 Lead Titanium Zirconium Oxide | 12626-81-2 |
| 115 | 氧化鉛與硫酸鉛的複合物 Pentalead tetraoxide sulphate | 12065-90-6 |
| 116 | 顏料黃 41 Pyrochlore, antimony lead yellow | 8012-00-8 |

| | | |
|-----|--|-------------|
| 117 | 摻雜鉛的矽酸鋇 Silicic acid, barium salt, lead-doped | 68784-75-8 |
| 118 | 矽酸鉛 Silicic acid, lead salt | 11120-22-2 |
| 119 | 亞硫酸鉛 (II) Sulfurous acid, lead salt, dibasic | 62229-08-7 |
| 120 | 四乙基鉛 Tetraethyllead | 78-00-2 |
| 121 | 三域式硫酸鉛 Tetralead trioxide sulphate | 12202-17-4 |
| 122 | 磷酸氧化鉛 Trilead dioxide phosphonate | 12141-20-7 |
| 123 | 呋喃 Furan | 110-00-9 |
| 124 | 環氧丙烷 Propylene oxide; 1,2-epoxypropane; methyloxirane | 75-56-9 |
| 125 | 硫酸二乙酯 Diethyl sulphate | 64-67-5 |
| 126 | 硫酸二甲酯 Dimethyl sulphate | 77-78-1 |
| 127 | 3-乙基-2-甲基-2-(3-甲基丁基)噁唑烷 3-ethyl-2-methyl-2-(3-methylbutyl)-1,3-oxazolidine | 143860-04-2 |
| 128 | 地樂酚 Dinoseb | 88-85-7 |
| 129 | 4,4'-二氨基-3,3'-二甲基二苯甲烷 4,4'-methylenedi-o-toluidine | 838-88-0 |
| 130 | 4,4'-二氨基二苯醚 4,4'-oxydianiline and its salts | 101-80-4 |
| 131 | 4-胺基偶氮苯 4-Aminoazobenzene; 4-Phenylazoaniline | 60-09-3 |
| 132 | 2,4-二氨基甲苯 4-methyl-m-phenylenediamine (2,4-toluene-diamine) | 95-80-7 |
| 133 | 6-甲氧基-間-甲苯胺 甲苯胺 6-methoxy-m-toluidine (p-cresidine) | 120-71-8 |
| 134 | 4-氨基聯苯 Biphenyl-4-ylamine | 92-67-1 |
| 135 | 鄰氨基偶氮甲苯 o-aminoazotoluene | 97-56-3 |
| 136 | 鄰甲基苯胺 o-Toluidine; 2-Aminotoluene | 95-53-4 |
| 137 | N-甲基乙酰胺 N-methylacetamide | 79-16-3 |
| 138 | 溴代正丙烷 1-bromopropane; n-propyl bromide | 106-94-5 |
| 139 | 鎘 Cadmium | 7440-43-9 |
| 140 | 氧化鎘 Cadmium oxide | 1306-19-0 |
| 141 | 鄰苯二甲酸二戊酯 Dipentyl phthalate (DPP) | 131-18-0 |
| 142 | 分支或線性的乙氧化壬基酚，包括含有 9 個碳烷基鏈的所有獨立的同分異構體和所有含有線性或分支 9 個碳烷基鏈的 UVCB 物質 4-Nonylphenol, branched and linear, ethoxylated [substances with a linear and/or branched alkyl chain with a carbon number of 9 covalently bound in position 4 to phenol, ethoxylated covering UVCB- and well-defined substances, polymers and homologues, which include any of the individual isomers and/or combinations thereof] | - |
| 143 | 全氟辛酸銨 Ammonium pentadecafluorooctanoate (APFO) | 3825-26-1 |
| 144 | 全氟辛酸 Pentadecafluorooctanoic acid (PFOA) | 335-67-1 |
| 145 | 硫化鎘 Cadmium sulphide | 1306-23-6 |
| 146 | 鄰苯二甲酸二己酯 Dihexyl phthalate | 84-75-3 |
| 147 | 直接紅 28 Disodium 3,3'-[[1,1'-biphenyl]-4,4'-diylbis(azo)]bis(4-aminonaphthalene-1-sulphonate) (C.I. Direct Red 28) | 573-58-0 |
| 148 | 直接黑 38 Disodium 4-amino-3-[[4'-[(2,4-diaminophenyl)azo][1,1'-biphenyl]-4-yl]azo]-5-hydroxy-6-(phenylazo)naphthalene-2,7-disulphonate (C.I. Direct Black 38) | 1937-37-7 |
| 149 | 亞乙基硫脲 Imidazolidine-2-thione; 2-imidazoline-2-thiol | 96-45-7 |

| | | |
|-----|--|-------------------------------------|
| 150 | 醋酸鉛 Lead di (acetate) | 301-04-2 |
| 151 | 磷酸三(二甲苯)酯 Trixylyl phosphate | 25155-23-1 |
| 152 | 鄰苯二甲酸二己酯(支鏈和直鏈) 1,2-Benzenedicarboxylic acid, dihexyl ester, branched and linear | 68515-50-4 |
| 153 | 氯化鎘 Cadmium chloride | 10108-64-2 |
| 154 | 過硼酸鈉 Sodium perborate; perboric acid, sodium salt | 15120-21-5 |
| 155 | 過氧偏硼酸鈉 Sodium peroxometaborate | 7632-04-4 |
| 156 | 2-(2'-羥基-3',5'-二叔戊基苯基)苯並三唑(紫外線吸收劑 328) 2-(2H-benzotriazol-2-yl)-4,6-ditertpentylphenol (UV-328) | 25973-55-1 |
| 157 | 2-[2-羥基-3',5'-二叔丁基苯基]苯並三唑(紫外線吸收劑 320) 2-benzotriazol-2-yl-4,6-di-tert-butylphenol (UV-320) | 3846-71-7 |
| 158 | 二正辛基-双(2-乙基己基羧基乙酸酯)錫 2-ethylhexyl 10-ethyl-4,4-dioctyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate (DOTE) | 15571-58-1 |
| 159 | 氟化鎘 Cadmium fluoride | 7790-79-6 |
| 160 | 硫酸鎘 Cadmium sulphate | 10124-36-4; 31119-53-6 |
| 161 | 二正辛基-双(2-乙基己基羧基乙酸酯)錫和單辛基-三(2-乙基己基羧基乙酸酯)錫的反應物 Reaction mass of 2-ethylhexyl 10-ethyl-4,4-dioctyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate and 2-ethylhexyl 10-ethyl-4-[[2-[(2-ethylhexyl)oxy]-2-oxoethyl]thio]-4-octyl-7-oxo-8-oxa-3,5-dithia-4-stannatetradecanoate (reaction mass of DOTE and MOTE) | - |
| 162 | 鄰苯二甲酸二(C6-C6)烷基酯：(癸基，己基，辛基)酯與1,2-鄰苯二甲酸的複合物且鄰苯二甲酸二己酯含量≥0.3% 1,2-benzenedicarboxylic acid, di-C6-10-alkyl esters; 1,2-benzenedicarboxylic acid, mixed decyl and hexyl and octyl diesters with ≥ 0.3% of dihexyl phthalate (EC No. 201-559-5) | 68515-51-5 68648-93-1 |
| 163 | 5-仲丁基-2-(2,4-二甲基環己-3-烯-1-基)-5-甲基-1,3-二噁烷[1], 5-仲丁基-2-(4,6-二甲基環己-3-烯-1-基)-5-甲基-1,3-二噁烷[2] [覆蓋任何[1]和[2]或者其任意組合的單獨的異構體(卡拉花醛及其同分易構物)] 5-sec-butyl-2-(2,4-dimethylcyclohex-3-en-1-yl)-5-methyl-1,3-dioxane [1], 5-sec-butyl-2-(4,6-dimethylcyclohex-3-en-1-yl)-5-methyl-1,3-dioxane [2] [covering any of the individual stereoisomers of [1] and [2] or any combination thereof] | - |
| 164 | 硝苯 Nitrobenzene | 98-95-3 |
| 165 | 2,4-貳級丁基-6-(5-氯苯三唑-2-基)苯酚(UV-327) 2,4-di-tert-butyl-6-(5-chlorobenzotriazol-2-yl)phenol (UV-327) | 3864-99-1 |
| 166 | 2-(2H-苯并三唑-2-基)-4-(tert-丁基)-6-(sec-丁基)苯酚(UV-350) 2-(2H-benzotriazol-2-yl)-4-(tert-butyl)-6-(sec-butyl)phenol (UV-350) | 36437-37-3 |
| 167 | 1,3-丙磺內酯 1,3-propanesultone | 1120-71-4 |
| 168 | 全氟壬酸及其鈉與銨鹽 Perfluorononan-1-oic-acid and its sodium and ammonium salt | 375-95-1 21049-39-8 4149-60-4 |
| 169 | 苯并(a)芘 Benzo[def]chrysene | 50-32-8 |
| 170 | 雙酚 A 4,4'-isopropylidenediphenol (bisphenol A) | 80-05-7 |

| | | |
|-----|--|------------------------------------|
| 171 | 4-庚基苯酚, 支鍊及直鍊 包括含有 7 個碳烷基鏈的所有獨立的同分異構體和所有含有線性或分支 7 個碳烷基鏈的 UVCB 物質 '4-Heptylphenol, branched and linear [substances with a linear and/or branched alkyl chain with a carbon number of 7 covalently bound predominantly in position 4 to phenol, covering also UVCB- and well-defined substances which include any of the individual isomers or a combination thereof] | - |
| 172 | 十九氟癸酸及其鈉和銨鹽 Nonadecafluorodecanoic acid (PFDA) and its sodium and ammonium salts | 3108-42-7 335-76-2 3830-45-3 |
| 173 | 對(1,1-二甲基丙基)苯酚 p-(1,1-dimethylpropyl)phenol | 80-46-6 |
| 174 | 全氟己基磺酸及其鹽類 Perfluorohexane-1-sulphonic acid and its salts (PFHxS) | 355-46-4 |
| 175 | 1,2-苯并菲;(【++快】) Chrysene | 218-01-9 |
| 176 | 苯[a]蔥 Benz[a]anthracene | 56-55-3 |
| 177 | 硝酸鋇 Cadmium nitrate | 10325-94-7 |
| 178 | 氫氧化鋇 Cadmium hydroxide | 21041-95-2 |
| 179 | 碳酸鋇 Cadmium carbonate | 513-78-0 |
| 180 | 1,6,7,8,9,14,15,16,17,17,18, 18-十二氯五環 [12.2.1.16,9.02,13.05,10]十八碳-7,15-二烯 ("Dechlorane Plus"™)[含有其任何單獨的反式和順式異構體或其任何組合] 1,6,7,8,9,14,15,16,17,17,18,18-Dodecachloropentacyclo[12.2.1.16,9.02,13.05,10]octadeca-7,15-diene("Dechlorane Plus"™) [covering any of its individual anti- and syn-isomers or any combination thereof] | - |
| 181 | 1,3,4-噁二唑-2,5-二硫醇與甲醛和支鍊和直鍊 4-庚基酚的反應產物(RP-HP) [含有≥0.1%w/w 支鍊和直鍊的 4-庚基酚] Reaction products of 1,3,4-thiadiazolidine-2,5-dithione, formaldehyde and 4-heptylphenol, branched and linear (RP-HP) [with ≥0.1%w/w 4-heptylphenol, branched and linear] | - |
| 182 | 1,2,4-苯三甲酸酐 Benzene-1,2,4-tricarboxylic acid 1,2 anhydride (trimellitic anhydride; TMA) | 552-30-7 |
| 183 | 苯并[g,h,i]芘 Benzo[ghi]perylene | 191-24-2 |
| 184 | 十甲基環五矽氧烷 Decamethylcyclopentasiloxane (D5) | 541-02-6 |
| 185 | 鄰苯二甲酸二環己酯 Dicyclohexyl phthalate (DCHP) | 84-61-7 |
| 186 | 八硼酸二鈉 Disodium octaborate | 12008-41-2 |
| 187 | 十二甲基環六矽氧烷 Dodecamethylcyclohexasiloxane (D6) | 540-97-6 |
| 188 | 乙二胺 Ethylenediamine (EDA) | 107-15-3 |
| 189 | 鉛 Lead | 7439-92-1 |

| | | |
|-----|--|------------------------|
| 190 | 八甲基環四矽氧烷 Octamethylcyclotetrasiloxane (D4) | 556-67-2 |
| 191 | 氫化聯三苯 Terphenyl, hydrogenated | 61788-32-7 |
| 192 | 1,7,7-三甲基-3-(苯亞甲基)雙環[2.2.1]庚-2-酮 (3-亞苄基樟腦) 1,7,7-trimethyl-3-(phenylmethylene)bicyclo[2.2.1]heptan-2-one 3-benzylidene camphor; 3-BC | 15087-24-8 |
| 193 | 2,2-雙(4-羥基苯基)-4-甲基戊烷 2,2-bis(4'-hydroxyphenyl)-4-methylpentane | 6807-17-6 |
| 194 | 苯(k)苯駢芴 Benzo[k]fluoranthene | 207-08-9 |
| 195 | 苯駢芴 Fluoranthene | 206-44-0 93951-69-0 |
| 196 | 菲 Phenanthrene | 85-01-8 |
| 197 | 芘 Pyrene | 129-00-0 1718-52-1 |
| 198 | 2,3,3,3-四氟-2-(七氟丙氧基)丙酸·鹽類·及其醯鹵(涵蓋他們其個別和組合之同分異構物) 2,3,3,3-tetrafluoro-2-(heptafluoropropoxy)propionic acid, its salts and its acyl halides (covering any of their individual isomers and combinations thereof) | - |
| 199 | 2-甲氧基乙基乙酯 2-methoxyethyl acetate | 110-49-6 |
| 200 | 4-叔丁基苯酚 *16 4-tert-butylphenol | 98-54-4 |
| 201 | 三(4-壬苯基,支鏈及直鏈)亞磷酸酯 含≥0.1%的支鏈及直鏈 4-壬基酚 Tris(4-nonylphenyl, branched and linear) phosphite (TNPP) with ≥ 0.1% w/w of 4-nonylphenol, branched and linear (4-NP) | - |
| 202 | 2-苄基-2-二甲氨基-4'-嗎啉基丁酮 2-benzyl-2-dimethylamino-4'-morpholinobutyrophenone | 119313-12-1 |
| 203 | 2-甲基-1-(4-甲基噻吩基)-2-嗎啉基丙烷-1-酮 2-methyl-1-[4-(4-methylthiophenyl)-2-morpholino]propan-1-one 2-甲基-1-[4-(4-噻吩基)-2-(4-嗎啉基)-1-丙酮 | 71868-10-5 |
| 204 | Diisohexyl phthalate 二異己基鄰苯二甲酸酯 | 71850-09-4 |
| 205 | Perfluorobutane sulfonic acid (PFBS) and its salts 全氟丁烷磺酸及其鹽類 | - |
| 206 | 1-vinylimidazole 1-乙烯基咪唑 | 1072-63-5 |
| 207 | 2-methylimidazole 2-甲基咪唑 | 693-98-1 |
| 208 | Butyl 4-hydroxybenzoate(Butylparaben) 4-羥基苯甲酸丁酯 (對羥基苯甲酸丁酯) | 94-26-8 |
| 209 | Dibutylbia(pentane-2,4-dionato-0,0')tin 雙(乙酰丙酮酸)二丁基錫 | 22673-19-4 |
| 210 | bis(2-(2-methoxyethoxy) ethyl) ether 雙(2-(2-甲氧基乙氧基)乙基)醚 | 143-24-8 |

| | | |
|-----|---|--|
| 211 | Dioctyltin dilaurate, stannane, dioctyl-, bis(coco acyloxy) derivs., and any other stannane, dioctyl-, bis(fatty acyloxy) derivs. wherein C12 is the predominant carbon number of the fatty acyloxy moiety 二月桂酸二辛基錫·錫烷·二辛基-· 雙(椰油醯氧基)衍生物·以及任何其他錫烷·二辛基-·雙(脂肪醯氧基)衍生物。 其中 C12 為脂肪醯氧基部分的主要碳原子數 | - 91648-39-4 3648-18-8 |
| 212 | 1,4-dioxane 1,4-二氧六環 (二惡烷) | 123-91-1 |
| 213 | 2,2-bis(bromomethyl)propane-1,3-diol (BMP); 2,2-dimethylpropan-1-ol, tribromo derivative/3-bromo-2,2-bis(bromomethyl)-1-propanol (TBNPA); 2,3-dibromo-1-propanol (2,3-DBPA) 2,2-雙(溴甲基)-1,3-丙二醇 (BMP) 三溴新戊醇 (TBNPA) 2,3-二溴-1-丙醇 (2,3-DBPA) | 36483-57-5 1522-92-5 3296-90-0 96-13-9 |
| 214 | 2-(4-tert-butylbenzyl)propionaldehyde and its individual stereoisomers 2-(4-叔丁基苄基)丙醛及其立體異構體 | 75166-31-3 80-54-6 75166-30-2 |
| 215 | 4,4'-(1-methylpropylidene)bisphenol 4,4'-(1-甲基亞丙基) 雙酚 ; (雙酚 B) | 77-40-7 |
| 216 | Glutaral 戊二醛 | 111-30-8 |
| 217 | Medium-chain chlorinated paraffins (MCCP) 中鏈氯化石蠟 (MCCP) | 1372804-76-6 85535-85-9 - 198840-65-2 |
| 218 | orthoboric acid, sodium salt 硼酸鈉 | 25747-83-5 22454-04-2 14312-40-4 1333-73-9 13840-56-7 14890-53-0 |
| 219 | Phenol, alkylation products (mainly in para position) with C12-rich branched alkyl chains from oligomerisation, covering any individual isomers and/ or combinations thereof (PDDP) 碳鏈(C12 為主·直鏈或支鏈)主要在对位的烷基酚物質及其任何单个異構體或組合 (PDDP) | 121158-58-5 74499-35-7 210555-94-5 27459-10-5 57427-55-1 27147-75-7 |
| 220 | (±)-1,7,7-trimethyl-3-[(4-methylphenyl)methylene]bicyclo[2.2.1]heptan-2-one covering any of the individual isomers and/or combinations thereof (4-MBC) (±)-1,7,7-三甲基-3-[(4-甲基苯基)亞甲基]雙環[2.2.1]庚-2-酮·包括任何单独的異構體和/或其組合(4-MBC) | 1782069-81-1 95342-41-9 852541-25-4 36861-47-9 741687-98-9 852541-30-1 852541-21-0 |
| 221 | 6,6'-di-tert-butyl-2,2'-methylenedi-p-cresol 2,2'-亞甲基雙-(4-甲基-6-叔丁基苯酚) | 119-47-1 |
| 222 | S-(tricyclo[5.2.1.0'2,6]deca-3-en-8(or 9)-yl O-(isopropyl or isobutyl or 2-ethylhexyl) O-(isopropyl or isobutyl or 2-ethylhexyl) phosphorodithioate S-(三環[5.2.1.0'2·6]癸-3-烯-8(或9)-基)O-(異丙基或異丁基或2-乙基己基)O-(異丙基或異丁基或2-乙基己基)二硫代磷酸酯 | 255881-94-8 |
| 223 | tris(2-methoxyethoxy)vinylsilane 乙烯基-三(2-甲氧基乙氧基)硅烷 | 1067-53-4 |
| 224 | N-(hydroxymethyl)acrylamide N-(羥甲基)丙烯酰胺 | 213-103-2 |

4.4. Product Composition

LUMISSIL products are mainly dedicated to commercial / industrial / medical / mobile and automotive markets. Few selected ones are penetrating some advanced applications. To ensure that our products can comply with the regulations of environmental protection, LUMISSIL has established a database that contains the information of product composition by package families. This database is confirmed with related assembly houses and its information is very important because it allows us to estimate the effectiveness of re-cycle and re-use rates of products and helps us answer customer's End-Of-Life questions.

Table 4-5 below is an example sheet of material composition for thin small outline package (TSOP) family. The chemical characteristics are specified according to the components such as chip, gold wire or encapsulation. For each component, the material name, mass percentage, element, CAS4 number and element weight are carefully calculated. Similar sheets are available for SOP, SOJ or other package families. Please contact us if you need more information.

Table 4-5 Material Composition Sheet

| Material Composition Sheet (for IS prefix P/N) | | | | | | | | ISSI | |
|--|-------------------------------------|-------------------------|----------------------|--------------------------|--------------|-------------------------|--------------------|-------------|-----------|
| Package family | Thin Small Outline Package(Type II) | | | | | | | | |
| Issue date | 2/4/2008 | | | | | | | | |
| Package weight(mg) | 541.200 | | | | | | | | |
| Composition part | Material name | Material composition(%) | Material weight (mg) | Element name | CAS No | Element composition(%) | Element weight(mg) | mg/kg (ppm) | |
| Die | Silicon Chip | 5.50% | 29.790 | Silicon | 7440-21-3 | 99.400% | 29.612 | 54714.73 | |
| | | | | Aluminum | 7429-90-5 | 0.300% | 0.089 | 165.14 | |
| | | | | Copper | 7440-50-8 | 0.300% | 0.089 | 165.14 | |
| Leadframe | A42 | 21.26% | 115.037 | Fe | 7439-89-6 | 58.00% | 66.721 | 123284.22 | |
| | | | | Ni | 7440-02-0 | 42.00% | 48.316 | 89274.78 | |
| | | | | Aromatic polyimide resin | 105218-97-1 | 50.00% | 1.068 | 1973.50 | |
| Die Attach Adhesive | LOC Tape | 0.39% | 2.136 | polyether amideimide | Trade Secret | 50.00% | 1.068 | 1973.50 | |
| Bonding Wire | Gold Wire | 0.14% | 0.768 | Au | 7440-57-5 | 100.00% | 0.768 | 1419.00 | |
| Encapsulation | Mold Compound | 72.00% | 389.673 | Epoxy resin | Trade Secret | 5.50% | 21.432 | 39600.94 | |
| | | | | Phenol resin | Trade Secret | 4.50% | 17.535 | 32400.77 | |
| | | | | Carbon black | 1333-86-4 | 0.20% | 0.779 | 1440.03 | |
| | | | | Silica | 60676-86-0 | 89.80% | 349.927 | 646575.27 | |
| | | | | Solder Plating(Pb-free) | Tin | 0.70% | 3.795 | Sn | 7440-31-5 |
| Total | | 100.00% | 541.200 | | | | | | |

Materials Disclosure Disclaimer

Note: Even though all possible efforts have been made to provide you with the most accurate information, we can not guarantee to its completeness and accuracy due to the fact that the data has been compiled based on the ranges provided and some information that may not have been provided by the subcontractors and raw material suppliers to protect their business proprietary information. Based on the above considerations, this information is provided only as estimates of the average weight of these parts and the anticipated significant toxic metals components. These estimates do not include trace levels of dopants and metal materials contained within silicon devices in the finished products.

4.5. Lead-free Solution

4.5.1. Overview

Lead containing waste, disposed from PCB assembly, in landfills is eluded by acid rain, resulting in contaminated groundwater and rivers. When accumulated in the human body through drinking water or food, it will cause intellectual growth disorder in children.

The use of lead in electronic products is an important issue of global environmental protection. LUMISSIL has received significant amount of requests regarding lead-free package demand from Japanese customers since early 2001. Consequently, LUMISSIL has dedicated its resources to work with suppliers to provide lead-free solutions.

4.5.2. Background

For any alloy to be a worthwhile soldering material used in the electronic industry, it must possess certain specific qualities under the following criteria:

1) Melting Range:

It must have a liquids temperature that is sufficiently low so that components and boards are not damaged during soldering. In practice, this means that it must be usable at 260 degree C, which is the maximum temperature exposure limit for the majority of electronic components. Also, it must have a solidus temperature that is sufficiently high so that during service the solder joints do not lose their mechanical strength⁵.

2) Metallurgy:

Another crucial attribute of the alloy is that it must wet the common engineering metals and metallizations (silver, copper, nickel, etc). Ideally, new alloys should also be compatible with existing fluxes, stable and non-corrosive that they can withstand the stress/strain/temperature regimes encountered in electronic applications.

3) Environment Health and Safety Issues:

The alloy and its components must be non-toxic. Similar considerations apply to the soldering fluxes and the cleaning agents.

⁵ The melting point of tin-lead eutectic at 183 °C provides a useful compromise between these two criteria.

4) Economic and Supply Issues:

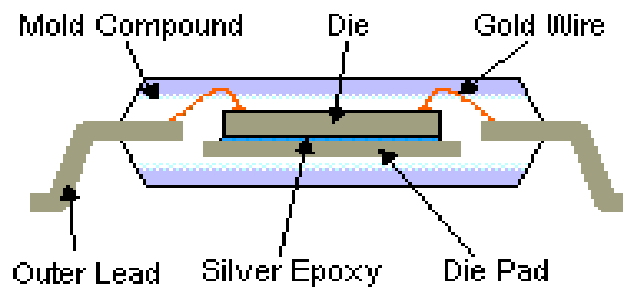
For any alloy to be considered as a potential replacement for tin-lead solder, its components must be in sufficient supply that it would not be subject to price constraints.

4.5.3. Lead-free Solder Solutions

There are a number of low melting point elements that can be combined to form feasible solder systems. The most practical solder systems are based on tin and bismuth or matte tin. LUMISSIL has already provided millions of devices for Analog/Analog_MCU/Connectivity products with lead-free external terminals. The composition and plating thickness of the lead-free solder solutions follow:

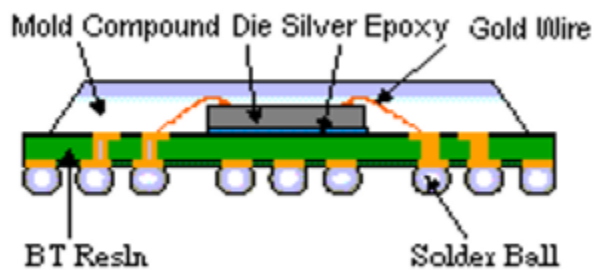
1) Outer lead:

Plating composition: Pure matte Tin Plating thickness: 300 to 800 micro-inches (7.6 to 20.3 μm). The thickness of plating of curved region of shoulder and heel region due to the plating layer is stretched and will be reduce to min 3 μm after lead forming.



2) Solder ball:

Composition: 99.0 Sn 1.0 Ag



4.6. Halogen-free Solution

4.6.1. Overview

In epoxy molding compounds and substrates, halogens and antimony trioxide are usually used as flame retardant to meet UL94V-0 requirement. When electronic products contain those substances are disposed and incinerated, it is possible to produce harmful dioxins.

4.6.2. Halogen-free Compound Status

When normal compounds are replaced with phosphorous and inorganic compounds, the moldability and reliability may be lessened. However, several industrial consortia and LUMISSIL assemblers have evaluated halogen-free compound. Safe materials for replacement have been successfully developed with wide molding window and excellent reliability, and are commercially available now. The providers include Hitachi Chemical, Sumitomo Bakelite, Kyocera etc. LUMISSIL is currently ready to provide samples or components with halogen-free⁶ compound for lead-free packages upon customer's request.

4.7. Pb-free/Halogen-free Evaluation/Qualification Information

4.7.1. Commercial / Industrial Grade Products

The evaluation/qualification of products for general purpose is carried out in two stages. One is the standard procedure that includes preconditioning test and environmental tests. The other is the evaluation/qualification of solder plating.

1) Component or Package Level Tests

In this stage, the qualification items and procedures are similar to that of the regular packages as described in chapter 3. The details are shown in Table 4-6 and the major difference is that the IR reflow temperature of preconditioning is higher (260 °C).

Table 4-6 Component level tests

⁶ Halogen-free will cause further cost increment in comparison with lead-free. Material supply chain availability and cost concern in new material will rely on market demand in green product.

| Reliability Test Items | Test Method | Test Conditions | S/S | Acc/Rej |
|---|-------------------------|---|-----|---------|
| Preconditioning MSL 3 (Heat resistance test included) | JESD22-A113 & J-STD-020 | 30C / 60%RH / 192hrs + 260C IR x 3 | 240 | 0/1 |
| TCT (Temp cycling) | JESD22-A104 | - 65 to 150 C / 500 cycles | 77 | 0/1 |
| PCT (Autoclave or pressure cooker) | JESD22-A102 | 121 C / 100 %RH / 15 psi / 168 hrs (Not apply for BGA packages) | 77 | 0/1 |
| HAST (Highly Accelerated Stress Test) | JESD22-A110 | 130C / 85%RH / 33.3 psi / 96 hrs | 77 | 0/1 |

2) Solder Plating Quality/Reliability Evaluation

The solder paste and solder plating material used in Pb-free package require higher temperature in the SMT process because these materials have higher melting point. To ensure the transition from regular package to Pb-free package will not result in detrimental failure, it is crucial to examine the mechanical properties of the solder joints, which determines the resistance to installation and handling mechanics.

Before the solder joint test, the package will go through the SMT process in which the preheating temperature is ramping up from 130 °C to 170 °C within 45 to 90 seconds. Then the package is heated to 225 °C or more within 20 to 30 seconds. The peak temperature is 230 °C or less at solder joint of terminal.

Solder joint strength tests are carried out by two items:

Item 1: lead pull strength

- All the packages will go through the pretreatment of moisture soaking at 105 °C under 100% relative humidity for 4 hours
- Perform TCT test under the condition of –35 °C to 85°C with 30 minutes/cycle
- Measure lead pull strength at 0, 250, 500 and 1000 cycles.

The pass criterion requires that the final lead pull strength has to exceed half of the initial values.

Item 2: cross-sectional view study

- Perform SEM cross-sectional view study after 0, 250, 500 and 1000 cycles.

The pass criterion requires that the final solder joint width has to exceed half of the initial values.

4.7.2. Advanced Electronic Grade Products

For products used in advanced applications, we will either introduce extra test items or tighten the test conditions/criteria.

1) Component or Package Level Tests

For component level test, we add HTSL (High Temperature Storage Life) item to check the resistance of package to the prolonged high temperature storage condition.

For stricter test conditions/criteria, first of all, all the acceptance criteria allow zero failures only. In addition, final test (FT) check before and after the test is a must for all the test items involved. In some cases, FT at various temperatures are also specified such as in the PCT and HTSL tests as shown in Table 4-7.

Table 4-7 Component level tests for advanced applications

| Reliability Test Items | Reference Doc. | Test Method | Sample size/Lot | Accept Criteria | Note |
|---|----------------|------------------------|-----------------|-----------------|--|
| Preconditioning (Heat resistance test included) | AEC-Q100#A1 | J-STD-020 & JESD22A113 | 231/ 3 lots | 0 fails | MSL3 at least. PC performed prior to TCT, PCT and THB/HAST stresses. F/T checked before and after at room temp. Delamination from die surface is acceptable if the device can pass subsequent qualification tests. |
| TCT (Temperature Cycling) | AEC-Q100#A4 | JESD22A104 | 77/ 3 lots | 0 fails | Grade 1 : -65C~150C, 500 cycles. F/T checked before and after at high temp. Decap procedure on 5 units/ 1 lot after test completed, and perform wire pull test on 2 corner bonds per corner and 1 mid-bond per side. |
| PCT (Autoclave or Pressure cooker) | AEC-Q100#A3 | JESD22A102 or A118 | 77/ 3 lots | 0 fails | 121C/15psi/168 hrs (Not apply for BGA packages). F/T checked before and after at room temp. |
| THB (Temp Humidity Bias) or HAST (Highly Accelerated Stress Test) | AEC-Q100#A2 | JESD22A101 or A110 | 77/ 3 lots | 0 fails | THB: 85C/85%RH/1000 hrs with bias or HAST: 130C/85%RH/33.3psi/96 hrs or 110C/85%RH/17.7psi/264hrs with bias. F/T checked before and after at room and high temp. |

| | | | | | |
|-------------------------------|-----------|------------|-----------|---------|--|
| HTSL (High Temp Storage Life) | AECQ100#A | JESD22A103 | 45/ 1 lot | 0 fails | Grade 1: 150C, 1000 hrs. F/T checked before and after at room and high temp. |
|-------------------------------|-----------|------------|-----------|---------|--|

2) Solder Plating Quality/ Reliability Evaluation

Besides the aforementioned solder joint strength test, three more test items are added for advanced electronic applications. They are: the solderability and wettability test, the tin whisker check, and the electrical continuity check with Daisy Chain.

a) Solderability and wettability test

This test determines the solderability of terminals after transportation and storage. Equilibrium method will be adopted to measure the Meniscus force curve. The acceptance criterion requires the zero cross time to be less than 3 seconds.

b) Tin whisker

The extent of tin whisker growth of Pb-free package is much worse than in the regular package because the built-in stress is quite different. If this reliability issue is not well taken care of, the product might get shorted after prolonged service in the field.

The tin whisker tests will be carried out with three different approaches:

- Perform TCT test under the condition of $-55\text{ }^{\circ}\text{C}$ to $85\text{ }^{\circ}\text{C}$ with 10 minutes soak ; 3 cycles/hour for 1500 cycles .
- Perform THT (Temperature humidity storage) under the condition of $30 \pm 2\text{ }^{\circ}\text{C}$ and $60 \pm 3\%$ RH relative humidity for 4,000 hrs.
- Perform THT (High temperature humidity storage) under the condition of $55 \pm 3\text{ }^{\circ}\text{C}$ and $85 \pm 3\%$ RH relative humidity for 4,000 hrs.

After the tests, the length of any tin whisker will be checked. The acceptance criterion is 45 um maximum for TCT testing & 40 um for temperature humidity storage (Room Temp & High Temp) by stereoscope at 40X or SEM at 300X above.

LUMISSIL implements annealing process to reduce tin whisker growth, for the pure matte tin of terminal is performed the heat treatment with 1hr @ 150°C within 24 hrs after plating process.

c) Daisy chain

For this test, we will perform preconditioning test and TCT test for 3000 cycles. The acceptance criterion is that the electrical continuity should be guaranteed after 3000 cycles.

4.8. Current Status

The development work on lead-free solders has been launched by a number of organizations and institutions through either formal partnership or professional alliance in U.S., Europe and Japan. The qualified lead-free and halogen-free packages for mass production.

However, both lead-containing and lead-free packages will be provided in parallel for customers' choice.

4.9. Solder Heat Resistance for PCBA (PC Board Assembly)

Surface Mount devices (SMD) have become popular in recent years due to their advantage in high-density mounting. However, SMD package delamination often occurring between the chip/die pad and the molding compound, caused by thermal stress during mounting, has also become a problem. To assure all LUMISSIL's products not plagued by this problem, all lead-free packages are required to meet JEDEC standard, Level 3. The recommended soldering methods and constraints are described below:

1) Reflow soldering method

Peak temperature: 260°C maximum, 30 seconds, soldering zone: 217°C or more, 60 to 150 seconds, number of cycles: 3 cycles

2) Soldering iron method

Temperature: 380°C max., application time of soldering iron: 5 seconds maximum, number of cycles: 2 cycles

4.10. Lead Time from Ordering to Delivery

The maximum lead-time from ordering to delivery, for sample evaluation and mass production on unqualified lead-free and halogen-free products, is 2 and 3.5 months respectively. Should you have any comments, suggestions, or questions, please contact LUMISSIL regional Sales office for details.

4.11. Distinguishing Mark of Lead-free and RoHS compliance Package

- 1) Add an "L" or a "G" to the end of the part number. Please refer to the documents of packing and IC top mark.
- 2) Add lead-free discrimination stamp on dry pack, inner box and outer box (Figure. 4-2a)
- 3) Add RoHS label on reel, dry pack, inner box and outer box (Figure. 4-2b).



Figure 4-2

4.12. Re-flow Temperature Profile for Lead-free Package

Pb-free Process – Package Classification Reflow Temperatures

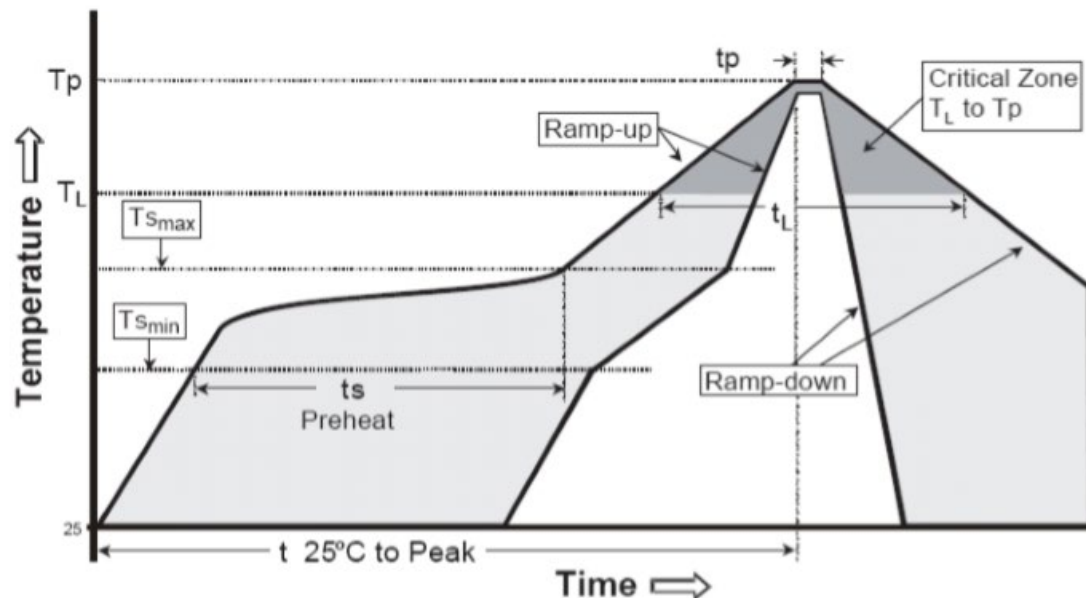
| Package Thickness | Volume mm ³ <350 | Volume mm ³ : 350- 2000 | Volume mm ³ >2000 |
|-------------------|-----------------------------|------------------------------------|------------------------------|
| <1.6 mm | 260°C | 260°C | 260°C |
| 1.6 mm - 2.5 mm | 260°C | 250°C | 245°C |
| >2.5 mm | 250°C | 245°C | 245°C |

| Profile Feature | Pb-free Assembly |
|---|----------------------------|
| Ramp-Up Rate(TL to Tp) | 3 °C/second max. |
| Preheat– Temperature Min (T _{smin}) to Max (T _{smax}) | 150~200 °C |
| – Time (t _{smin} to t _{smax}) | 60-120 seconds |
| Time maintained above – Temperature (TL) | 217 °C |
| – Time (t _L) | 60-150 seconds |
| Peak Temperature (Tp) (Note 2) | See package classification |
| Time within 5 °C of actual Peak, Temperature (tp) | 30 seconds (Note 3) |
| Ramp-Down Rate(Tp to TL) | 6 °C/second max. |
| Time 25 °C to Peak Temperature | 8 minutes max. |
| Number of applicable Temperature cycles | 3 cycles max. |


Notes: 1. All temperatures refer to top side of the package, measured on the package body surface.

2. The peak temperature (Tp) is defined as package heatproof min. and customer used max.

3. The time at peak temperature (tp) is defined as package heatproof min. and customer used max.



4.13. Storage Recommendations



Caution
This bag contains
MOISTURE-SENSITIVE DEVICES

LEVEL
3

1. Calculated shelf life in sealed bag: 12 months at <40°C and <90% relative humidity (RH)

2. Peak package body temperature: _____ °C (If blank, see IPC/JEDEC J-STD-020)

3. After bag is opened, devices that will be subjected to reflow solder or other high temperature process must

a) Mounted within: 168 hours of factory conditions <30°C/60% RH, or

b) Stored at <10% RH

4. Devices require bake, before mounting, if:

a) Humidity Indicator Card is >10% when read at 23 ± 5°C

b) 3a or 3b not met

5. If baking is required, devices may be baked for 48 hours at 125 ± 5°C

Note1: If device containers cannot be subjected to high temperature or shorter bake times are desired, reference IPC/JEDEC J-STD-033 for bake procedure

Note2: If parts packed in T/R and tube, they should be transferred to metal tube or high temp. (150 °C) tray for baking process.

Bag Seal Date: _____

Note: Level and body temperature defined by IPC/JEDEC J-STD-020

4.14. LUMISSIL Declaration of Compliance

LUMISSIL issues a letter of declaration to certify that parts are compliant to:



1) RoHS (EU Directive entitled “Restriction on the use of certain Hazardous Substances 2011/65/EU, and 2006/122/EC”) requirements and containing none of the following 7 substances: Pb, Hg, Cd, Cr(VI), PBB, PBDE, and PFOS.

2) The 209 SVHC (Substance of Very High concern) of EU directive of the Regulation (EC) No 1907/2006 (REACH): the part shall not contain more than the 0.1% of the following SVHC by weight of part as defined in appendix also including annex XVII.

3) IEC 61249-2-21, JPCA-ES01 2003 & IPC 4101, the Br, Cl, must be lower than 900 ppm, respectively, and total amount of PPM must be lower than 1500 ppm (Br + Cl < 1500 ppm).

4) Conflict Materials and EICC by not using the materials from mines with inferior working conditions, such as DRC (Democratic Republic of the Congo). The suppliers or subcontractors

110


A Division of 

will trace the supply chain for gold (Au), tantalum (Ta), tungsten (W), tin (Sn) and cobalt (Co).

4.15. RoHS Declaration



August, 8th 2022

Declaration of RoHS (including Halogen Free) Compliance

Dear Customer,

Lumissil hereby declares that all our lead free products satisfy the following requirements/conditions:

- 1) Using a "L" or "G" after the package type designating letter in the IS prefix or IC prefix part number for identification respectively.
- 2) Complying with the RoHS directive including POPs, annex XVII & XIV, and Halogen free with none of exemption restricting the use of certain materials in products. This is also covered China RoHS and ELV requirements. The allowable concentration listed below:

| Regulations | Substances | Allowable concentration |
|------------------------------|--|-------------------------|
| RoHS directive (2011/65/EU) | Cadmium (Cd) | 100 ppm |
| | Lead (Pb) | 1000 ppm |
| | Mercury (Hg) | 1000 ppm |
| | Hexavalent Chromium (Cr6+) | 1000 ppm |
| | Poly Brominated Biphenyls (PBB) | 1000 ppm |
| (EU 2015/863) | Poly Brominated Diphenyl Ethers (PBDE) | 1000 ppm |
| | Phthalates (DEHP,BBP,DBP,DIBP) | 1000 ppm by each |
| | Halogen Free (IEC 61249-2-21, JPCA-ES01 2003 & IPC 4101) | |
| | Bromine (Br) | 900 ppm |
| | Chlorine (Cl) | 900 ppm |
| | Total concentration of Cl & Br | 1500 ppm |

- 3) Complying with the IPC/JEDEC J-STD-020 with regard to the solder profile requirement (Max. reflow temperature 260 deg.C)
- 4) Complying with the 224 SVHC of EU directive of the Regulation (EC) No 1907/2006 (REACH): the part shall not contain more than the 0.1% of the following SVHC by weight of part as defined in appendix. (ECHA Candidate list table : <http://echa.europa.eu/web/guest/candidate-list-table>)

This Declaration is made with Lumissil's best commercial effort to verify the compliance, of its suppliers, with the above requirement, and is given in good faith without any responsibility or liability. The statement here above does not extend to or apply to the procedures subject to unintentional contamination, misuse, neglect, accident, improper installation or any use in violation of instructions furnished by Lumissil.

This Declaration contains the entire understanding between you and Lumissil with respect to this subject matter and supersedes all prior agreements, understandings and/or representations. This Declaration covers Lumissil products from both Analog, Analog_MCU and Connectivity.

Please let us know if there is any further concern.

Sincerely Yours,

Shou-Kong Fan
Vice President
Quality & Reliability Assurance Division

1623 Buckeye Drive, Milpitas, California, 95035-7423 USA (Headquarters)

Tel: 408-969-6600 Fax: 408-969-7800 Web: www.lumissil.com

4.16. California Proposition 65



Declaration of California Proposition 65

Proposition 65 is a California law officially known as the California Safe Drinking Water and Toxic Enforcement Act, approved by California voters in 1986. The purpose of Proposition 65 warning is to ensure that people are informed about exposure to such chemicals by the State of California to cause cancer, birth defects or the other reproductive harm.

Lumissil Microsystems reviews suppliers' certifications, content declarations, and confidentially disclosed chemicals and materials information. Based on foregoing information, Lumissil Microsystems has determined to the best of its knowledge and belief that certain Lumissil Microsystems semiconductor products may contain one or more of chemicals on the Prop 65 List. Lumissil Microsystems products are not intended to cause user exposure to any contained substances, nor are they intended to be released or discharged during normal product use.

To our knowledge, Lumissil Microsystems products are within the "no significant risk" range, and not harmful when normally used. However, Lumissil Microsystems has elected to provide this Proposition 65 declaration on our website.

Visit <https://oehha.ca.gov/proposition-65> to get more information about Proposition 65.

A handwritten signature in black ink that reads "Shou-Kong Fan".

Shou-Kong Fan
Vice President
Quality & Reliability Assurance Division
Date: August. 9th 2022

4.17. China Volatile Organic Compounds (VOC)



November, 25th 2020

Declaration of China Volatile Organic Compounds (VOC)

Dear Customer,

Thank you for your support and trust in Lumissil to Lumissil's success.

The State Administration for Market Regulation Standardization Administration of China has issued new and revised national standards governing limits of volatile organic compounds and harmful substances in cleaning agents, adhesives, industrial protective coatings and printing ink. The GB Standards were approved March 4, 2020, published by March 20, 2020. The specific standards are:

- *GB 38508-2020 Limits for Volatile Organic Compounds Content in Cleaning Agents*
- *GB 33372-2020 (substitute for GB/T 33372-2016) Limit of Volatile Organic Compounds Content in Adhesive*
- *GB 30981-2020 (substitute for GB 30981-2014) Limit of Harmful Substances of Industrial Protective Coatings*
- *GB 38507-2020 Limits of Volatile Organic Compounds (VOCs) in Printing Ink*

Lumissil reviews suppliers' certifications, content declarations, and confidentially disclosed chemicals and materials information. Based on foregoing information, Lumissil has determined to the best of its knowledge and belief that all Lumissil semiconductor products meet the VOC GB standards for the People's Republic of China.

Lumissil would like to thank you for your continued business. For any additional questions, please feel free to reach out to your Lumissil Sales contact.

Visit <http://std.sacinfo.org.cn/gnoc/queryInfo?id=DBFEEDF05290B415CFBBEAA40EA24D78> to get more information about Volatile Organic Compounds (VOC) of China.

Sincerely Yours,

A handwritten signature in cursive script that reads "Jackie Chang".

Jackie Chang
Quality Director
Quality & Reliability Assurance Division

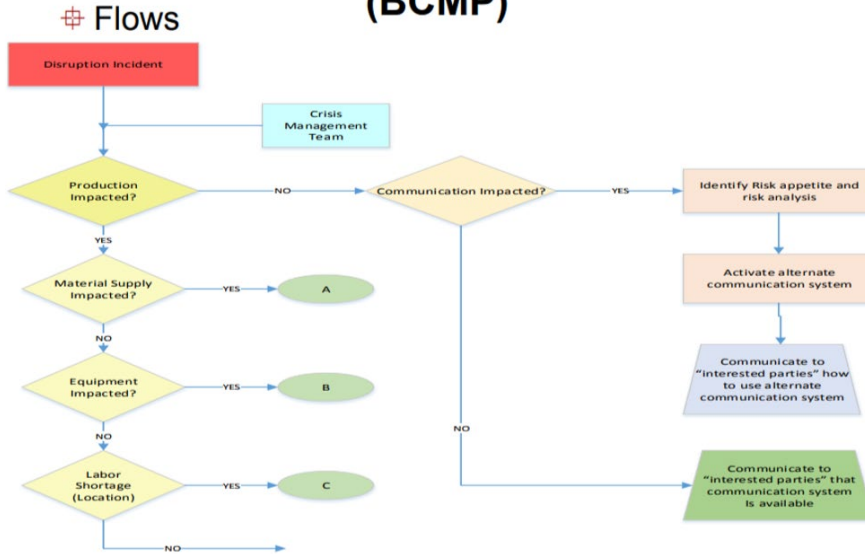
1623 Buckeye Drive, Milpitas, California, 95035-7423 USA (Headquarters)

Tel: 408-969-6600 Fax: 408-969-7800 Web: www.lumissil.com

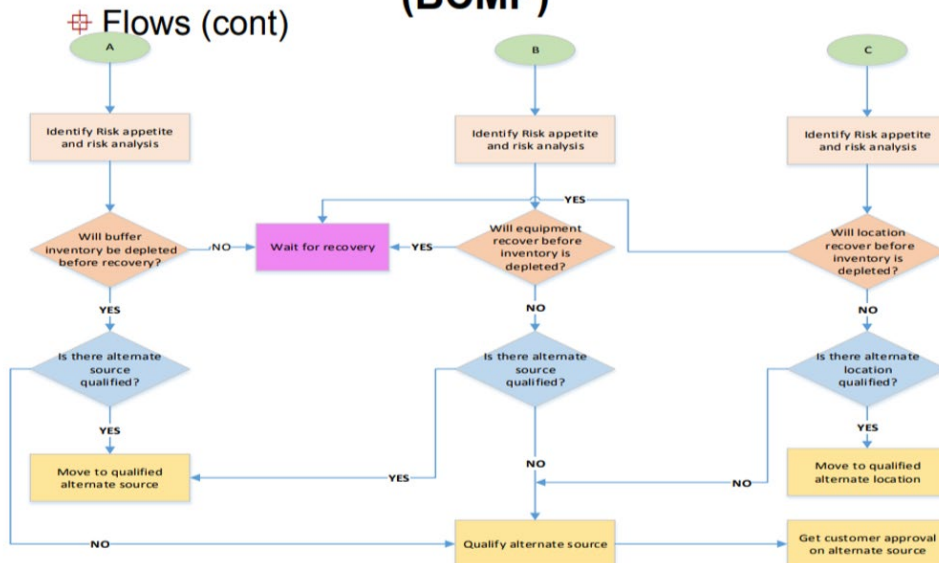
Business Continuity

LUMISSIL has procedures for planning and implementing controls and measures to manage disruptive incidents and to monitor the effectiveness of these measures.

Business Continuity Management Process (BCMP)



Business Continuity Management Process (BCMP)



Business Continuity Management Process (BCMP)

- ⊕ Contingency plans for:
 - Material availability
 - Process continuance
 - Uninterrupted delivery
 - Continuous systems of communication
 - Replacement of lost parts

BCMP – LUMISSIL Internal (Contingency plans per 230-110-005)

- ⊕ Material availability
 - Wafers availability from foundry reviewed monthly and quarterly
 - Alternate sources reviewed for contingency
- ⊕ Process continuance
 - Quarterly review of subcontractors for capability analysis and continuous supply
 - At any time during the week if there is any unscheduled interruption, the Risk Management team shall meet and make decisions on alternative sources
- ⊕ Uninterrupted delivery
 - Alternative means of delivery are set up for different locations.

BCMP - LUMISSIL Suppliers (Fab and Subcon)

- ⊕ Material availability
 - Purchasing monitors wafer deliveries
 - Buffer inventory prepared to ensure supply
- ⊕ Process continuance
 - Equipment consignment to key subcontractors guarantee continuous supply in case of process interruption in one location
 - Joint investment and Financial support of Fab and subcon guarantee priority of material supply in case of interruption
 - Qualified alternative subcontractor
- Uninterrupted delivery
 - Alternative means of delivery are set up for different locations.